

*10 Things*  
*You Didn't Know*  
*About*  
*Memristors*

The

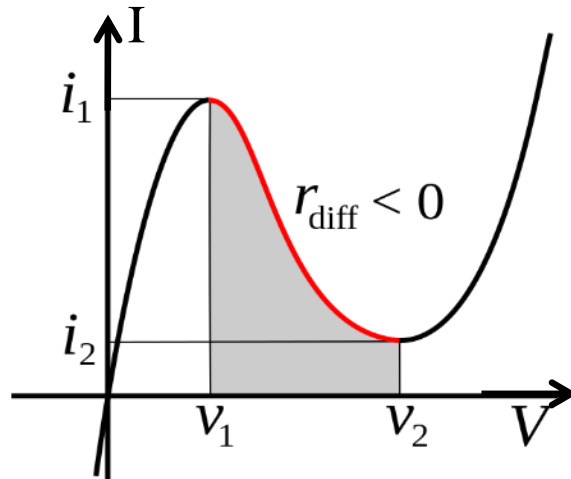
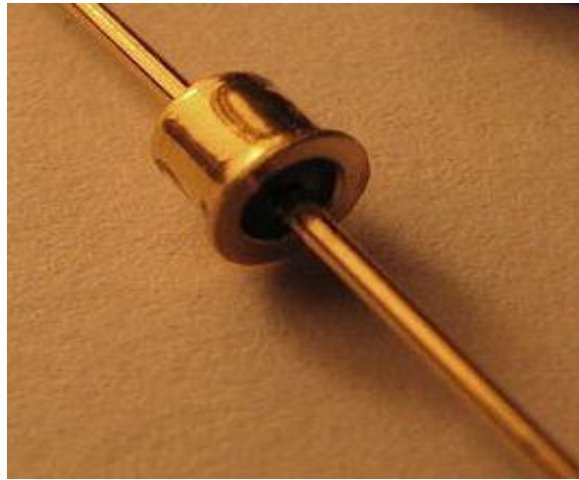
*Perfect Storm*

in

*Nonlinear Circuit Theory* !



# *Esaki Diode*



*Leo Esaki*

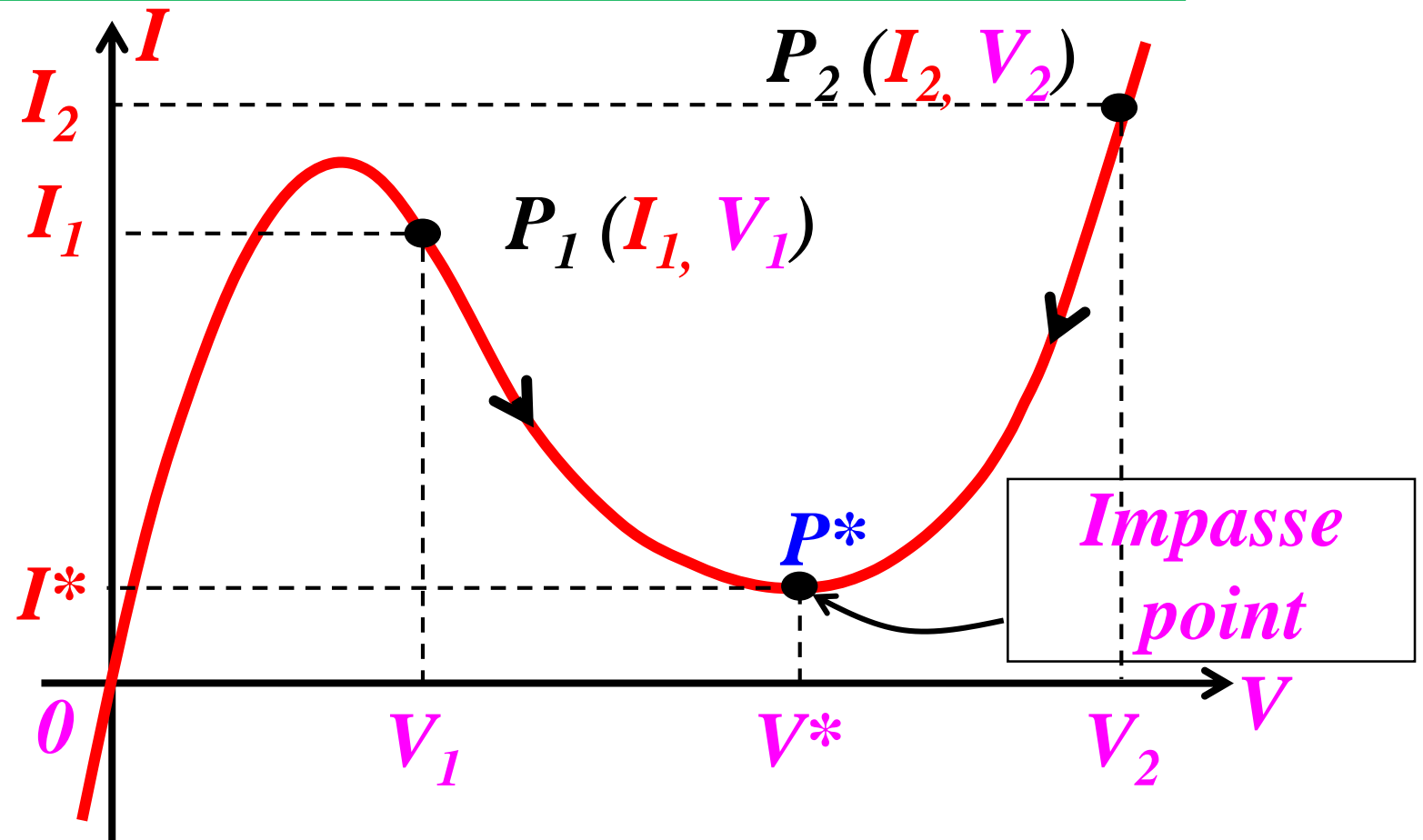
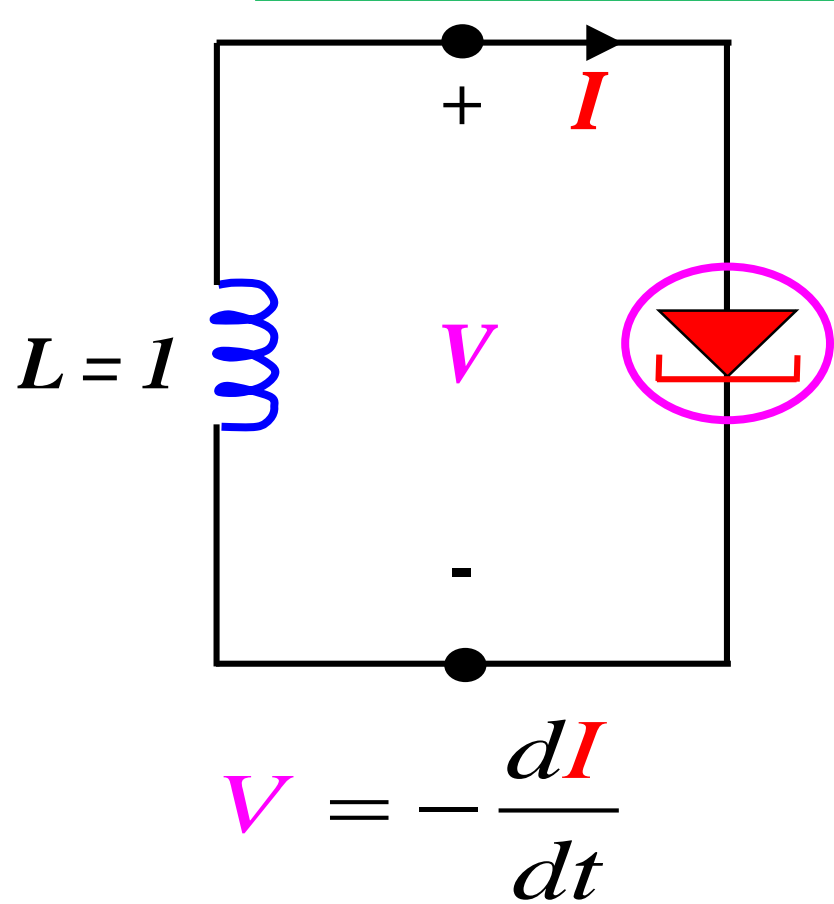
*Nobel Prize in Physics, 1973*

*L. Esaki*

*New Phenomenon in Narrow Germanium p-n junctions*

*Physics review 109(2):603, 1958*

# Simplest Tunnel Diode Circuit



**Solution does NOT exist beyond  $P^*$  !**

# *Two Points of View !*

- For *mathematician*,  
*no solution* is a  
Perfectly *valid solution*
- For *everybody else*,  
no solution means *nonsense*.

# *Crisis in Circuit Theory*

*Pre-1970 Definitions of the  
3 Basic Circuit Elements*

*Capacitors, Resistors, and Inductors  
give wrong circuit solutions*

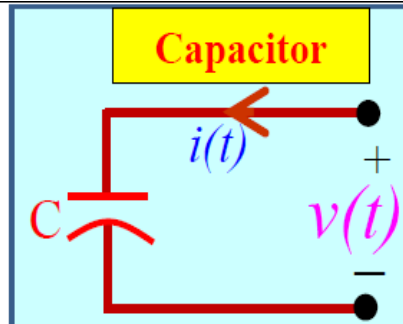
*when the elements are  
time-varying or nonlinear*

# 3 Basic Circuit Elements

1745



Ewald Georg Von Kleist

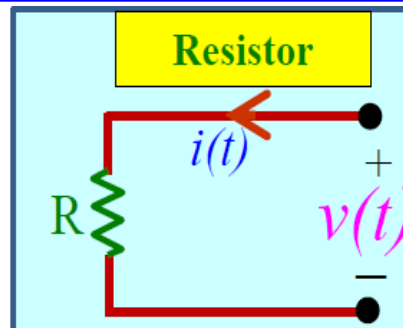


$$i(t) = C \frac{dv(t)}{dt}$$

1827



Georg Ohm

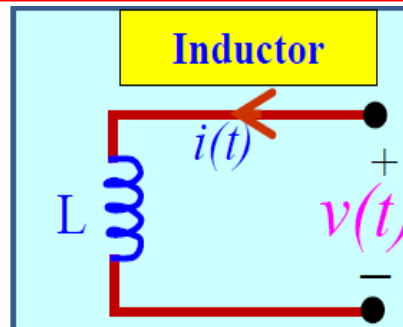


$$v(t) = R i(t)$$

1831



Michael Faraday



$$v(t) = L \frac{di(t)}{dt}$$

*To Recover from  
the **perfect storm***

*Capacitors, Resistors, Inductors  
must be*

*redefined*

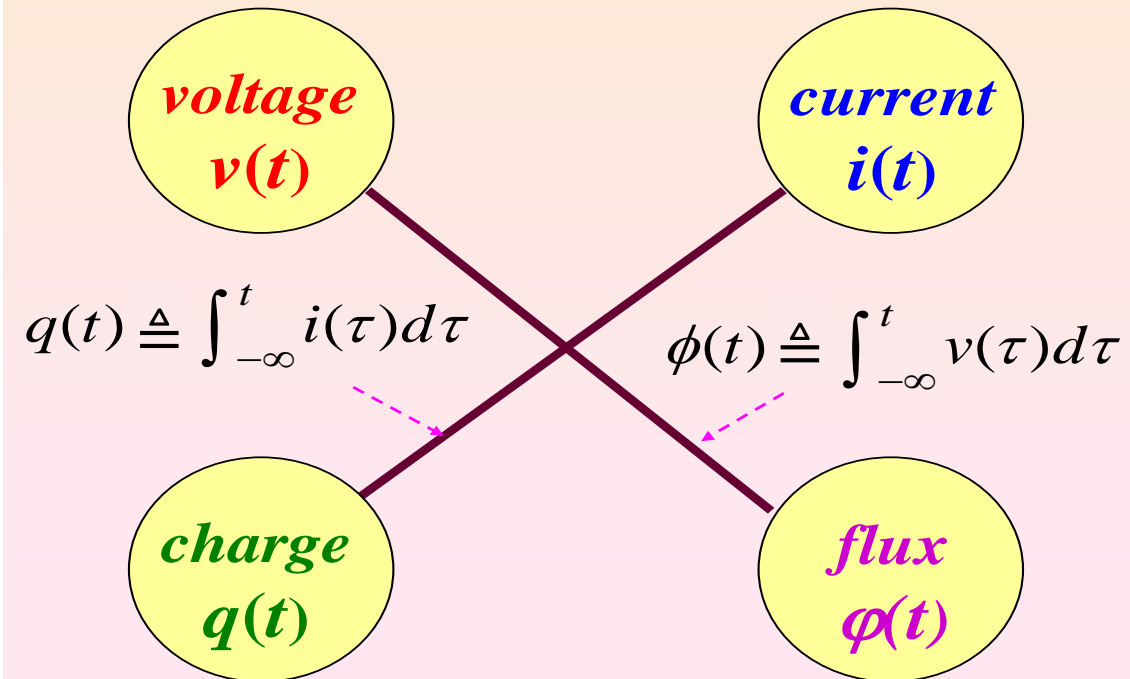
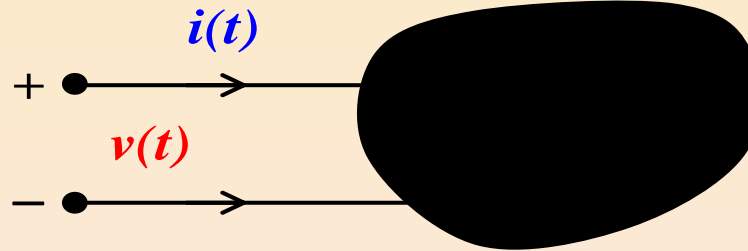
*via an*

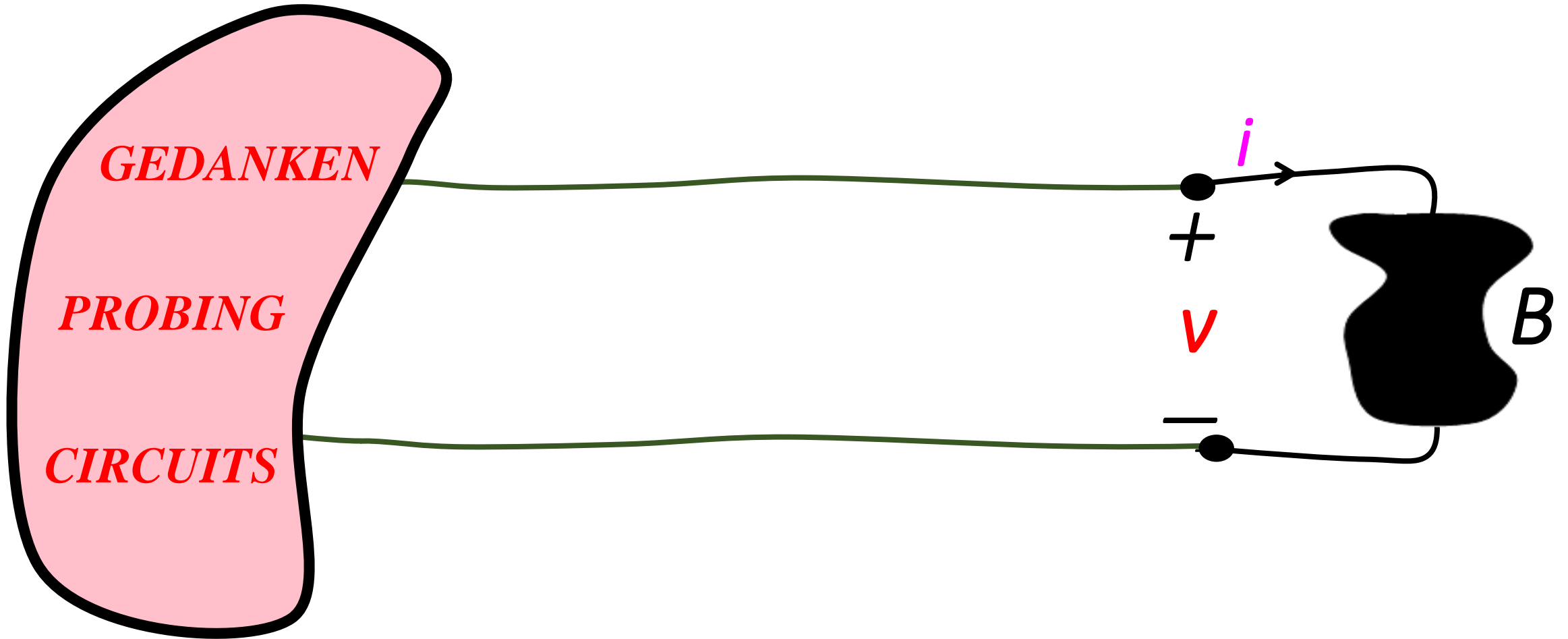
***AXIOMATIC APPROACH***

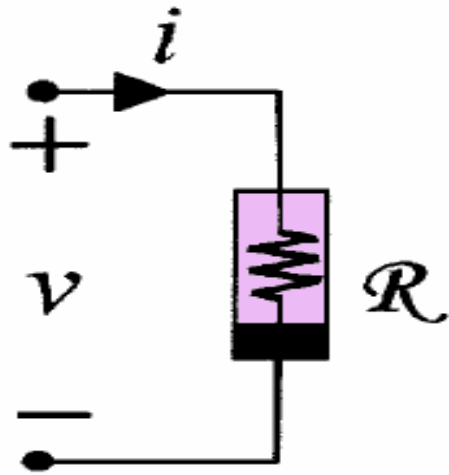


*All Results Derived  
from An  
Axiomatic Approach  
are  
Timeless !*

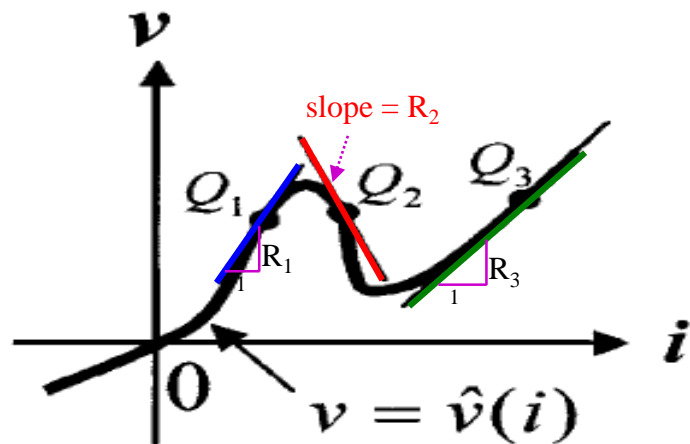
# Four Basic Circuit Variables







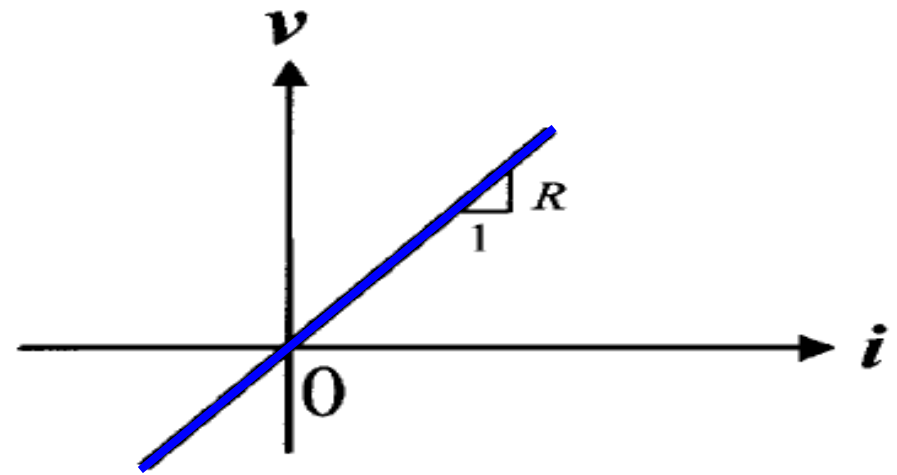
## Nonlinear Resistor $R$



Current-controlled Resistor:

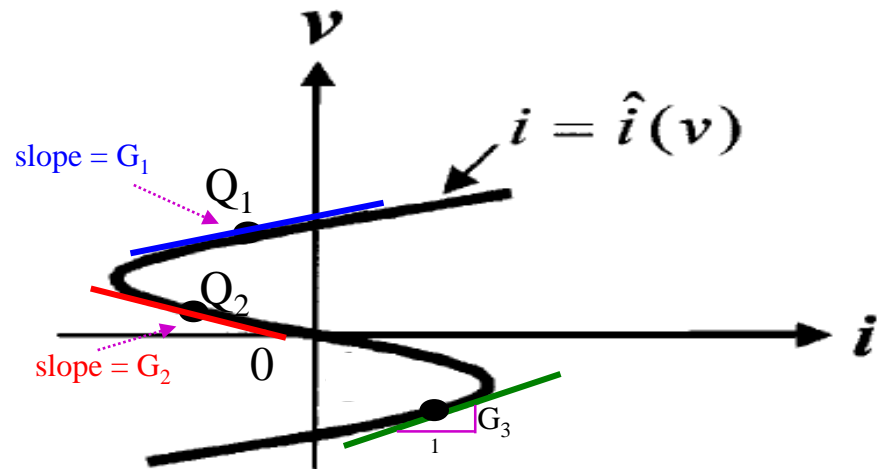
$R_i = \text{small-signal resistance at } Q_i$

$$v = \hat{v}(i)$$



Linear resistor:  $v = Ri$  or  $i = Gv$

$R = \text{Resistance}$ ,  $G \cong \frac{1}{R} = \text{Conductance}$



Voltage-controlled Resistor:

$G_i = \text{small-signal conductance at } Q_i$

$$i = \hat{i}(v)$$

*voltage, Volt V*

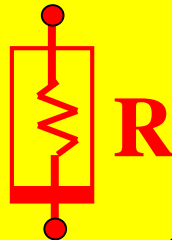
*current, Ampere A*

**RESISTOR**

*v*

*i*

$$R(v,i)=0$$



**R**

$$v = \frac{d\phi}{dt}$$

$$i = \frac{dq}{dt}$$

$$q \triangleq \int_{-\infty}^t i(\tau) d\tau$$

$$\phi \triangleq \int_{-\infty}^t v(\tau) d\tau$$

*q*

*φ*

*charge, Coulomb C*

*flux, Weber Wb*

voltage, Volt  $V$

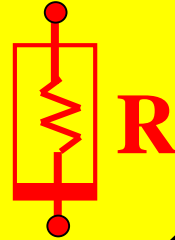
current, Ampere  $A$

$v$

$i$

**RESISTOR**

$$R(v, i) = 0$$



$R$

$$v = \frac{d\phi}{dt}$$

$$i = \frac{dq}{dt}$$

$q$

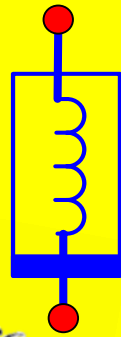
charge, Coulomb  $C$

$\phi$

flux, Weber  $Wb$

**INDUCTOR**

$L$



$L(\phi, i) = 0$

$$q \triangleq \int_{-\infty}^t i(\tau) d\tau$$

$$\phi \triangleq \int_{-\infty}^t v(\tau) d\tau$$

voltage, Volt  $V$

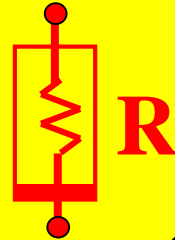
current, Ampere  $A$

**RESISTOR**

$v$

$i$

$$R(v, i) = 0$$



$R$

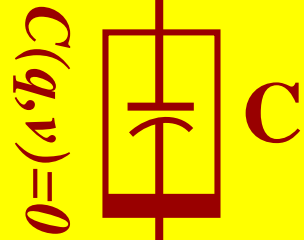
$$v = \frac{d\phi}{dt}$$

$$i = \frac{dq}{dt}$$

**CAPACITOR**

$q$

$\phi$



$C$

$$C(q, v) = 0$$

$$q \triangleq \int_{-\infty}^t i(\tau) d\tau$$

$$\phi \triangleq \int_{-\infty}^t v(\tau) d\tau$$

$L$

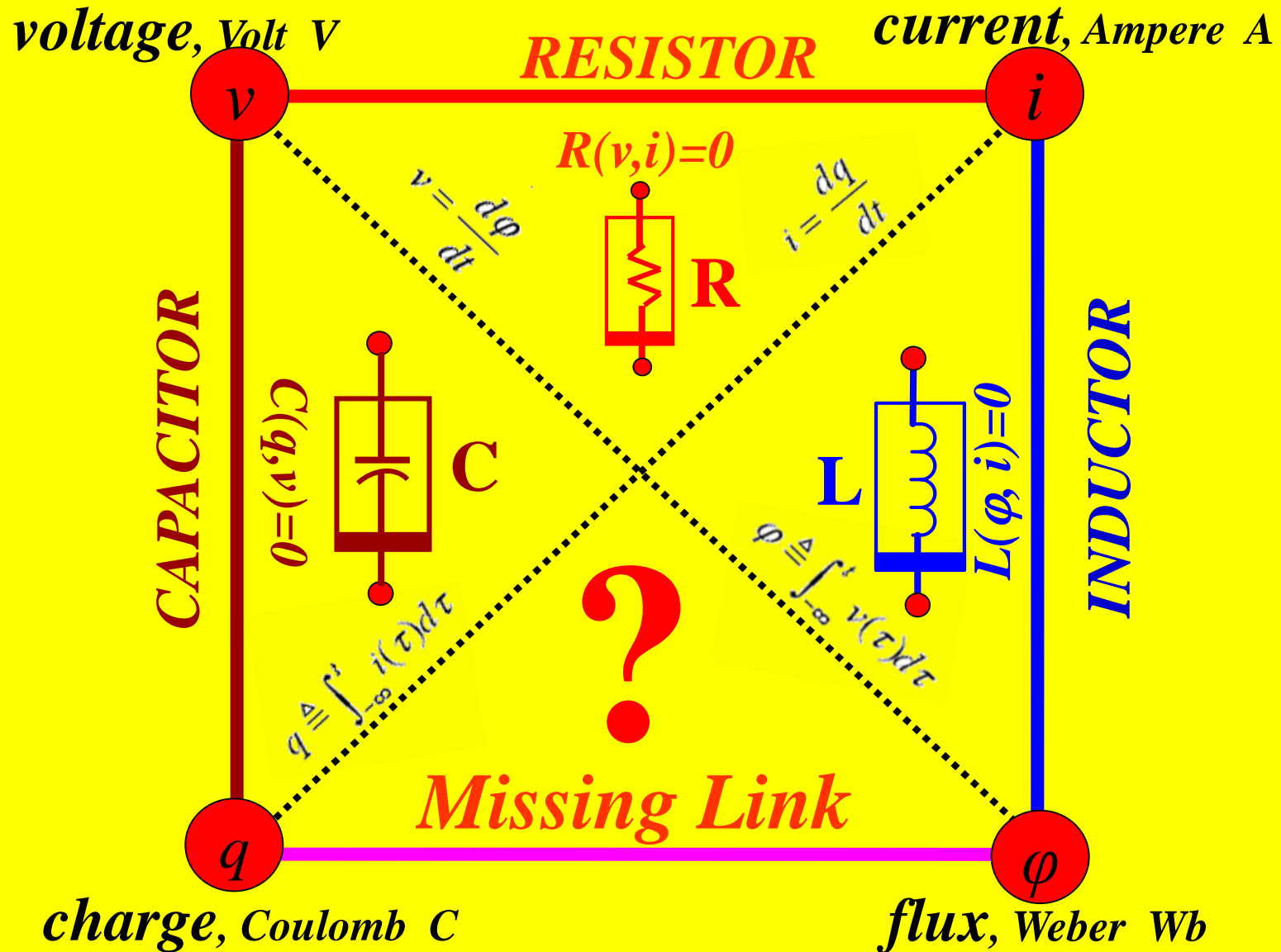
$$L(\phi, i) = 0$$

**INDUCTOR**

charge, Coulomb  $C$

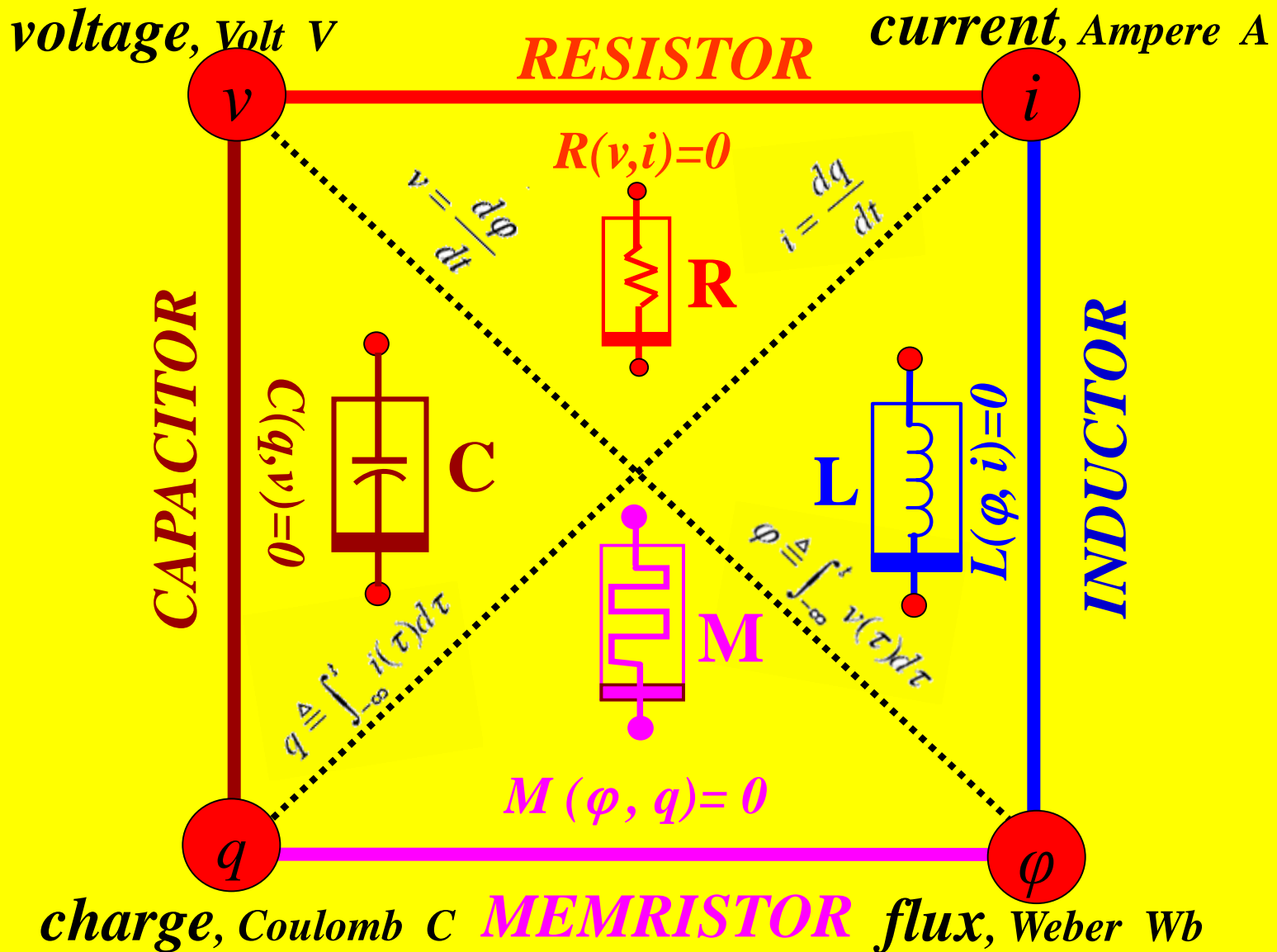
flux, Weber  $Wb$

# 4 Basic Circuit Elements

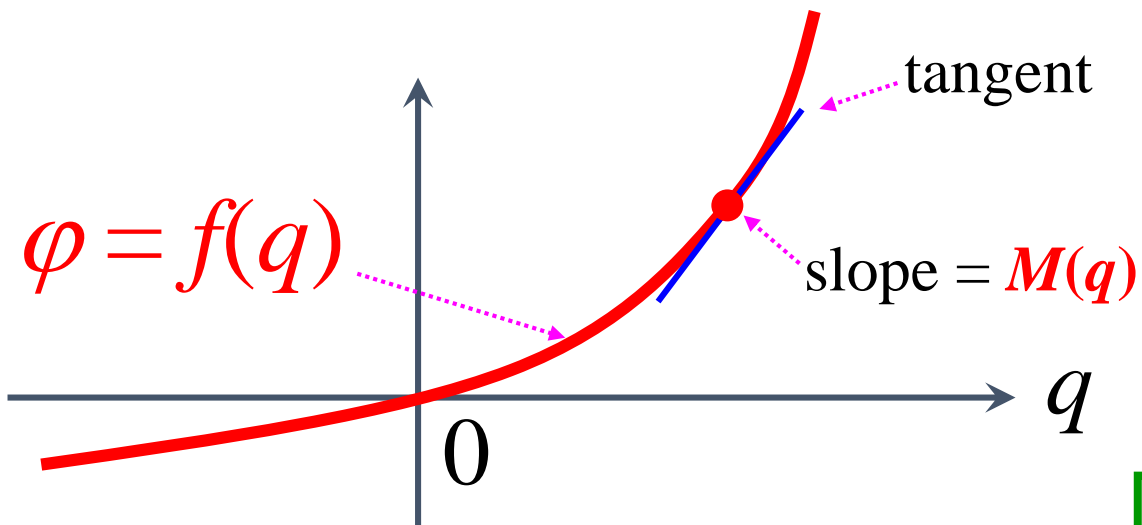
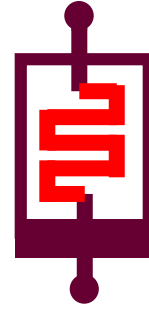




# 4 Basic Circuit Elements



# *Memristor*



$$\varphi = f(q)$$

$$v = \frac{d\varphi}{dt} \equiv \underbrace{\frac{df(q)}{dq}}_{M(q)} \underbrace{\frac{dq}{dt}}_i$$

$$v = M(q) i$$

$M(q)$  is called the *Memristance*.

# *A Fourth Basic Element*

Called the

## *Memristor*

was postulated in **1971**

*Leon O. Chua*

Memristor : The missing circuit element

*IEEE Transactions on Circuit Theory*, vol.18, no.5, p.507-519,  
1971.

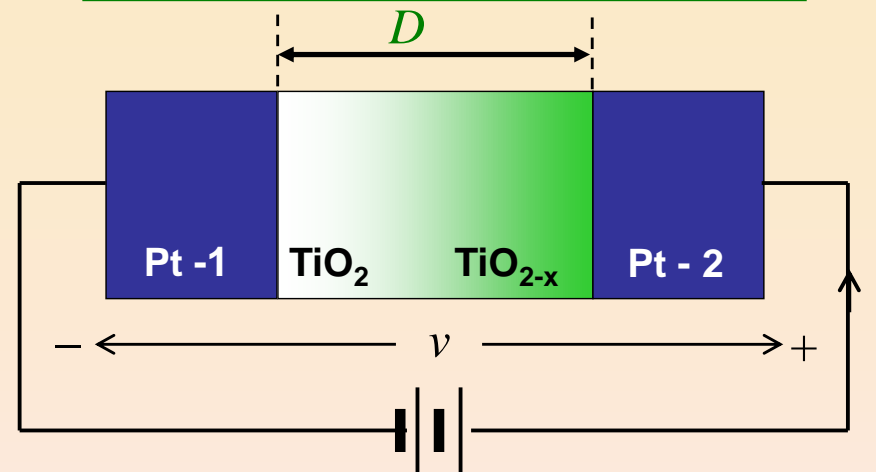
and found in **2008**

D. B. Strukov, G. S. Snider, D. R. Stewart, and R. S. Williams

The Missing Memristor Found

*Nature*, vol.453, p.80-83,2008.

## HP Memristor



$$v = M(q) i$$

Memristance

$$M(q) \square R_{OFF} \left( 1 - \frac{\mu_v R_{ON}}{D^2} q \right)$$

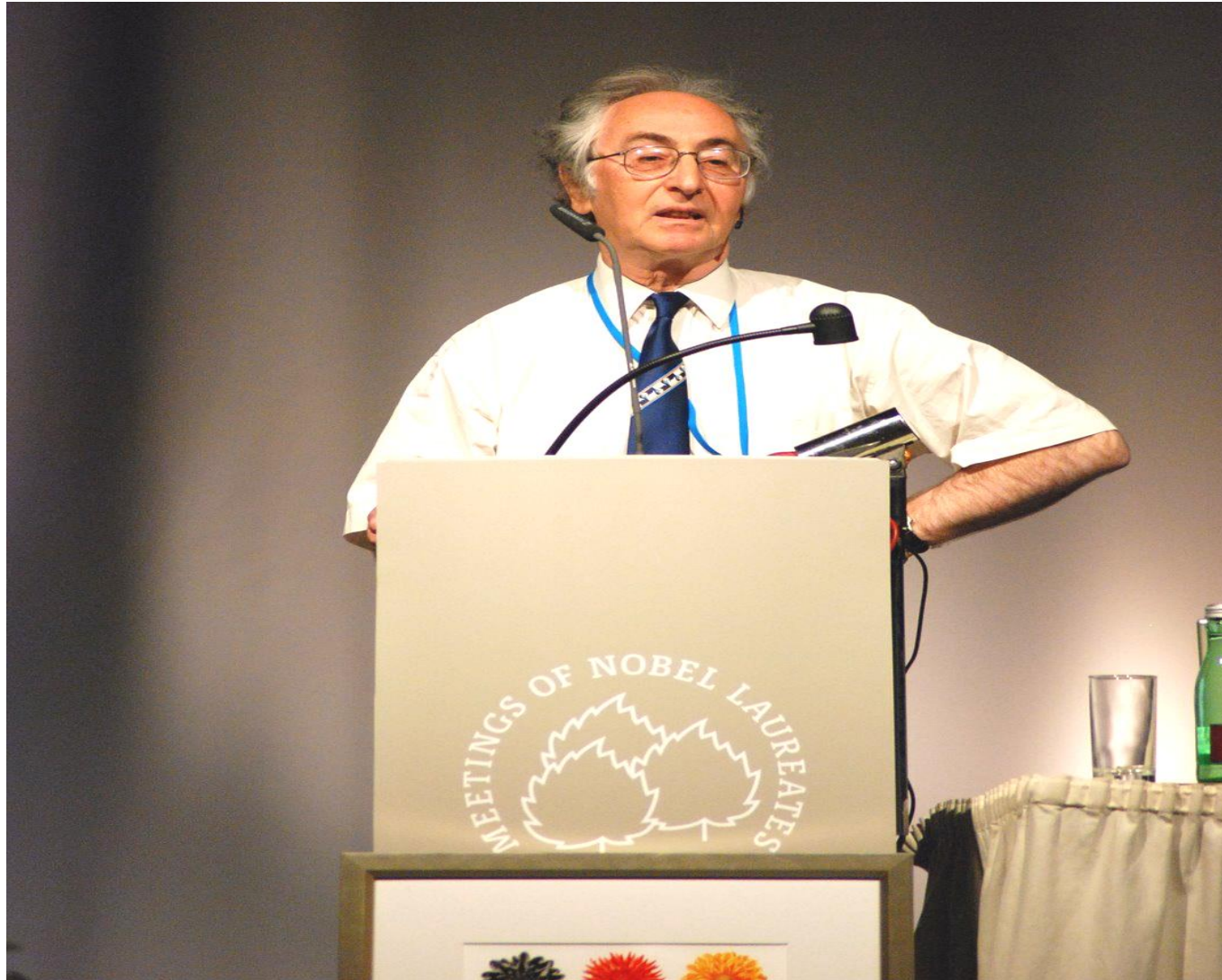
where

$D$  is the device thickness (can be scaled to less than 2 nano meters)

$R_{OFF}$ ,  $R_{ON}$ ,  $\mu_v$  are device parameters

*Memristor*  
*is defined by a*  
*State - Dependent*  
*Ohm's Law*

*1973  
Nobel  
Prize  
in  
Physics*

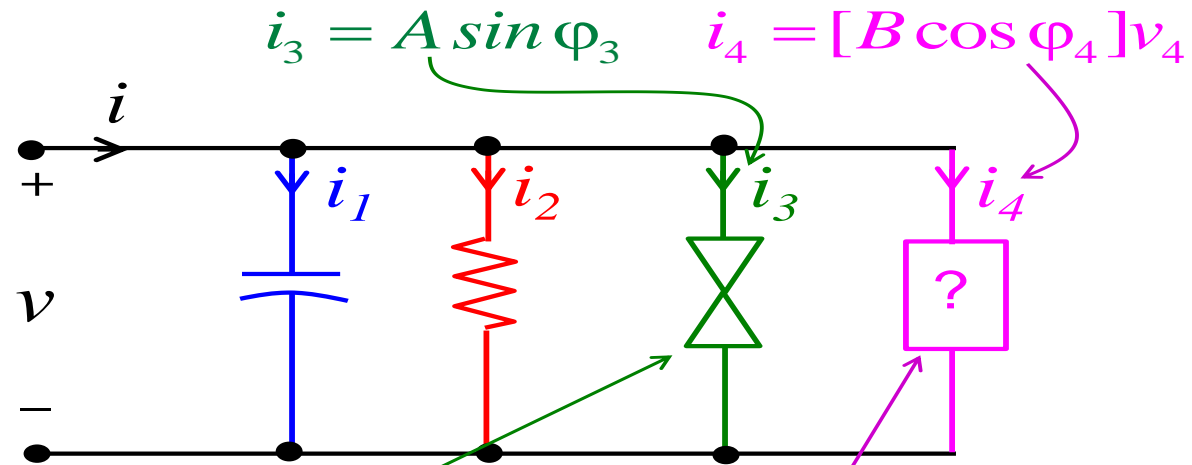


*Discovers  
Super-  
conducting  
Josephson  
tunneling  
junctions*

**B. D. Josephson**

Brian Josephson  
1973 Nobel Prize in Physics:

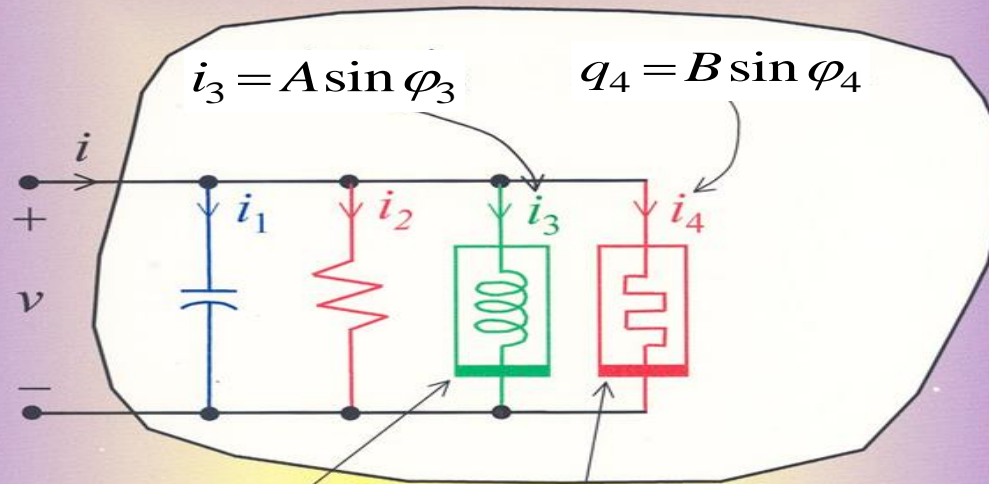
# JOSEPHSON JUNCTION CIRCUIT MODEL



2-terminal element to model the Josephson Pair-tunneling current

2-terminal element to model the Quasi-Particle Pair interference current

# JOSEPHSON JUNCTION CIRCUIT MODEL

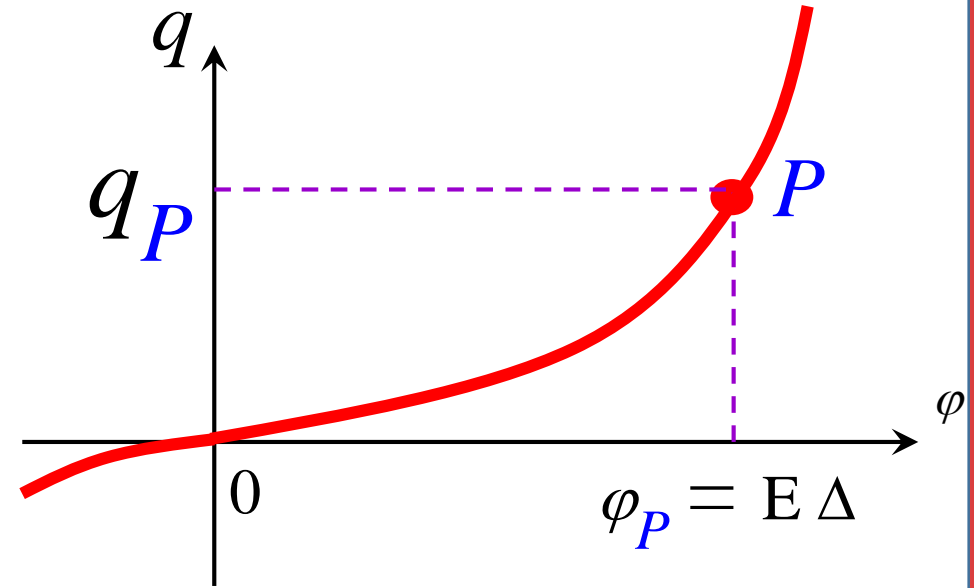
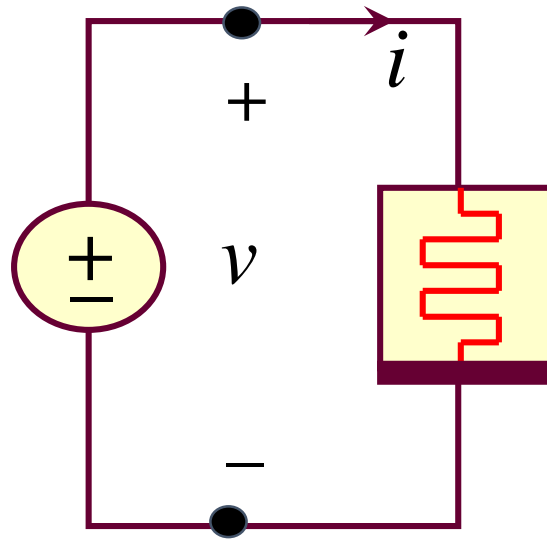
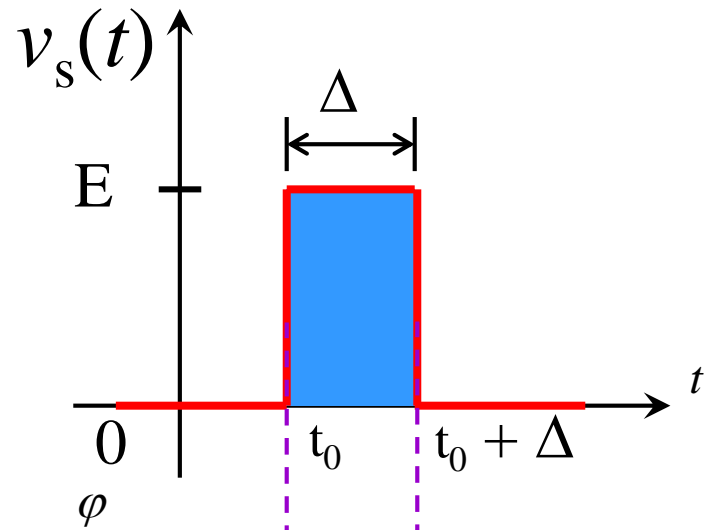


Nonlinear Inductor  
models the Josephson  
Superconducting Pair-  
tunneling current

Memristor models the  
Quasi-Particle Pair  
interference current

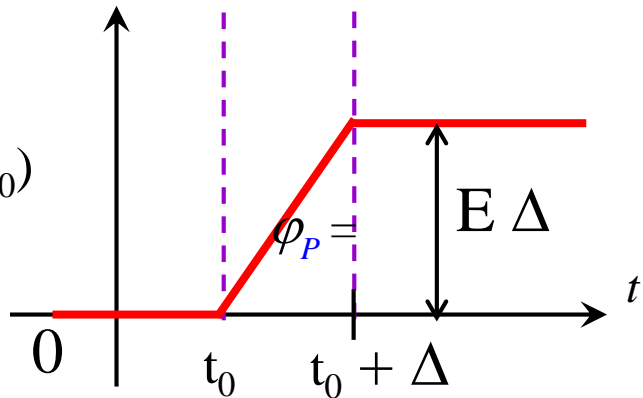


# Why is the Memristor Non-Volatile ?



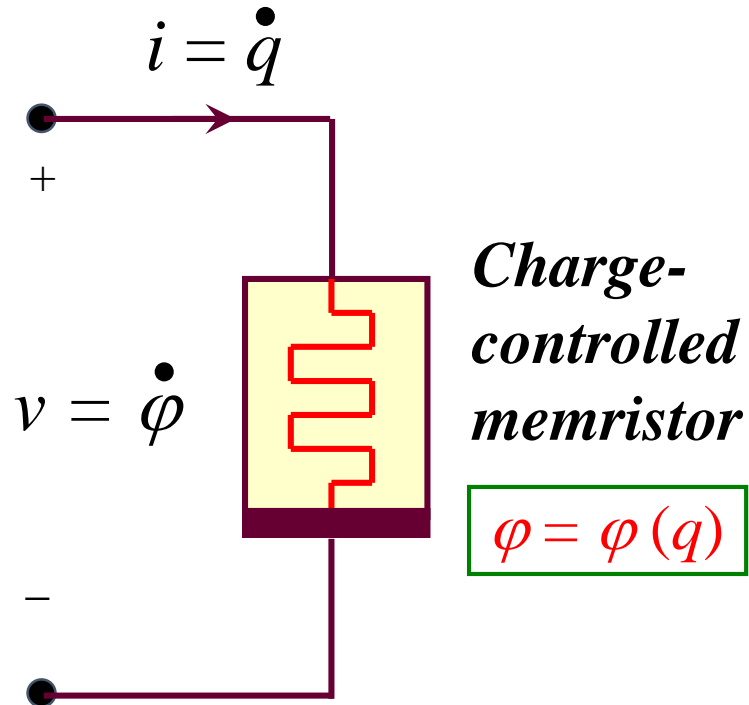
Assume

$$\varphi_0 \cong \varphi(t_0) = 0$$



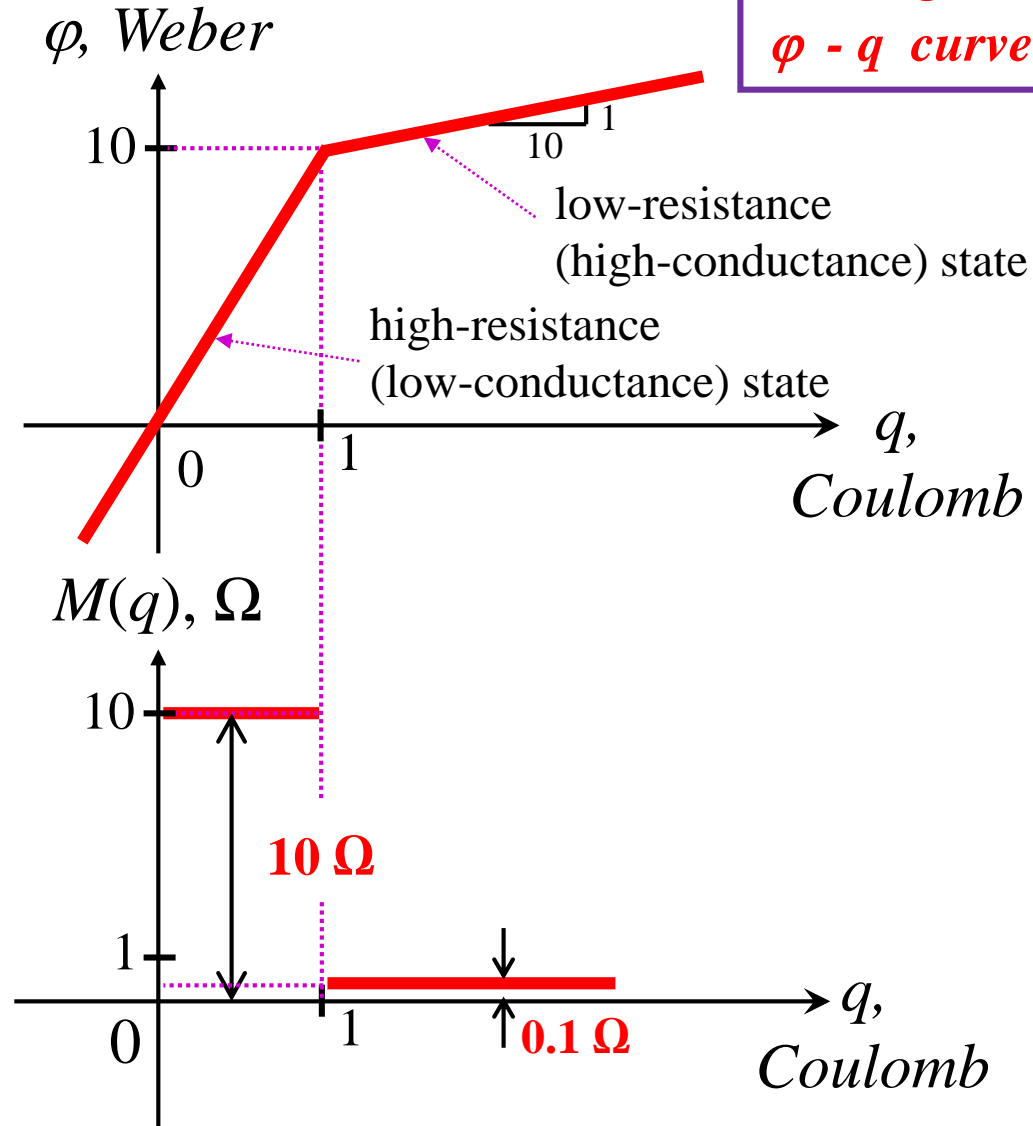
$$\varphi(t) = \varphi_0 + \int_{t_0}^t v(\tau) d\tau$$

# Example: A two-state Charge-Controlled Memristor



**Memristance**

$$M(q) \triangleq \frac{d\varphi}{dq}$$



**Charge - controlled  $\varphi - q$  curve :  $\varphi = \varphi(q)$**

*Non-volatile memories*

**are estimated to be a**

*400 billion dollar*

**Industry by 2020 !**

*Imagine a PC which turns on  
instantly !*

# *Why not Flash ?*

- *Can not* be economically scaled *below 10 nanometers*
- Poor Retention time: *Fails* after switching between *10,000 and 100,000 times*
- Low Speed
- Power Hungry
- They lose about *20 percent* of information for *decade*.



*Non-Volatile Nano Memristors  
will eventually replace the following conventional  
computer memories*

• *Flash Memories*



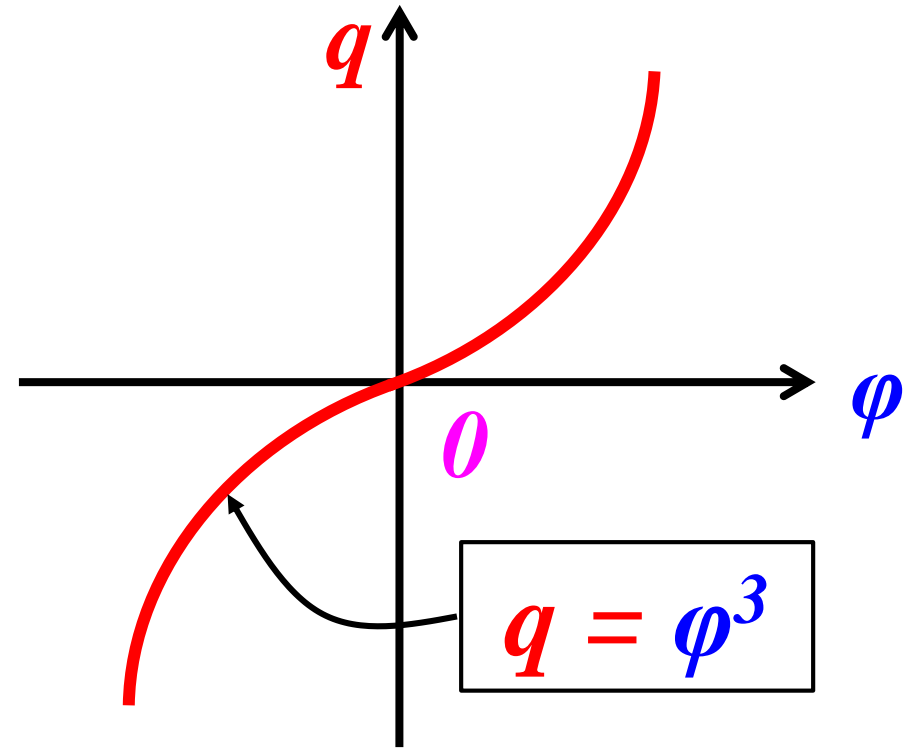
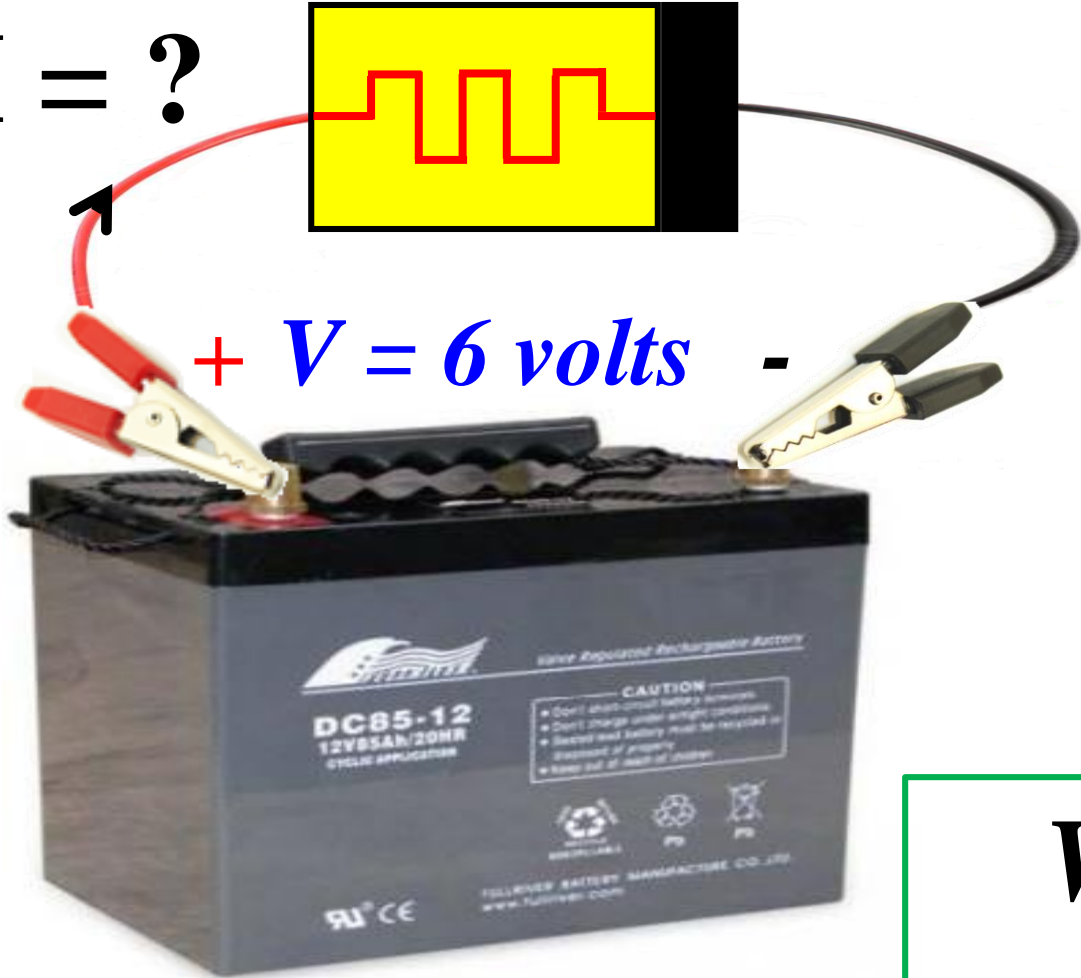
• *DRAMs*



• *Hard Drives*

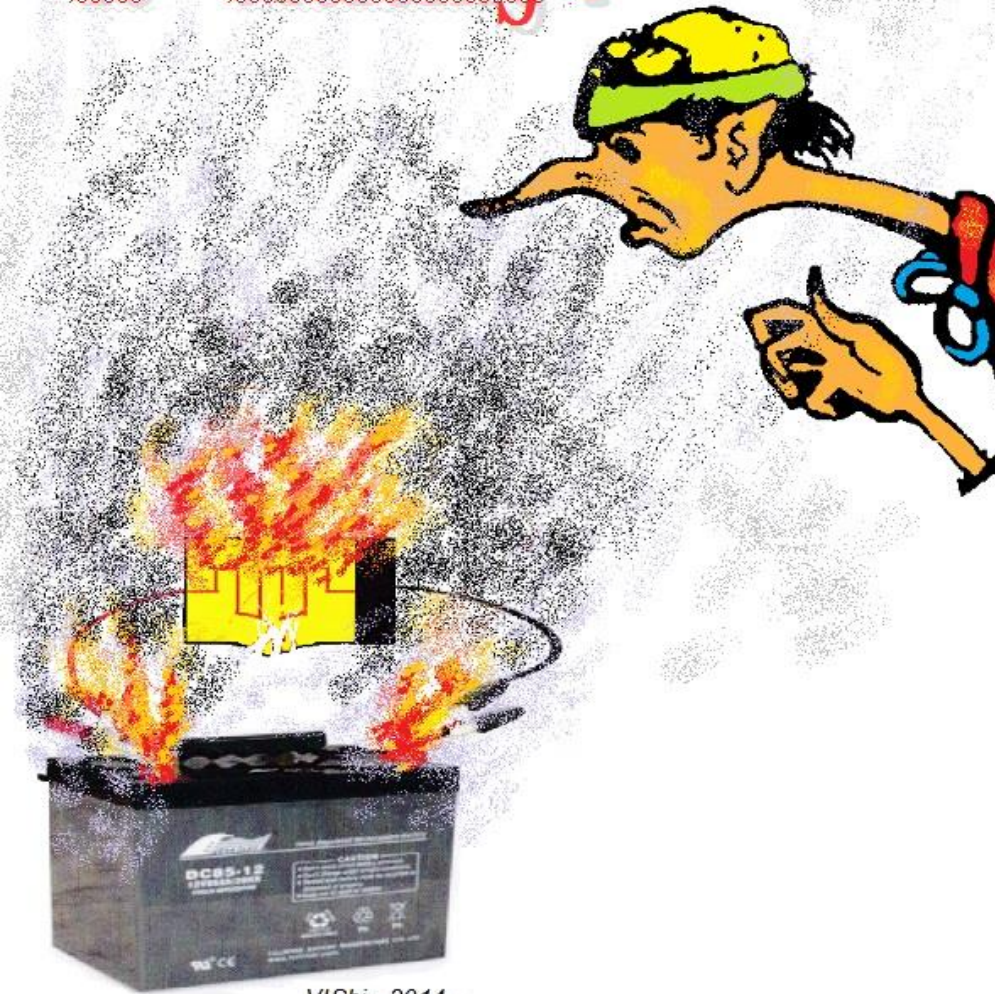


$I = ?$

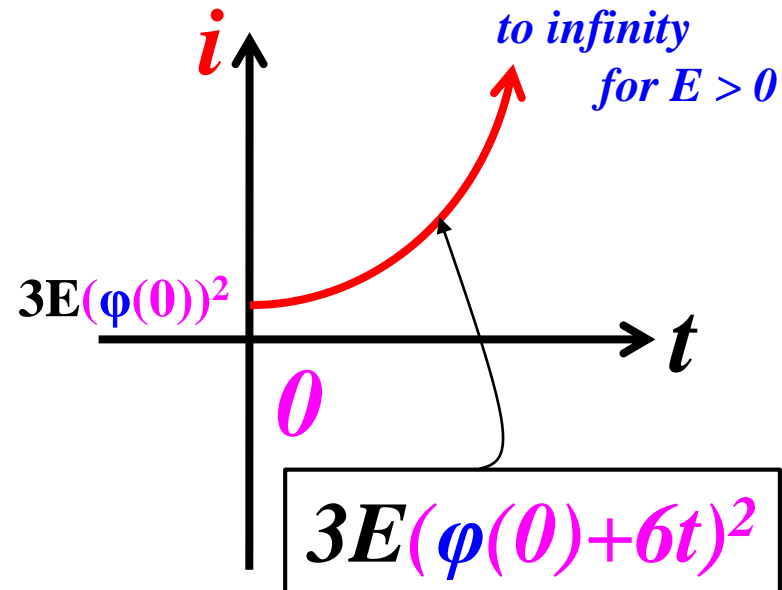
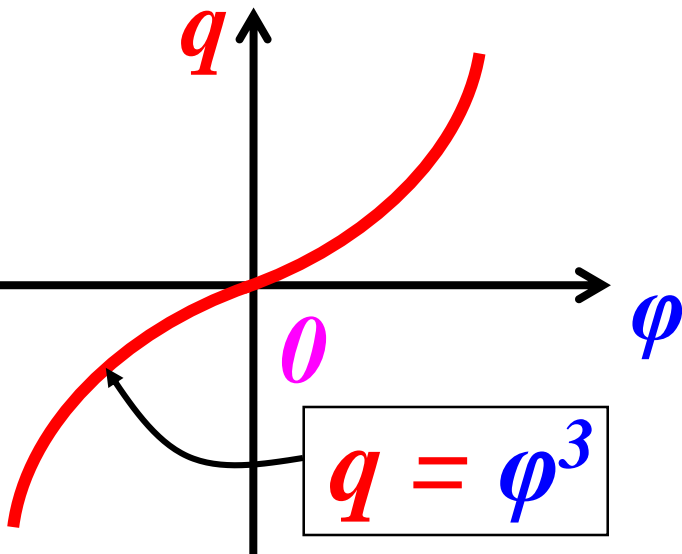
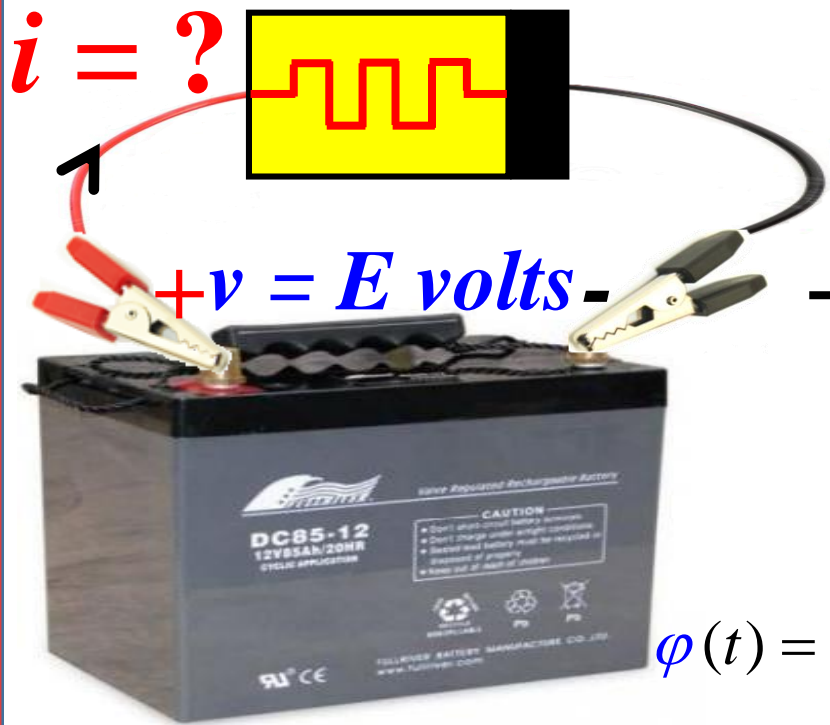


What *happen* when you connect a *Memristor* across a *battery* ?

# My Memristor is Melting!



VISbi 2014



$$\varphi(t) = \varphi(0) + \int_0^t v(\tau) d\tau$$

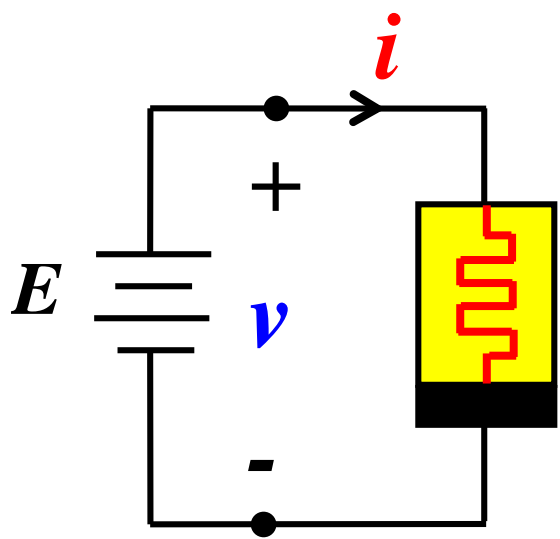
$$= \varphi(0) + Et$$

$$q(t) = (\varphi(0) + Et)^3$$

$$i(t) = \frac{dq(t)}{dt} = 3(\varphi(0) + Et)^2 (E)$$

$$= 3E(\varphi(0) + Et)^2$$

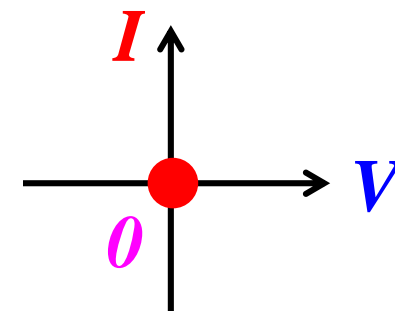
$$\rightarrow \infty \text{ as } t \rightarrow \infty$$



**Shocking Truth !**

The DC V-I curve consists of only one point

$$(V, I) = (0, 0).$$





*The*  
*Ideal Memristor*  
*does not have a*  
*DC V-I Curve !*

# *Standing Assumption*

All *state variables*  $x_i$  in the *state equation*

$$\dot{\mathbf{x}} = \mathbf{f}(\mathbf{x}, v) \quad (\text{Voltage-Controlled Memristor})$$

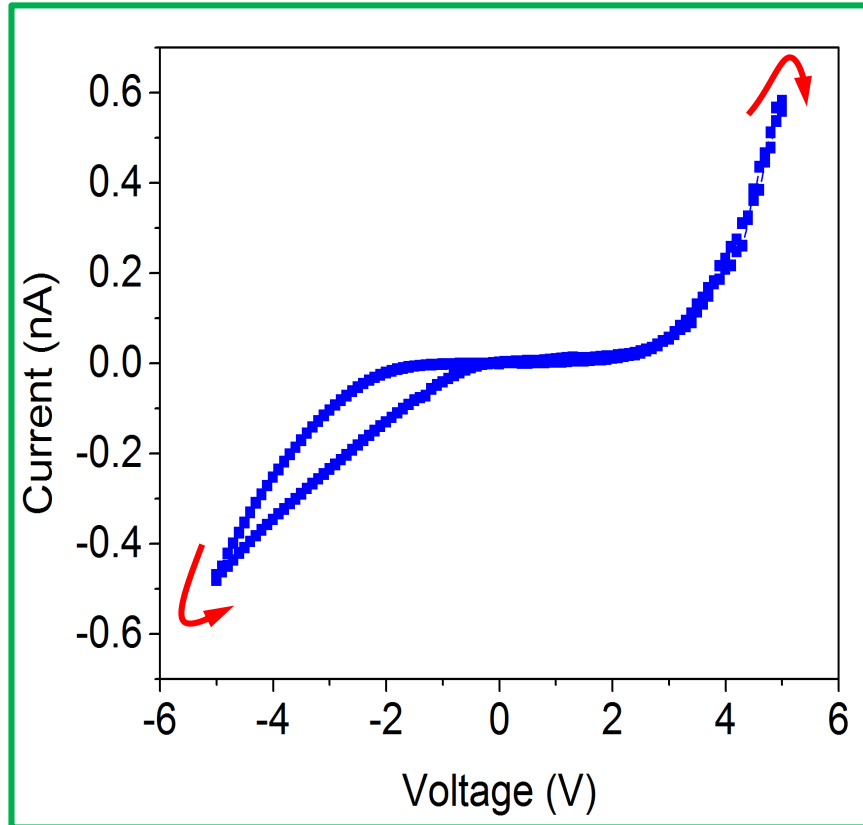
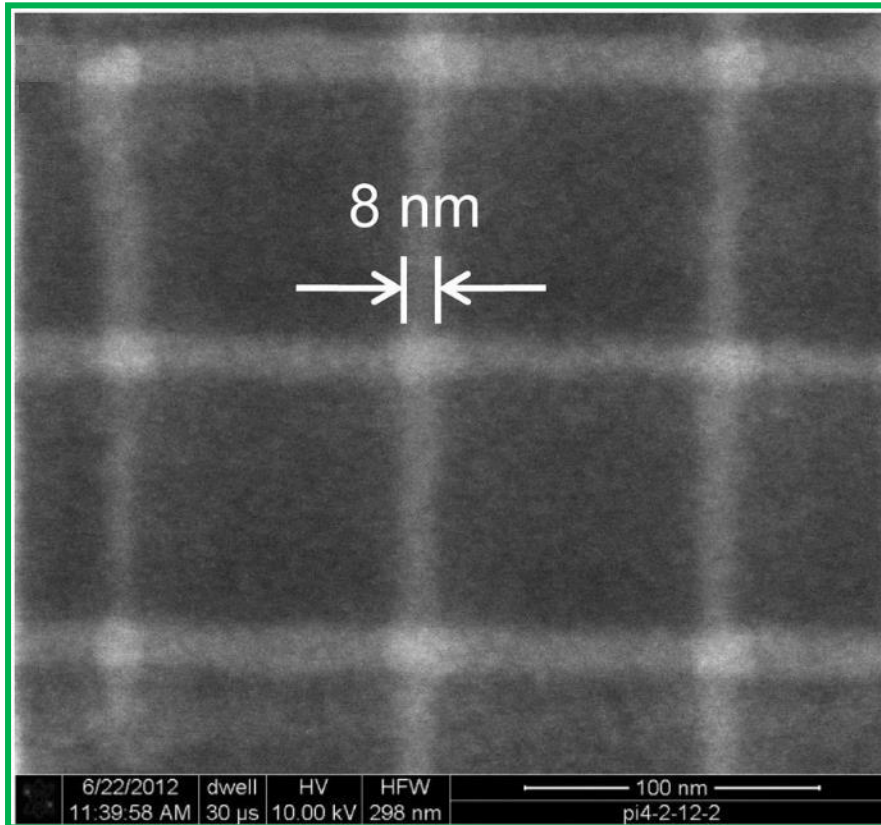
or

$$\dot{\mathbf{x}} = \mathbf{f}(\mathbf{x}, i) \quad (\text{Current-Controlled Memristor})$$

have *infinite* range:

$$-\infty < x_i < \infty$$

# An 8 nm Memristor



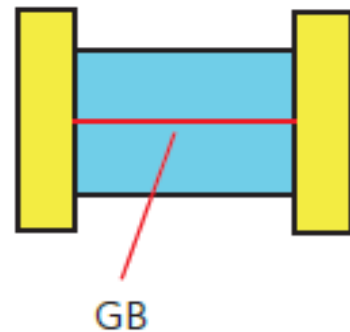
*From:*

*S. Pi, P. Lin, Q. Xia, "Cross point arrays of 8 nm × 8 nm memristive devices fabricated with nano imprint lithography", J. Vac. Sci. Technol. B 31, 06FA02-1 - 06FA02-6, 2013*

# Memristor

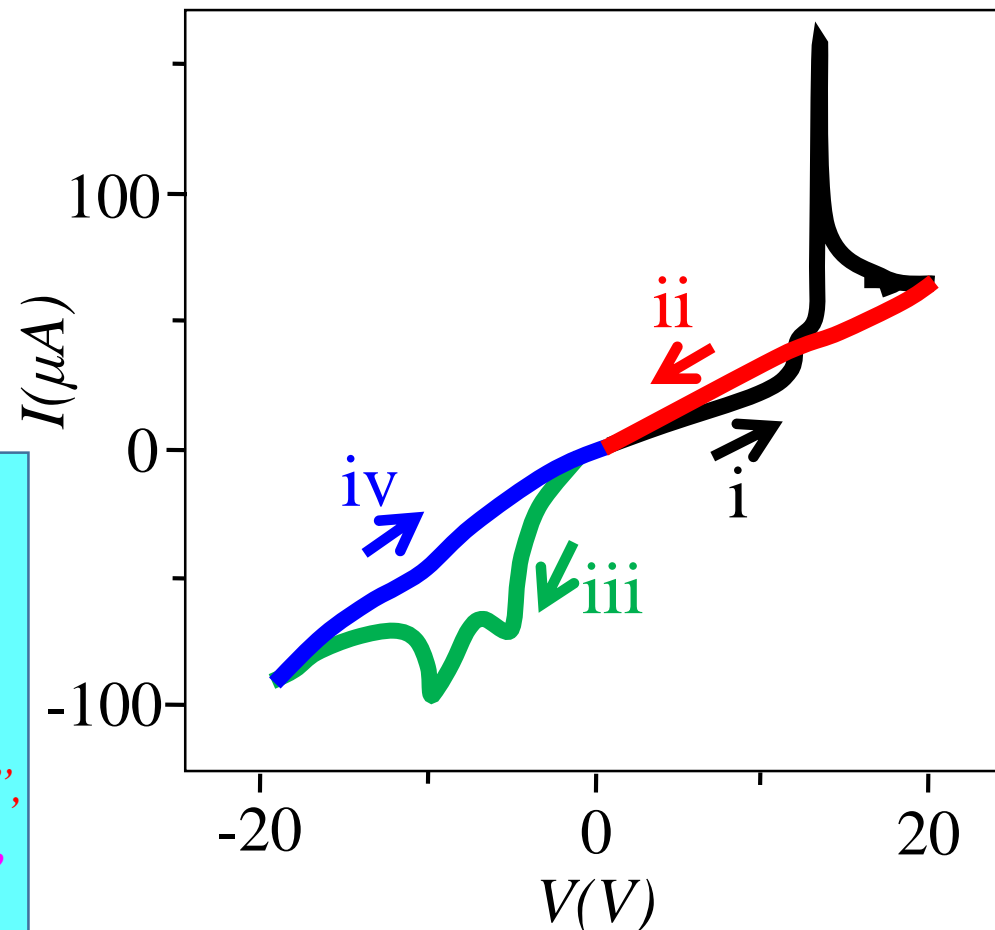
made from

A single Layer of the Molecule  $\text{MoS}_2$



**From:**

V. K. Sangwan, D. Jariwala, I. S. Kim,  
K. S. Chen, T. J. Marks, L. J. Lauhon,  
M. C. Hersam, "Gate-tunable  
memristive phenomena mediated by  
grain boundaries in single-layer  $\text{MoS}_2$ ",  
*Nature Nanotechnology* 10, p. 403-406,  
2015



# How Do You Know Your *Device is a Memristor ?*

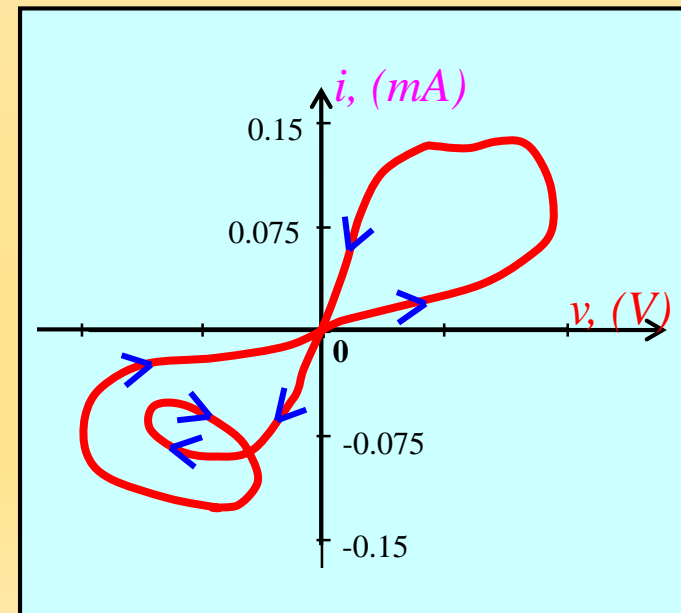
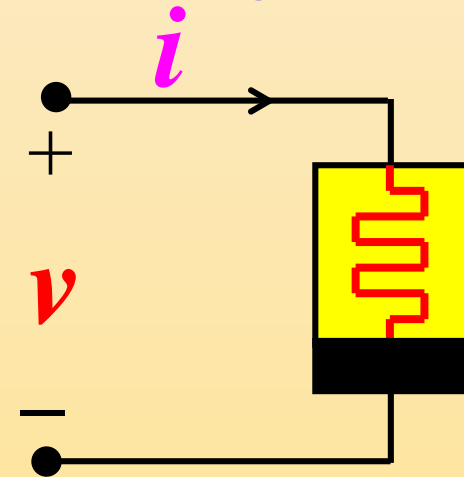
Since *hp*'s 2008 publication in *Nature* of a *nano-scale memristor*, numerous other *memristors* have been published.

*Less than 5* such publications have an *equation* describing their device !

*How then can they claim their  
device are memristors ?*

# *Experimental Definition of the* **Memristor**

*If it's Pinched,*  
*it's a*  
**Memristor**



# Genealogy of Memristors

## Extended Memristor

*Voltage – Controlled*

$$i = G(x, v)v$$

$$G(x, 0) \neq \infty$$

$$\frac{dx}{dt} = g(x, v)$$

## Generic Memristor

*Voltage – Controlled*

$$i = G(x)v$$

$$\frac{dx}{dt} = g(x, v)$$

## Ideal Generic Memristor

*Voltage – Controlled*

$$i = G(x)v$$

$$\frac{dx}{dt} = \hat{g}(x)v$$

## Ideal Memristor

*Voltage – Controlled*

$$i = G(\varphi)v$$

$$\frac{d\varphi}{dt} = v$$

# The Memristor Universe

## EXTENDED MEMRISTOR

$$v = R(x, i) i$$
$$R(x, 0) \neq \infty$$

$$\frac{dx}{dt} = f(x, i)$$

## GENERIC MEMRISTOR

$$v = R(x) i$$

$$\frac{dx}{dt} = f(x, i)$$

## IDEAL GENERIC MEMRISTOR

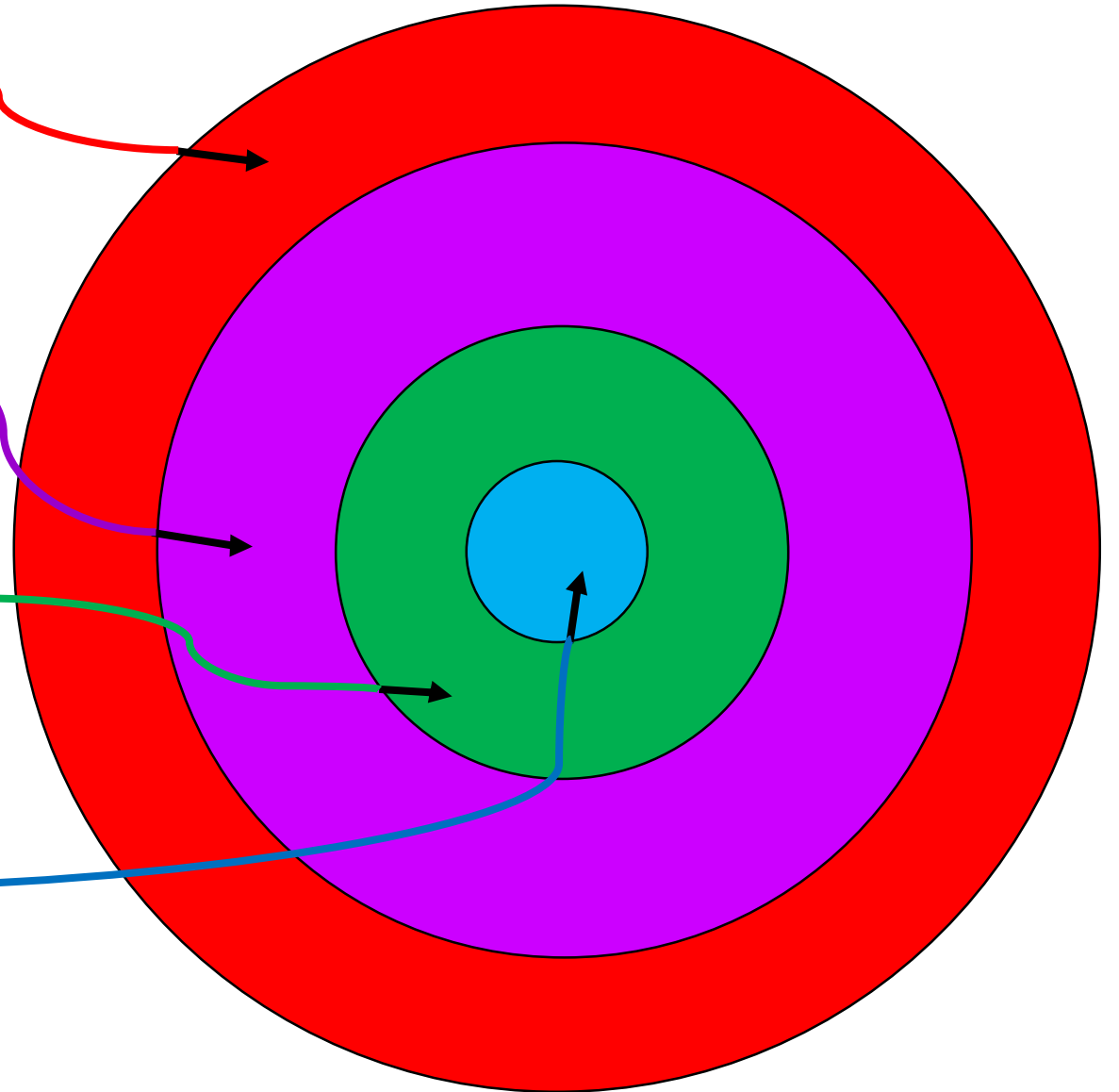
$$v = R(x) i$$

$$\frac{dx}{dt} = \hat{f}(x) i$$

## IDEAL MEMRISTOR

$$v = R(q) i$$

$$\frac{dq}{dt} = i$$





Every  
Ideal Memristor  
spawns an  
Infinite family  
of  
**Equivalent**  
Generic Memristor  
Siblings

# Ideal Memristor Cousins

All *Generic* and *Extended*  
Memristors are  
*Qualitatively Identical* to  
Ideal memristors

*All*  
*Non-volatile Memories*  
*based on*  
*Resistance Switchings*  
*are*  
*Memristors*

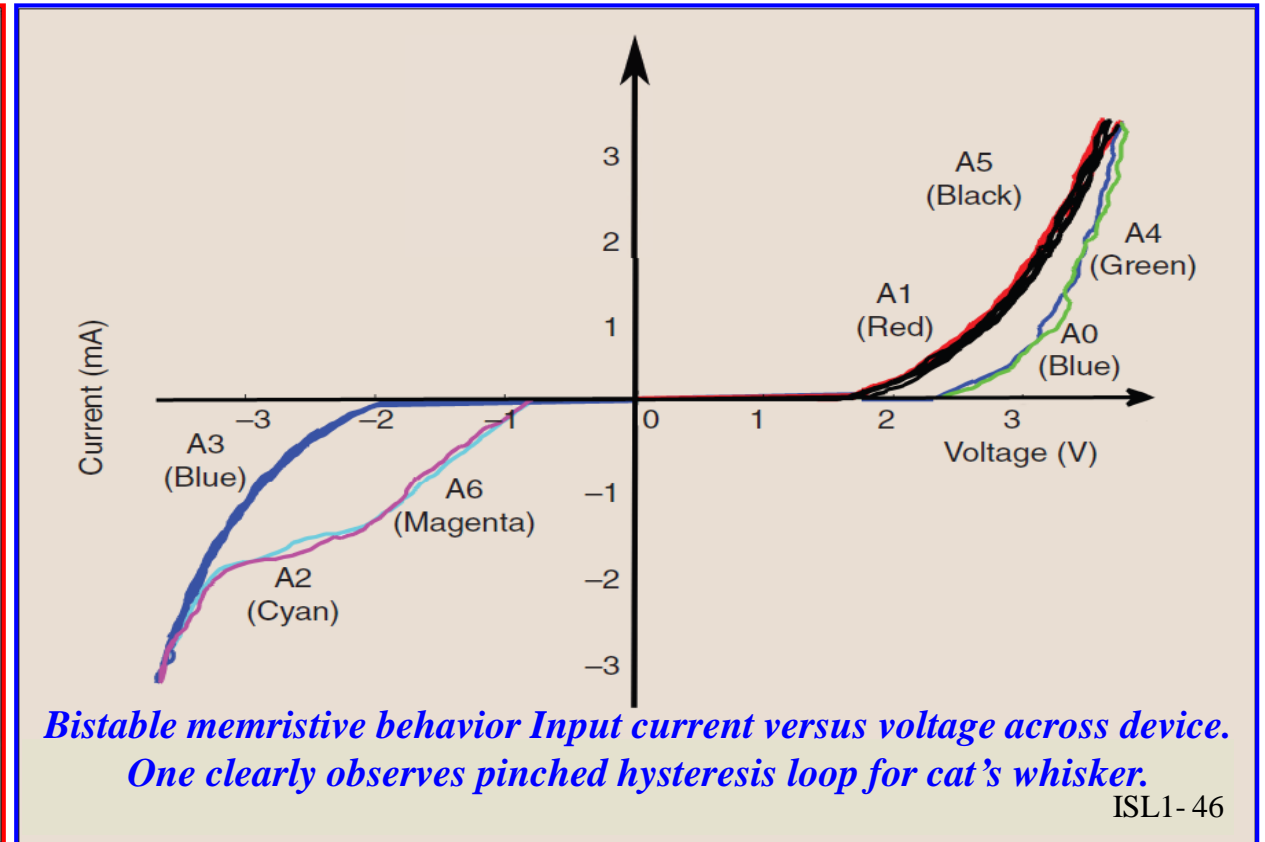
*Following*  
*non-volatile memory devices*  
*are*  
*memristors*

- *Re RAMS*
- *Phase Change Memories*
- *MRAMS*
- *Ferro-Electric Non-volatile Memories*
- *Atomic Switch*

# Examples of *Non-Volatile Memristors*

- **RRAM *Memristors*** (metal oxides  $\text{TiO}_2$ ,  $\text{TaO}_x$ , etc.)
- **Polymeric *Memristors*** (conducting polymers)
- **Ferroelectric *Memristors*** (Ferroelectric films)
- **Manganite *Memristors*** (Perovskite manganite)
- **Spintronic *Memristors*** (spin-transfer torque magnetic layers)

# *Cat's Whisker from the First Radios are Memristors*



# A Natural Silk Fibroin Protein-Based Transparent Bio-Memristor

Mrinal K. Hota, Milan K. Bera, Banani Kundu, Subhas C. Kundu, and Chinmay K. Maiti



Cocoons of mulberry silkworm



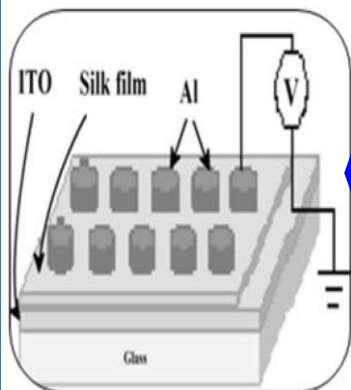
Cut pieces of cocoons



Degumming: removal of protein sericin



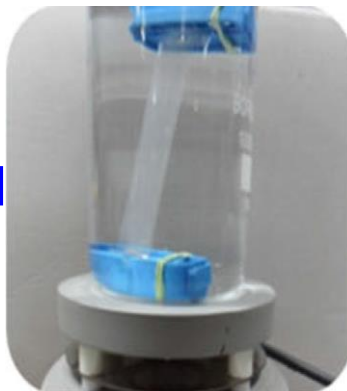
Degummed fibre of protein fibroin



Device Structure



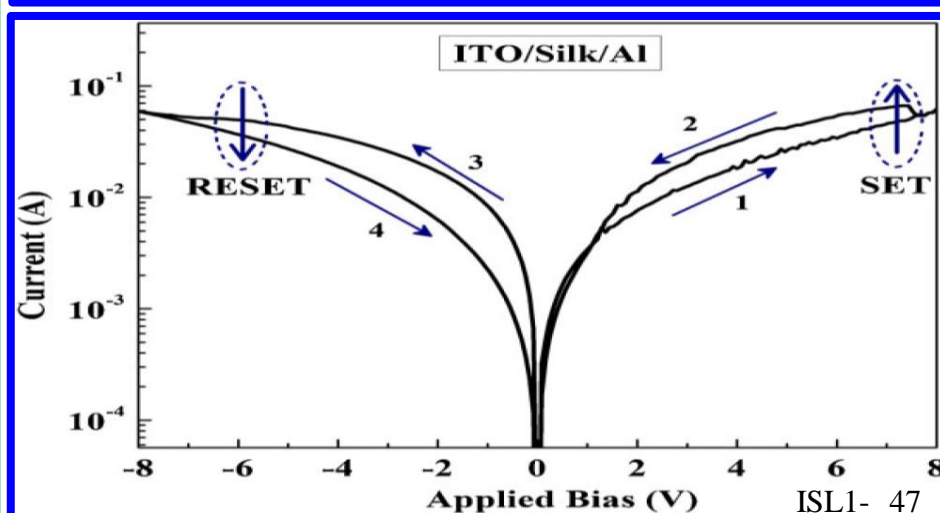
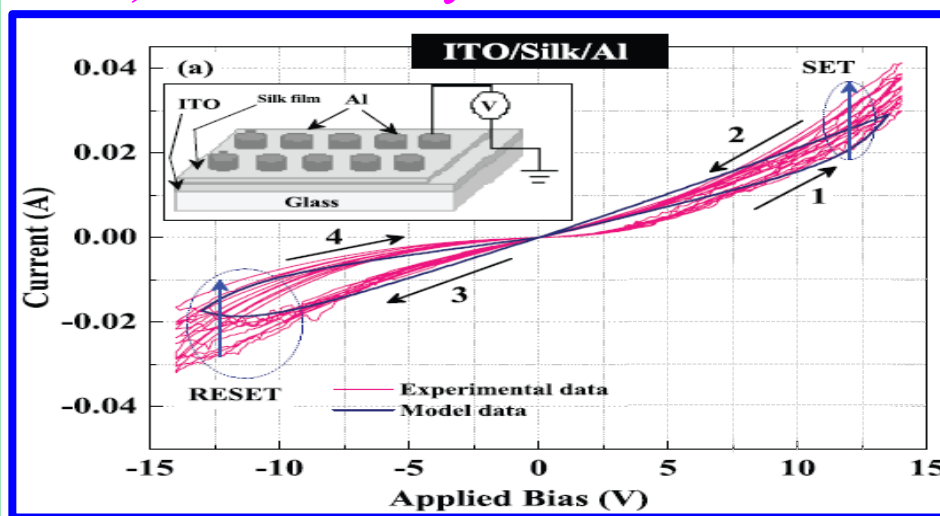
Fibroin solution (conc. 2% w/v)



Thorough dialysis of fibroin solution to remove excess LiBr



Dissolved fibre in 9.3 M LiBr



*Pinched hysteresis loop in the  $i - v$  plane resembles  
a seagull-wing in the  $\log |i| - v$  plane*

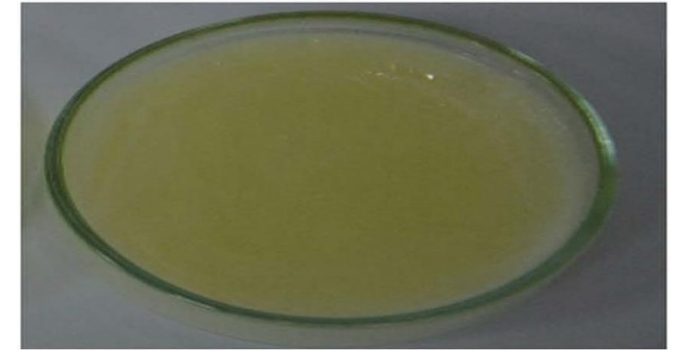
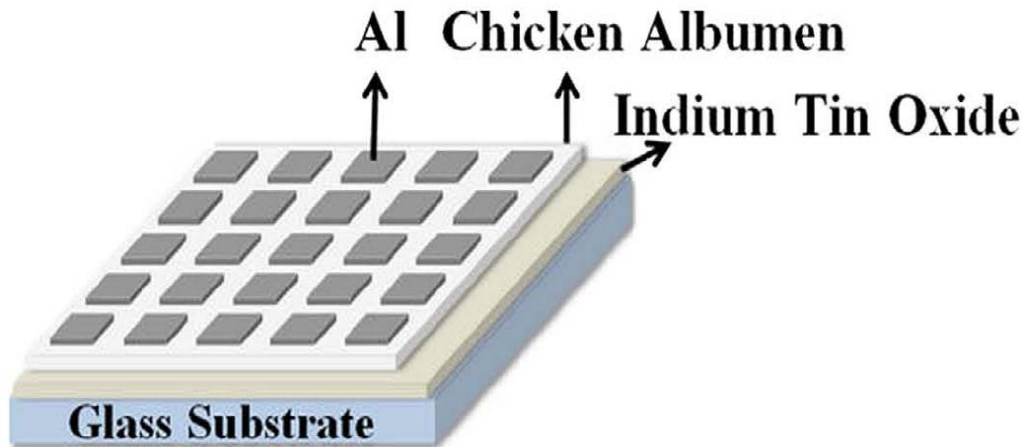




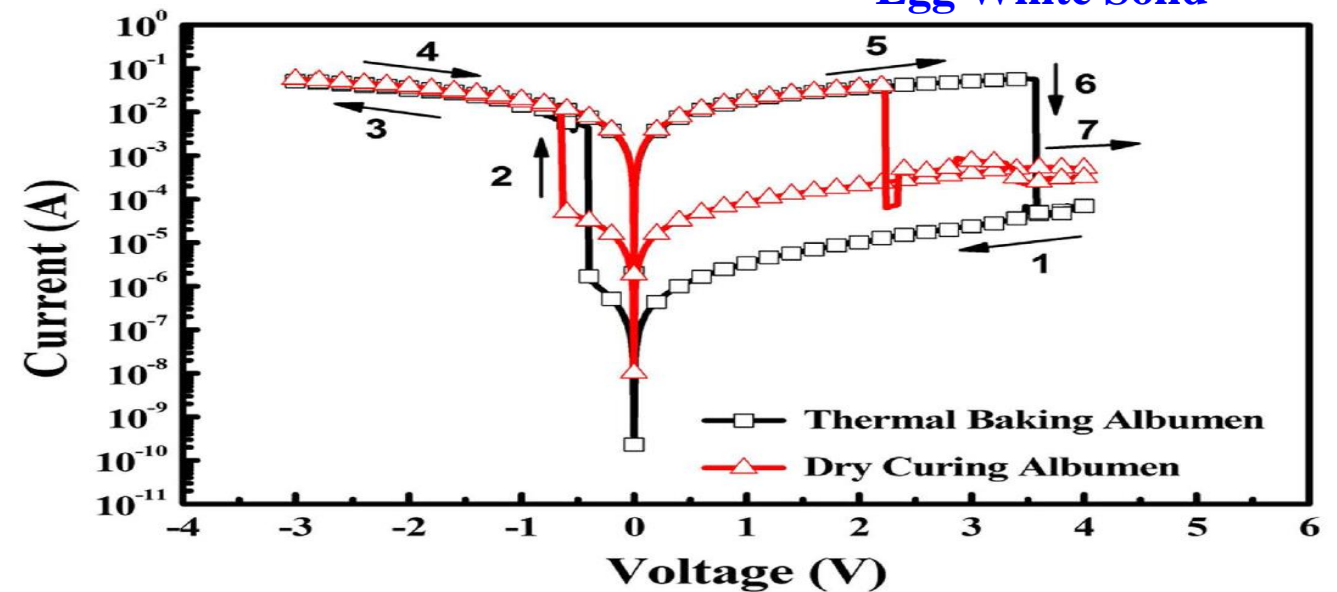
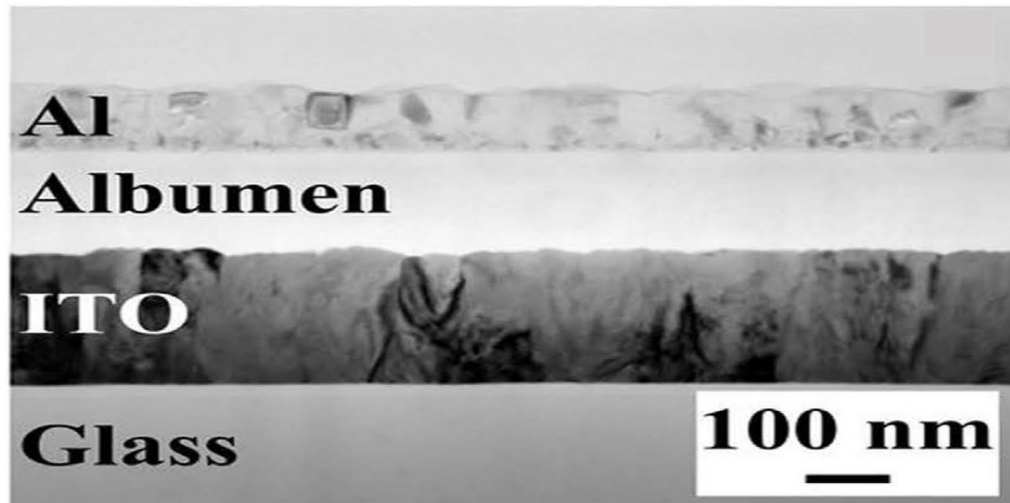


# Nonvolatile Bio-Memristor Fabricated with Egg Albumen Film

Ying-Chih Chen, Hsin-Chieh Yu, Chun-Yuan Huang, Wen-Lin Chung, San-Lein Wu & Yan-Kuin Su



Egg White Solid



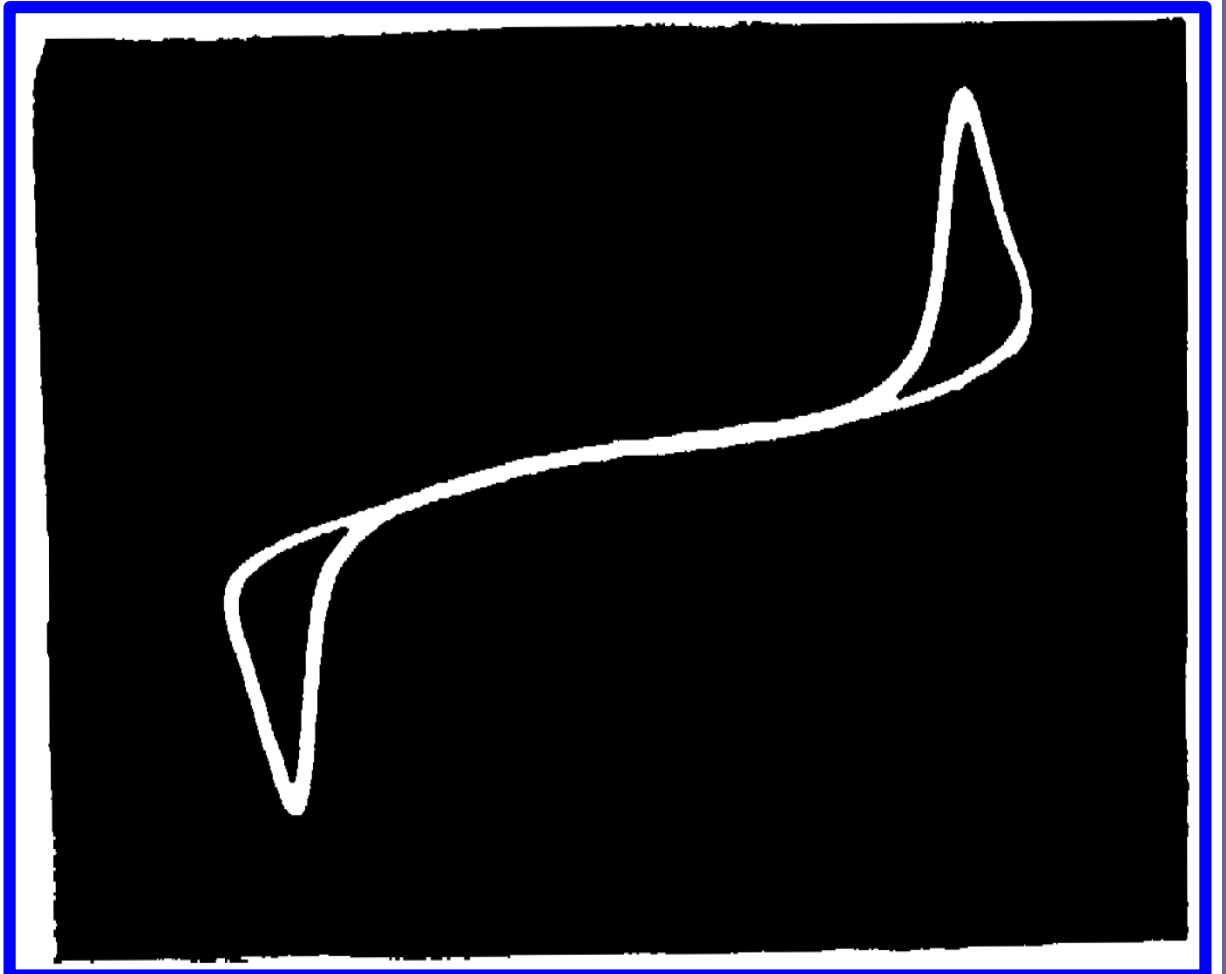
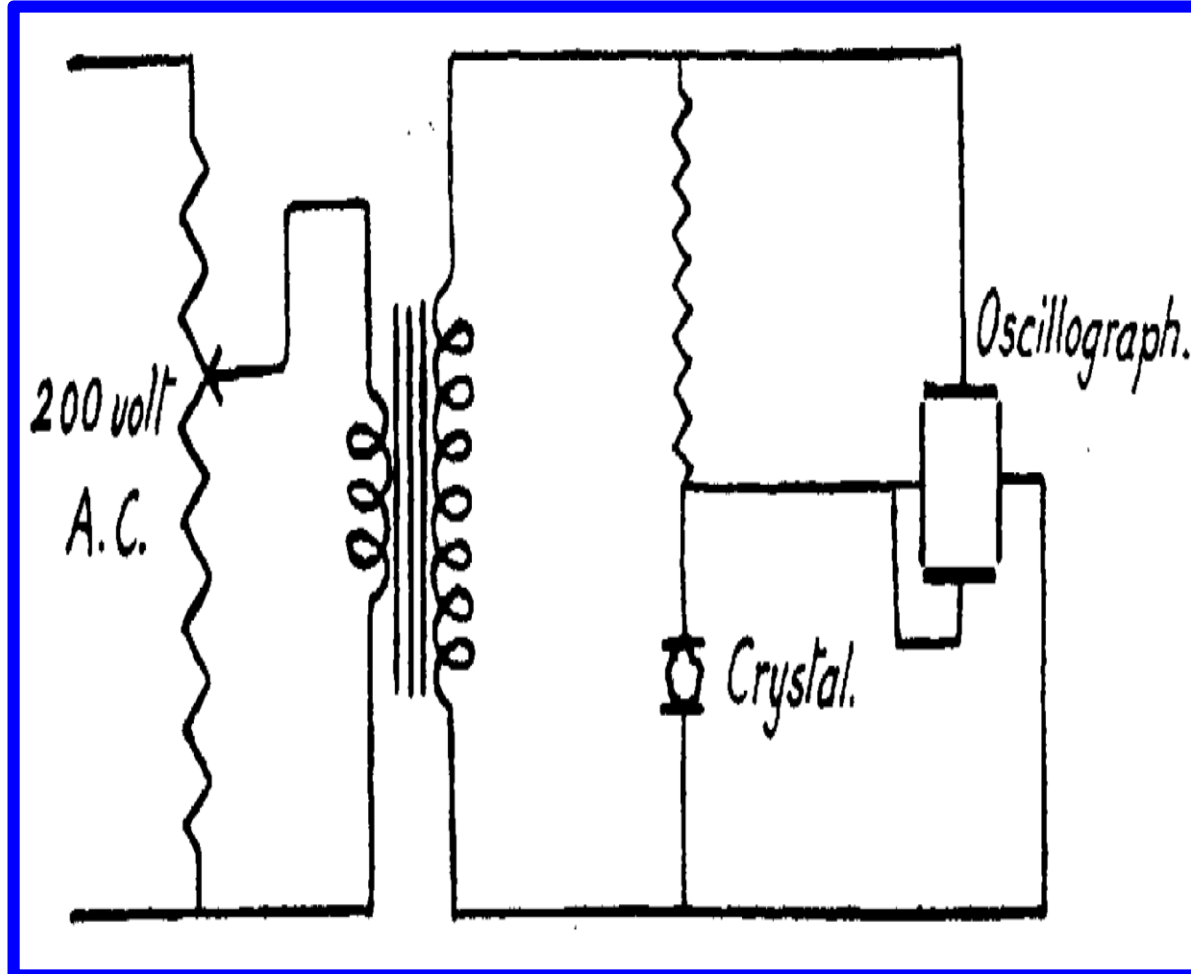
I-V characteristics of the thermal-baked and dry-cured albumen devices

The *Quest* for building  
*nano-scale solid state*  
*non-volatile memories*  
dates back from  
*1939*

*Trans. Faraday Society*, Vol. 35, pp. 1436-1439, 1939

# ELECTRICAL CONDUCTION OF COMMERCIAL BORON CRYSTALS

By J. H. BRUCE and A. HICKLING



ON THE PROPERTIES AND PREPARATION OF THE ELEMENT BORON.<sup>1</sup>

By E. WEINTRAUB.

Received March 25, 1911.

and the rapid change of resistance of boron with the temperature an accuracy in temperature measurements could be obtained which would be greater than anything yet available, especially as the boron resistor could be introduced in form of a very small filament, thus disturbing but very little the thermal conditions. Of course the boron thermometer would have to be calibrated and above red heat it would have to be enclosed in an envelope filled with inert gas.

Closely connected with this would be the use of boron as a temperature regulator in a way so obvious as to require no particular description.

Finally, in the same line of thought, boron could be used for measuring radiant energy. A rough surface of boron would probably behave very nearly like a black body, but if necessary a part or the whole of its surface could be covered with fine carbon. One way in which the measurement of radiant energy could be carried out would be by determining the radiant energy input as a difference between electrical energy inputs before and after the radiant energy falls on the boron piece. The temperature of the boron piece is recognized to be the same by the fact that its resistance is the same. This ought to be a very delicate zero method.

The industrial applications, however, are those which have first claim on my attention. Without going into details, I may say that these are based on the electrical characteristics of boron and on its mechanical properties.

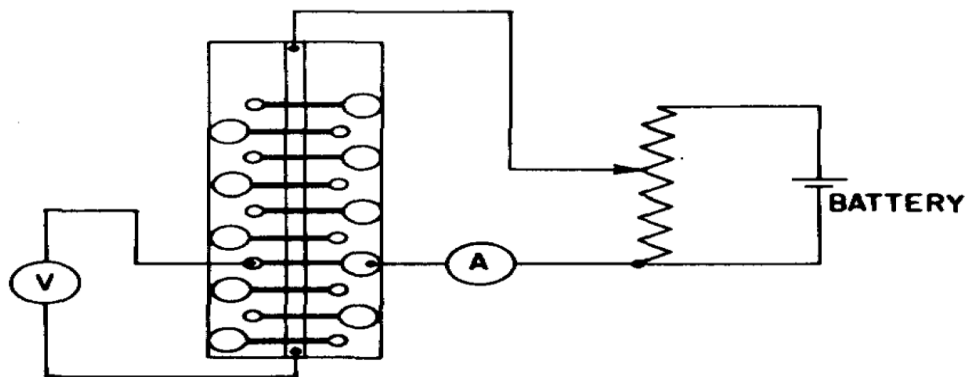
The large drop of resistance with the temperature which transforms boron under certain conditions from a very poor conductor for normal voltages into a good conductor for abnormally high voltages is certain to make it valuable for protection of electrical circuits.

Extracted from page 301

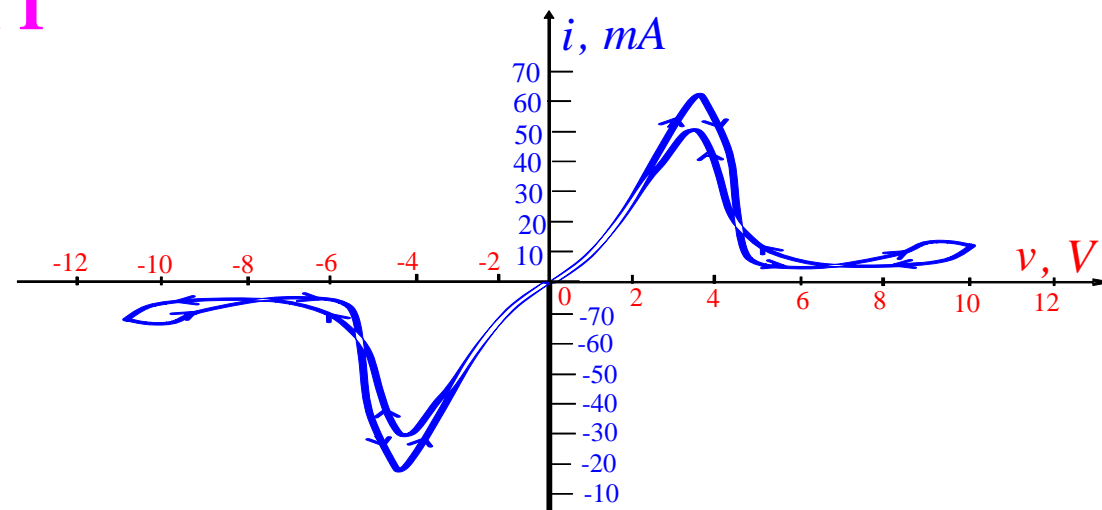
The large drop of resistance with the temperature which transforms boron under certain conditions from a very poor conductor for normal voltages into a good conductor for abnormally high voltages is certain to make it valuable for protection of electrical circuits.

# Low-Frequency Negative Resistance in Thin Anodic Oxide Films

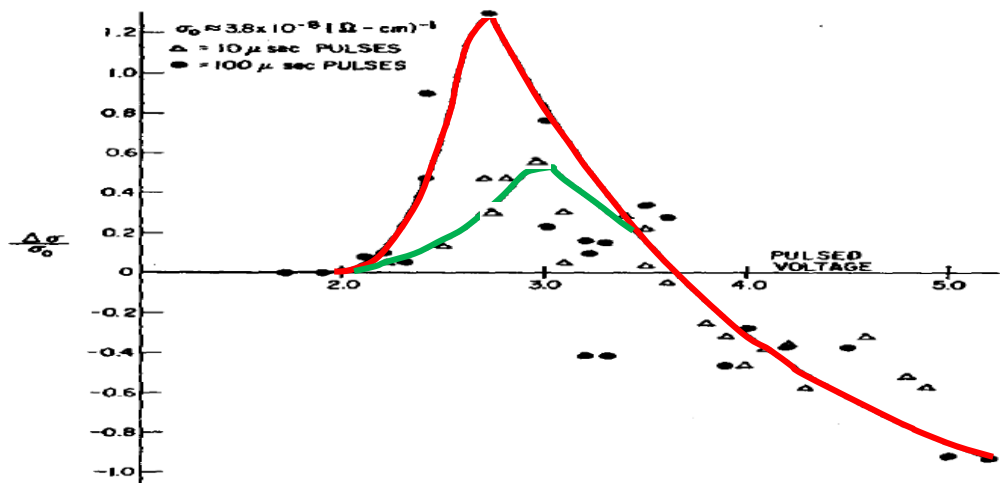
T. W. HICKMOTT



Preparation of metal-anodic oxide-metal sandwiches.  
Circuit for measuring electrical characteristics.



*Negative resistance is not found at 60 Hz !*



Change of conductivity of aluminium oxide film by 10-μsec and 100-μsec pulses of varying voltage.

Small-signal *conductance* at zero DC bias voltage can be varied continuously over a wide range by applying *voltage pulses*, and *tuning* the *pulse amplitude A*, or the *pulse width ΔT*.

*Conductance tuning voltage pulse*

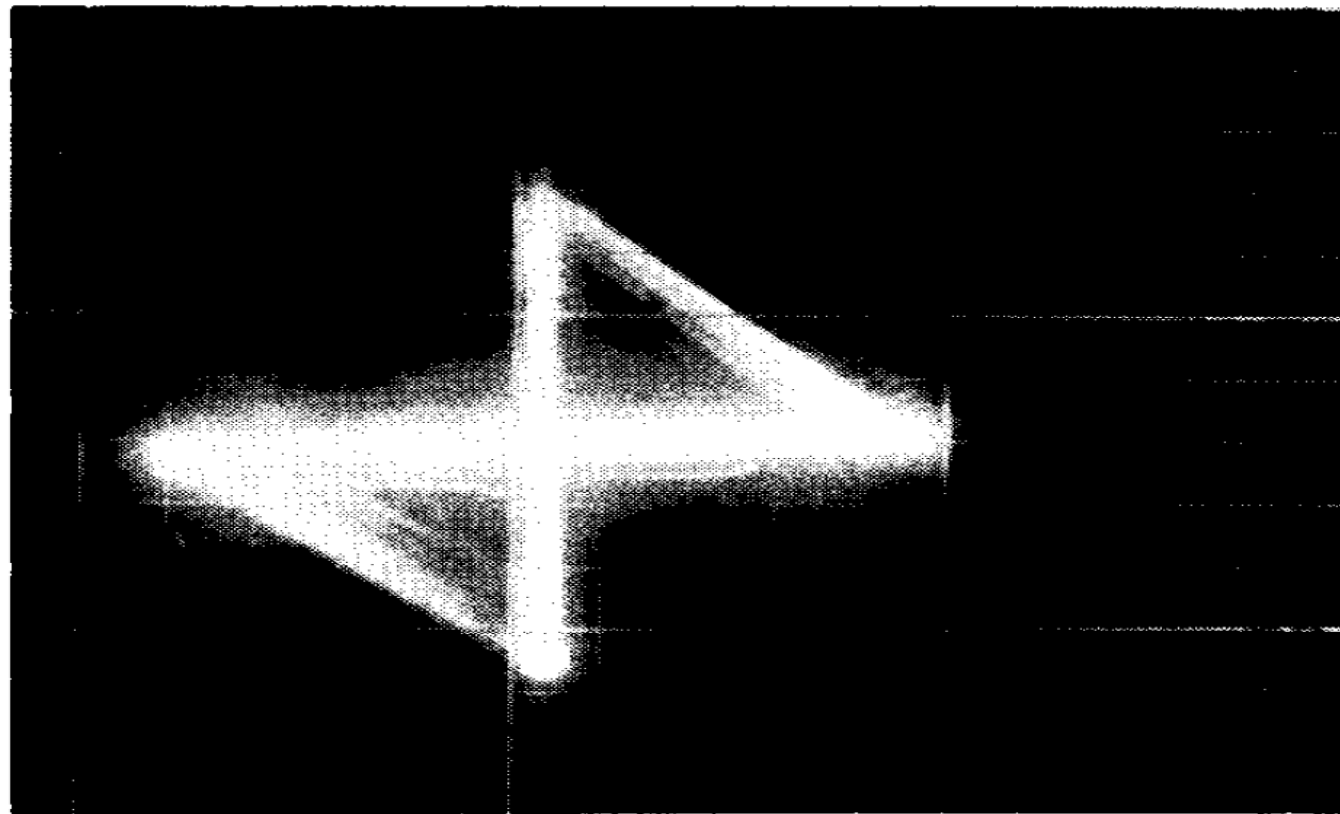
*Journal of Applied Physics*, Vol. 34, pp. 711-712, 1963

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*Negative Resistance in Thin Niobium Oxide Films*

By S. PAKSWER and K. PRATINIDHI

10 V



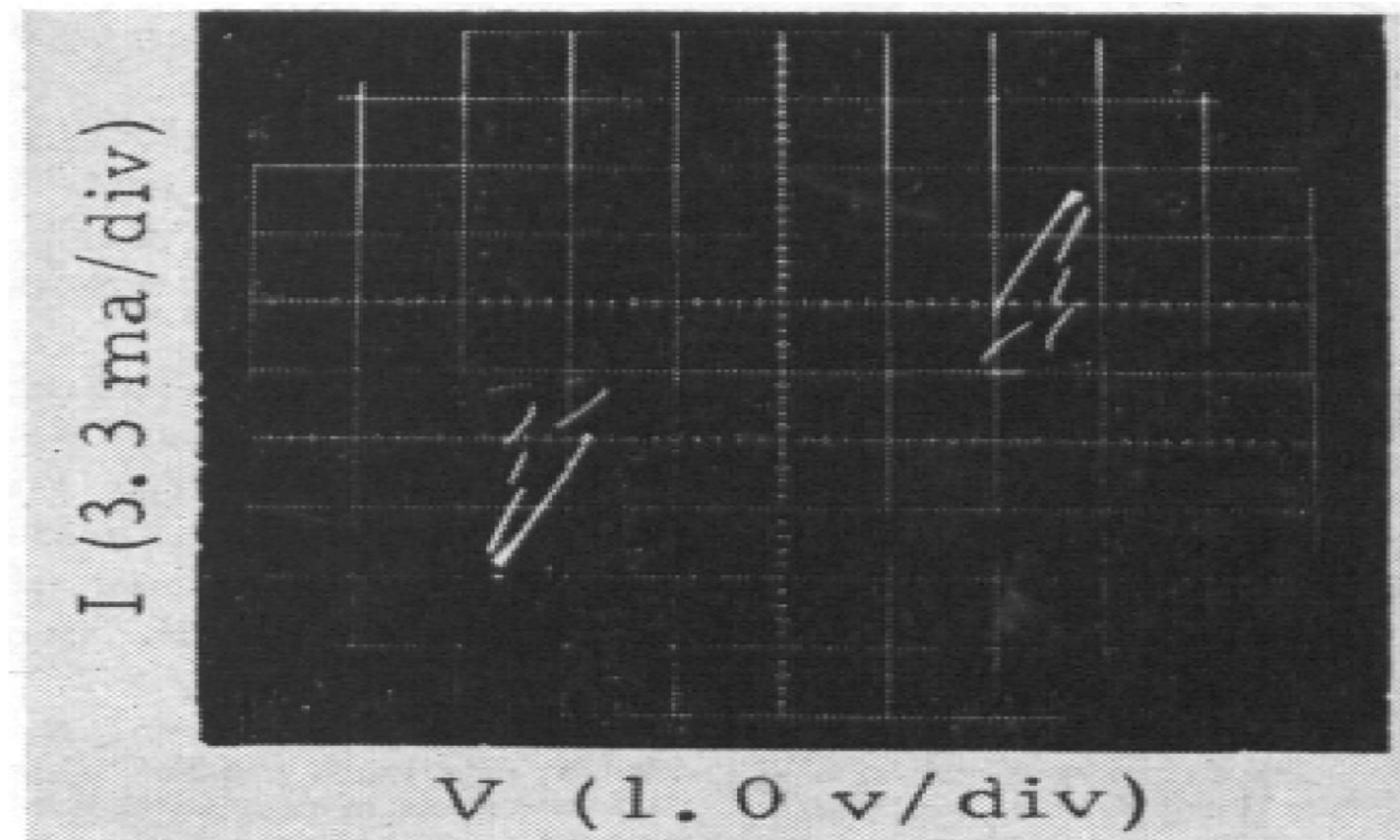
100  $\mu$ A

***I-V characteristics of Al-Al<sub>2</sub>O<sub>3</sub>-Hg sandwich***

*Proc. of the IEEE, Vol. 51, pp. 941-942, 1963*

*Current-Controlled Negative Resistance in Thin Niobium Oxide Film*

**By K. L. CHOPRA**



***I-V characteristics with multiple negative resistance regions***



## Some *Excerpts of Confused and Ambiguous statements* on *Non-Volatile Memories*

- A “*memory*” effect where no *negative resistance* would normally occur..... [Hickmott, 1962; page 2673]
- *In all cases* when a new *memory state* is induced, *hysteresis* is manifest in the *V-I characteristic* and the *V-I* loop is generated....
- Furthermore, a *memory* state *never* accompanies a *V-I characteristic* that does not exhibit *hysteresis*...
- *Hysteresis* is also exhibited in the *V-I characteristic* when the *memory* is erased..
- *In no circumstances* is erasure observed when there is no *hysteresis*...  
[Simmons and Verderber, 1969; page 91]

# *First Hint of Pinched Hysteresis Loop:*

A Device Dubbed

## **LETTER 8 MEMORY**

was published in 1971

***POLARIZED (LETETR '8') MEMORY IN CdSe  
POINT CONTACT DIODES***

***M. Kikuchi, M. Saito, H. Okushi***

*Electrotechnical Laboratory, Mukodai, Tanashi, Tokyo, Japan.*

***and***

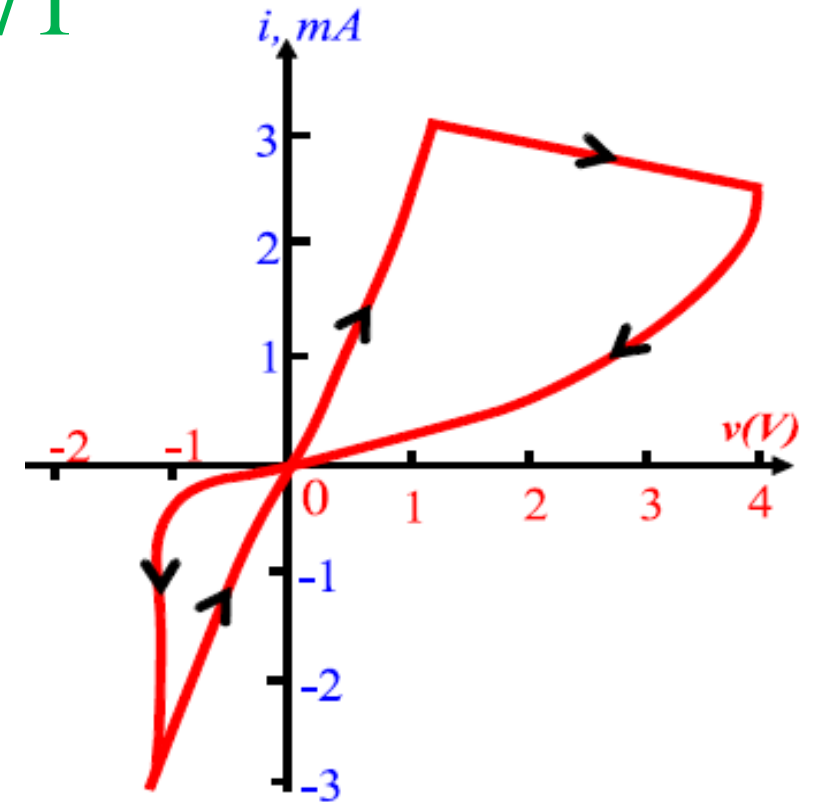
***A Matsuda***

*Nippon Columbia Co. Ltd., Kawasaki, Kanagawa, Japan.*

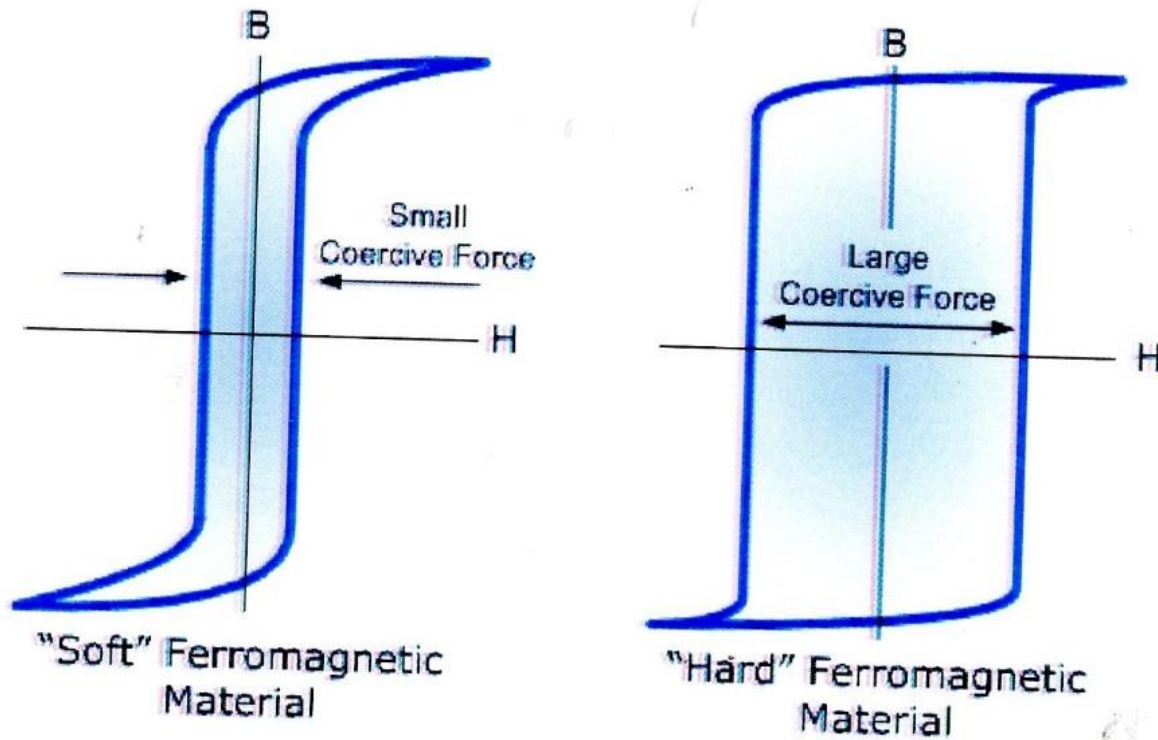
*(Received 10 March 1971 by T. Muto)*

***Solid State Communications***

***vol. 9, p. 705-707, 1971.***



Researchers were *mystified* by *hysteresis loops* which pass through the *origin* !



### *Magnetic Hysteresis*

The lag or delay of a magnetic material known commonly as *Magnetic Hysteresis*, relates to the magnetization properties of a material by which it firstly becomes magnetized and then demagnetized.

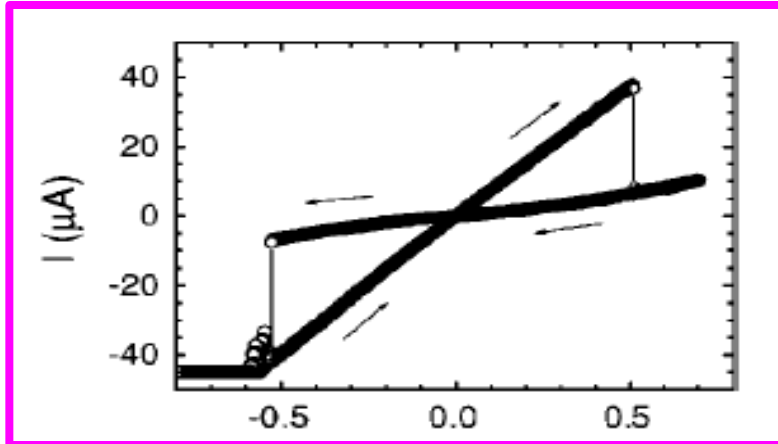
**Then Research was Frozen for  
the next 30 years !**

Less than 10 papers on *Solid state  
non-volatile memory devices*  
were published between  
**1970** and **2000** !

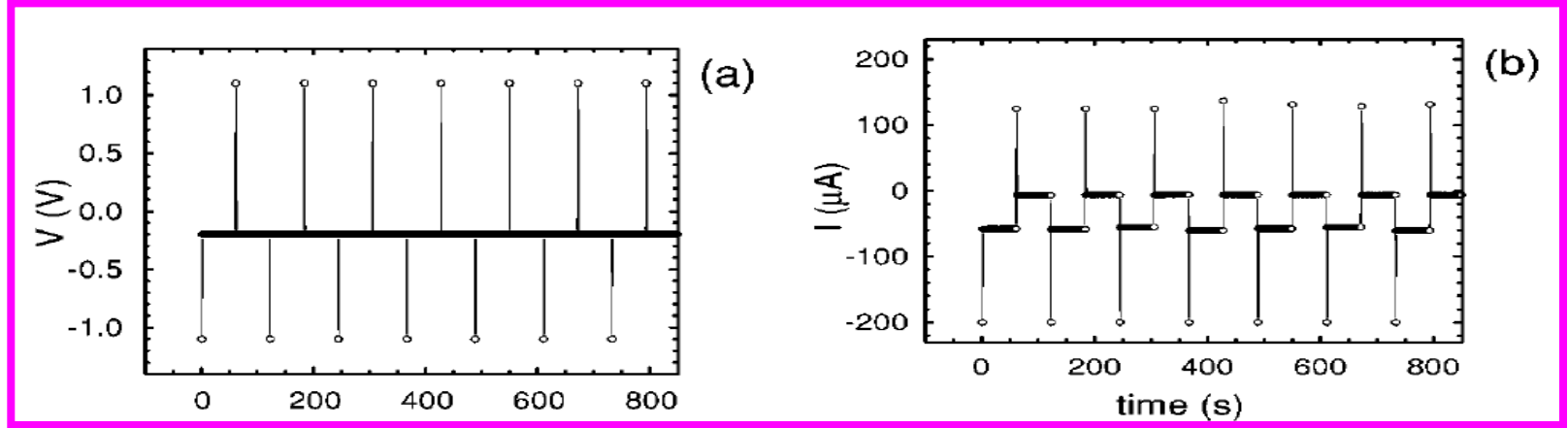
55 Years of  
*confused and*  
*misunderstood*  
non-volatile memory  
Devices

## Reproducible switching effect in thin oxide films for memory applications

A. Beck, J. G. Bednorz, Ch. Gerber, C. Rossel,<sup>a)</sup> and D. Widmer  
 IBM Research, Zurich Research Laboratory, CH-8803 Rüschlikon, Switzerland



*Pinched Hysteresis loop of Cr-doped SrZrO<sub>3</sub> memristor*



*Switching performance of a capacitor-like structure based on Cr-doped SrZrO<sub>3</sub>. (a) Applied voltage vs time and (b) readout current vs time.*

The switching operation of a Cr-doped SrZrO<sub>3</sub> device in the pulse mode is illustrated in Fig. 2. A negative voltage pulse of 2 ms switches the system into the low-impedance state. After applying a positive voltage pulse of 2 ms, the “information” written to the device is erased and the high-impedance state is recovered. Between each write and erase pulse the state is read every second for 1 min with 200 mV pulses of 2 ms duration. This switching behavior, which can be repeated reproducibly for longer periods, demonstrates the potential of such a simple capacitor-like structure to act as nonvolatile random access memory. In this example the write and erase voltages of  $\pm 1.1$  V are fairly small compared to those currently used in ferroelectric and FLASH memories and within the range of operation required in the future generations of microelectronic circuits. Faster switching speeds, i.e., shorter write and erase pulses as used here, are also possible but require higher voltage amplitudes. So far the fastest reproducible switching could be achieved with 100 ns write/erase pulses at an amplitude of  $\pm 5$  V. In our experi-

A negative voltage pulse of 2 ms switches the system into the low-impedance state. After applying a positive voltage pulse of 2 ms, the “information” written to the device is erased and the high impedance state is recovered.

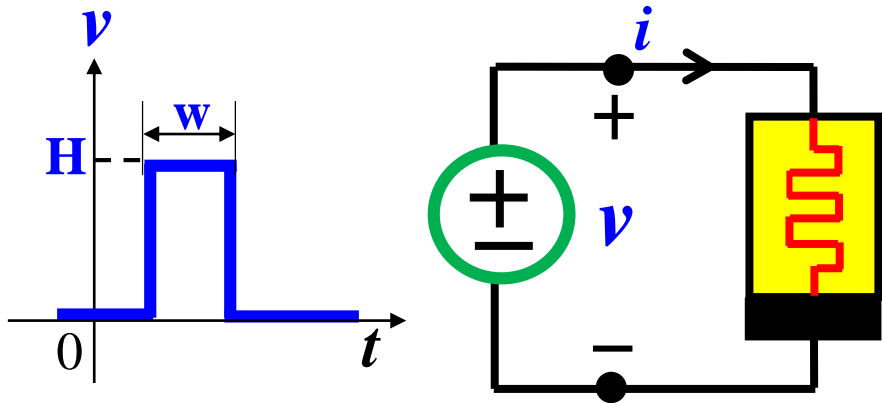
Faster switching speeds, i.e., shorter write and erase pulses as used here, are also possible but require higher voltage amplitudes.

*1987  
Nobel  
Prize  
in  
Physics*



*Discovers  
high-  
temperature  
Super-  
conductors*

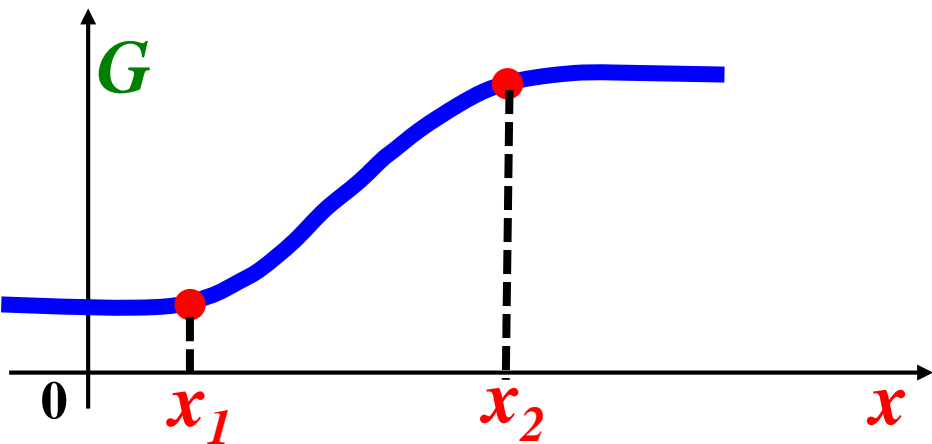
**Johannes Georg Bednorz**



$$i = G(x)v$$

$$\dot{x} = f(x, v)$$

$$f(x, 0) = 0$$

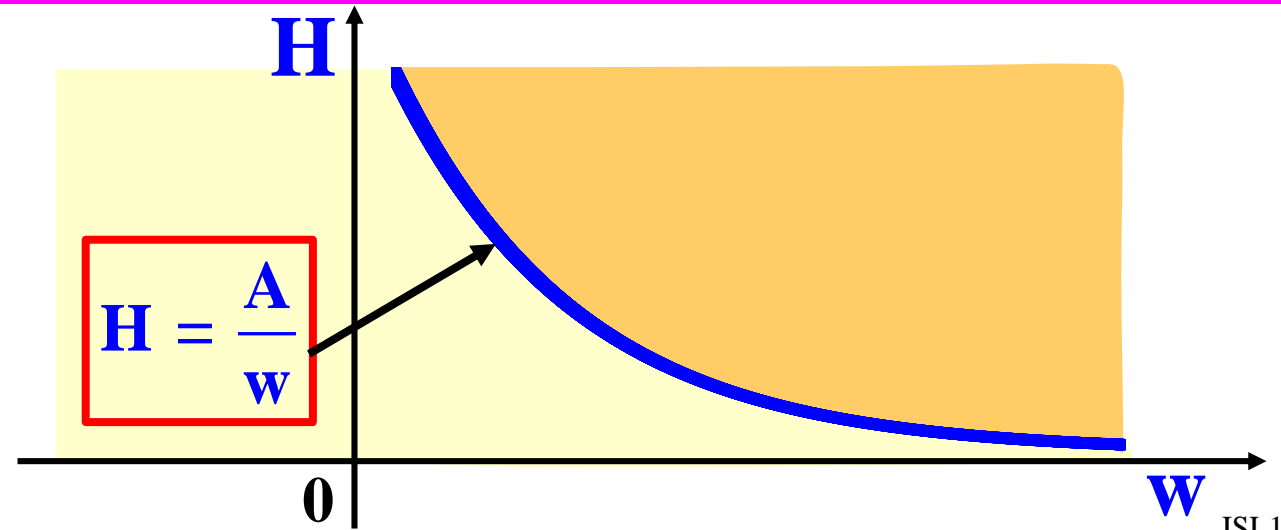


# Minimum Pulse-Area Switching Theorem

There is a *minimum pulse area*  $A(x_1, x_2)$

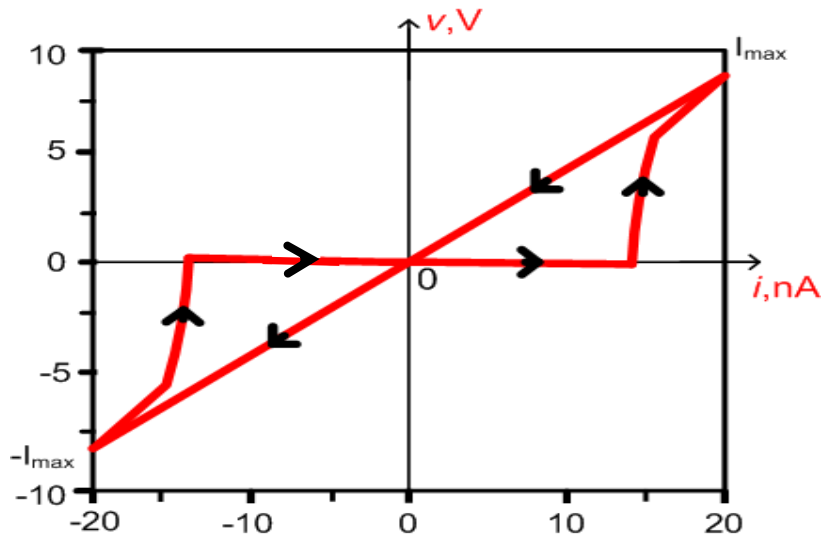
$$w \times H = A(x_1, x_2)$$

to switch between any 2 states  $x_1$  and  $x_2$  of any *non-volatile memristor*.

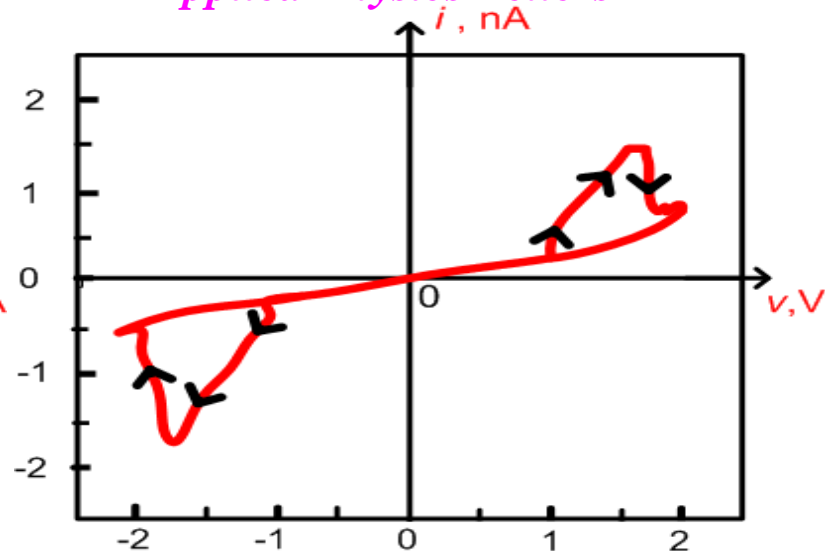




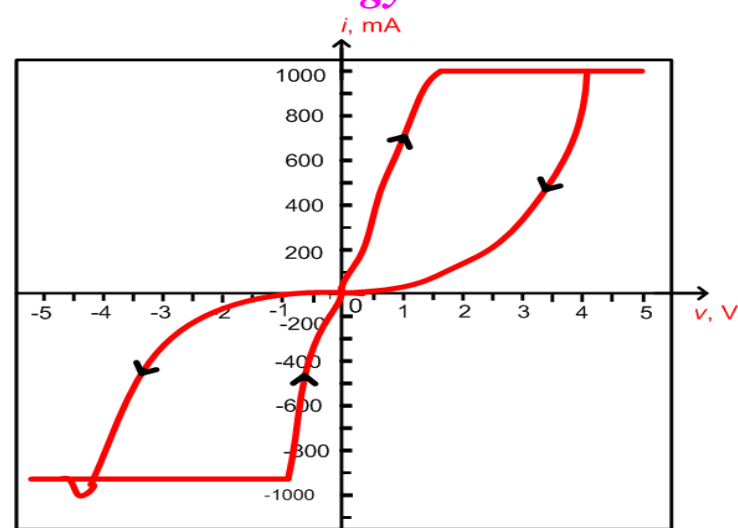
(a) 2009, Kim, et al.,  
*Nano Letters*



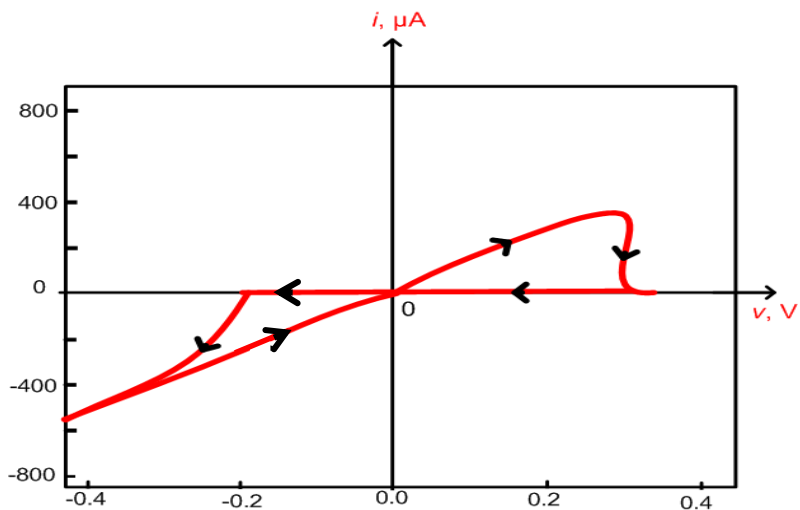
(b) 2012, Yang, et al.,  
*Applied Physics Letters*



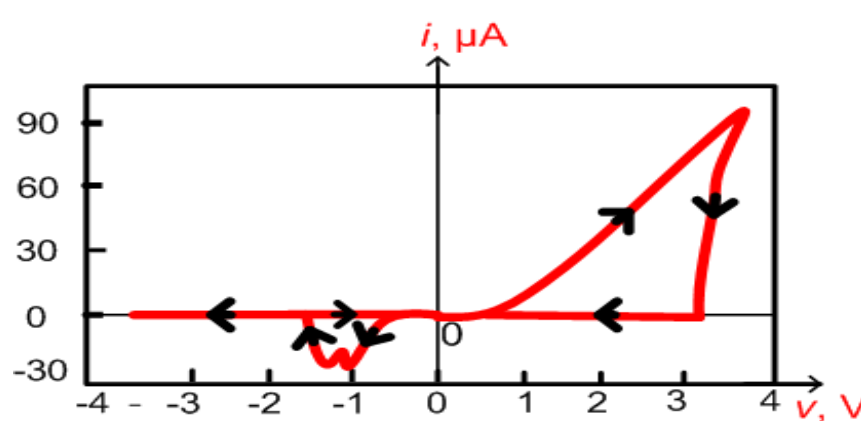
(c) 2011, Szot, et al.,  
*Nanotechnology*



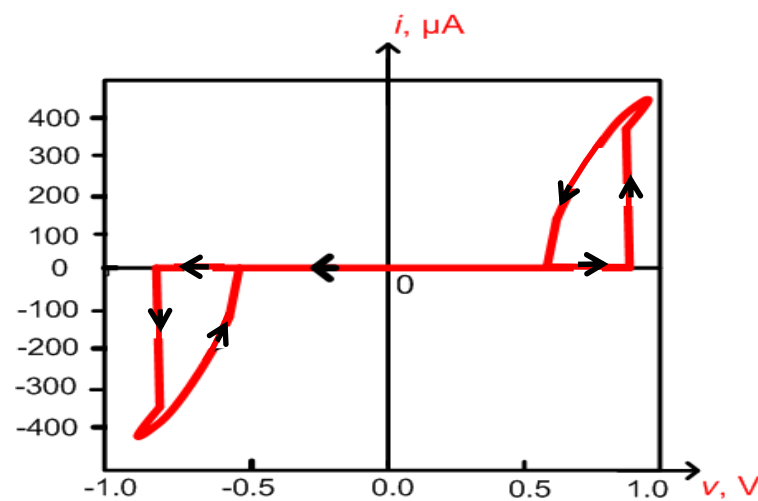
(d) 2011, Hino, et al.,  
*Sci. Technol. Adv. Mater.*



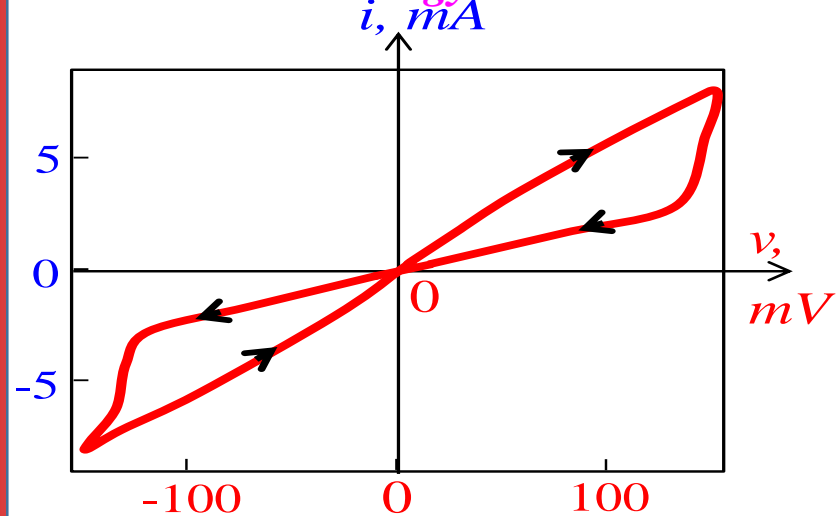
(e) 2009, Jo, et al.,  
*Nano Letters*



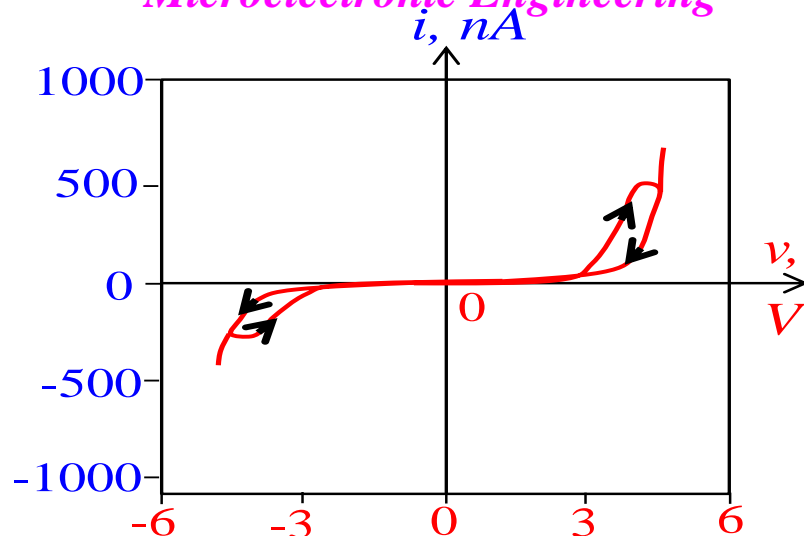
(f) 2012, Pickett, et al.,  
*Nature Materials*



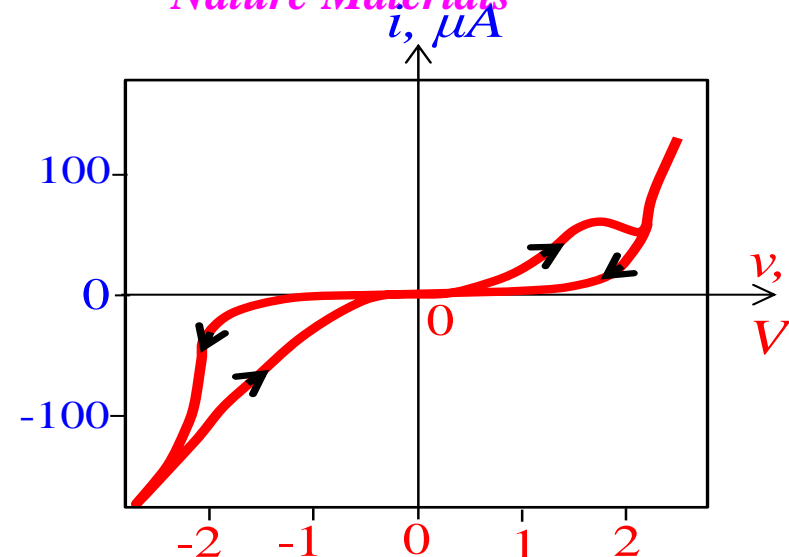
(a) 2010, Johnson, et al.,  
*Nanotechnology*



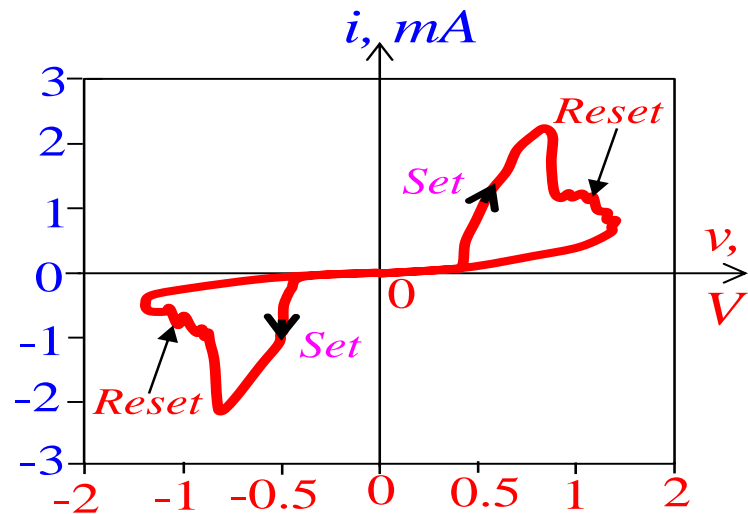
(b) 2009, R. Waser,  
*Microelectronic Engineering*



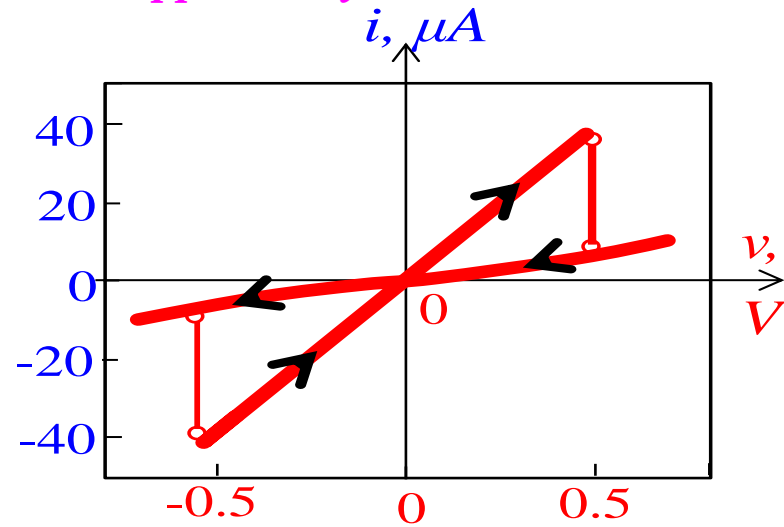
(c) 2012, Chanthbouala, et al.,  
*Nature Materials*



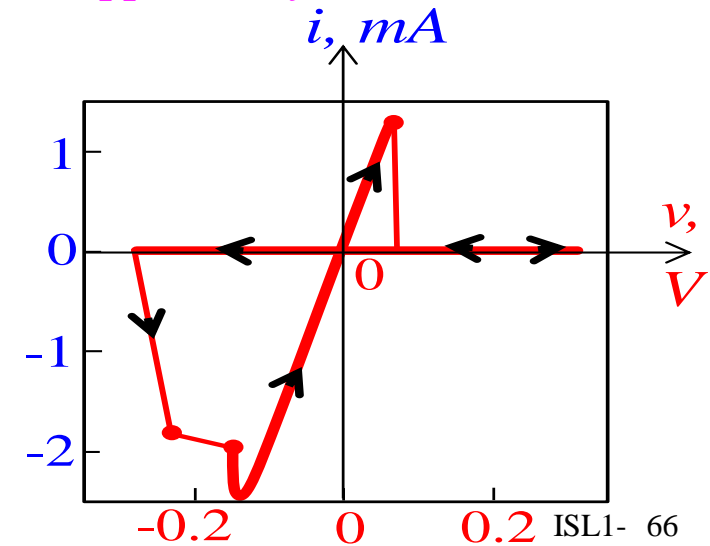
(d) 2013, Nardi et al.,  
*IEEE Trans. Electron Devices*



(e) 2000, Beck, et al.,  
*Applied Physics Letters*



(f) 2003, Sakamoto, et al.,  
*Applied Physics Letters*



Not all  
memristors are  
*Non-Volatile !*

# *Non-Volatile Memristor*

*Theorem : Two implies Infinite !*

If a *passive memristor* exhibits *2 stable memory states*, then it has a *continuum* of *stable memory* states.

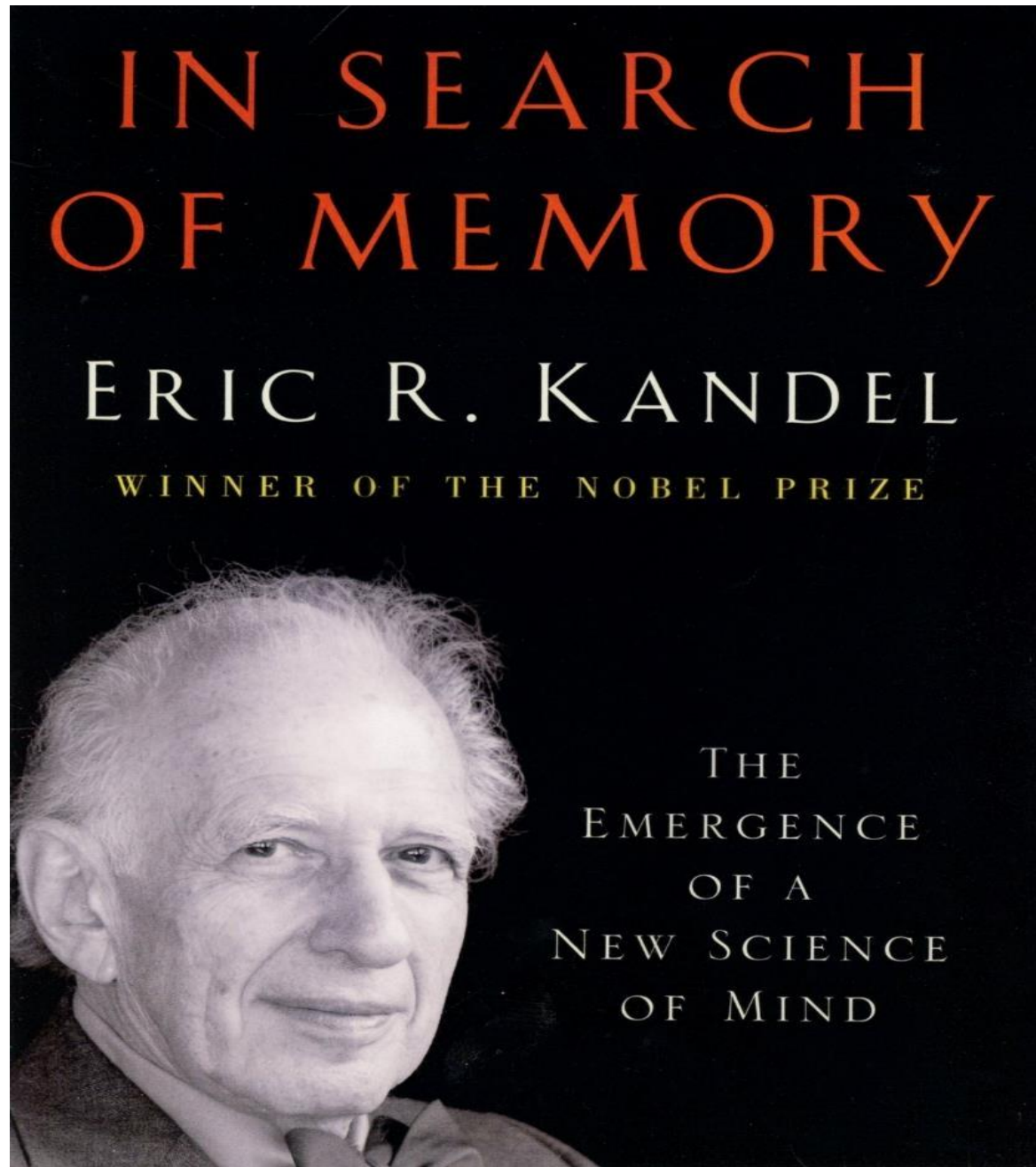
# *Fundamental memristor memory Theorem*

*All passive non-volatile memristor memories are continuum (analog) memories.*

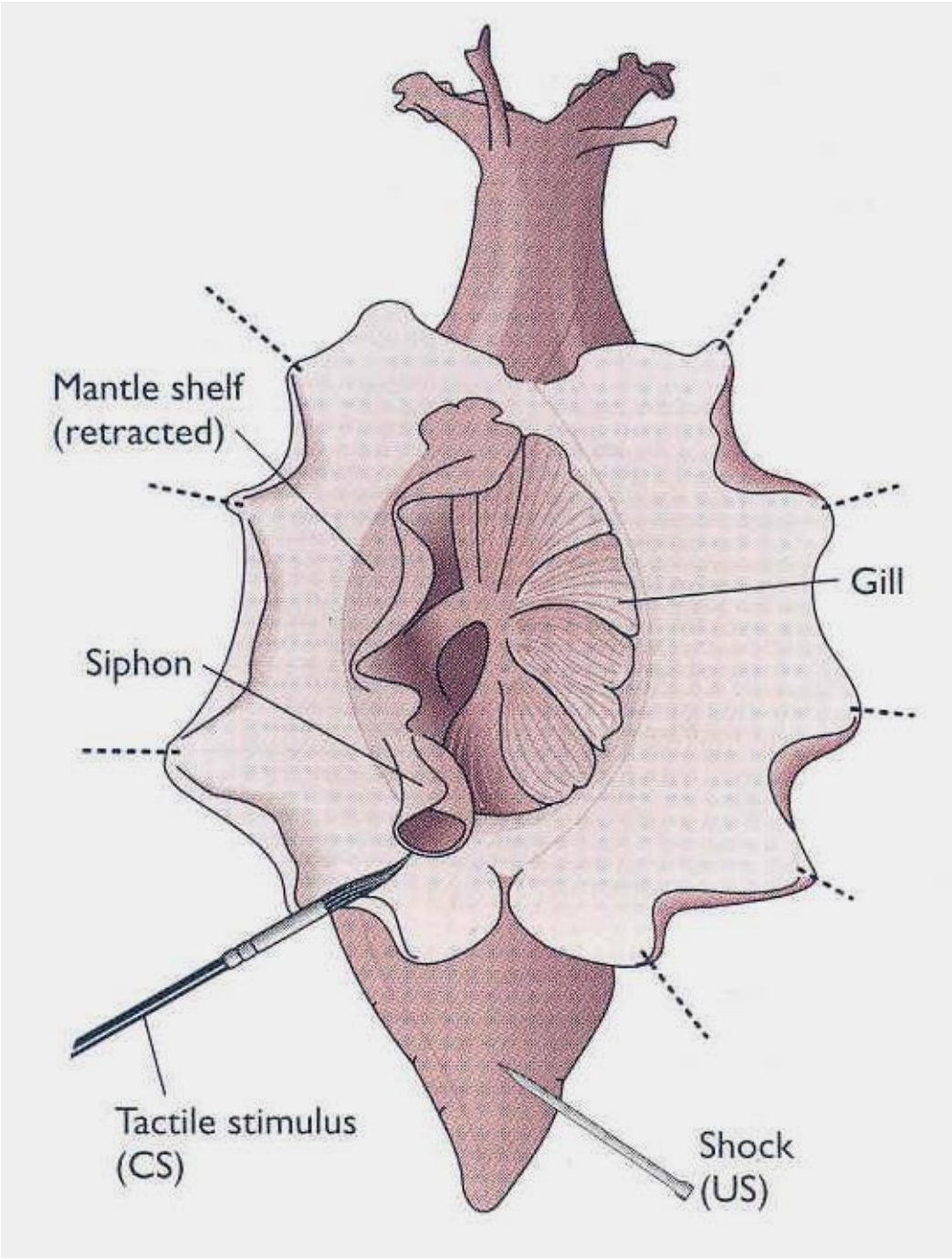


*Aplysia* with a Nobel Prize Medal

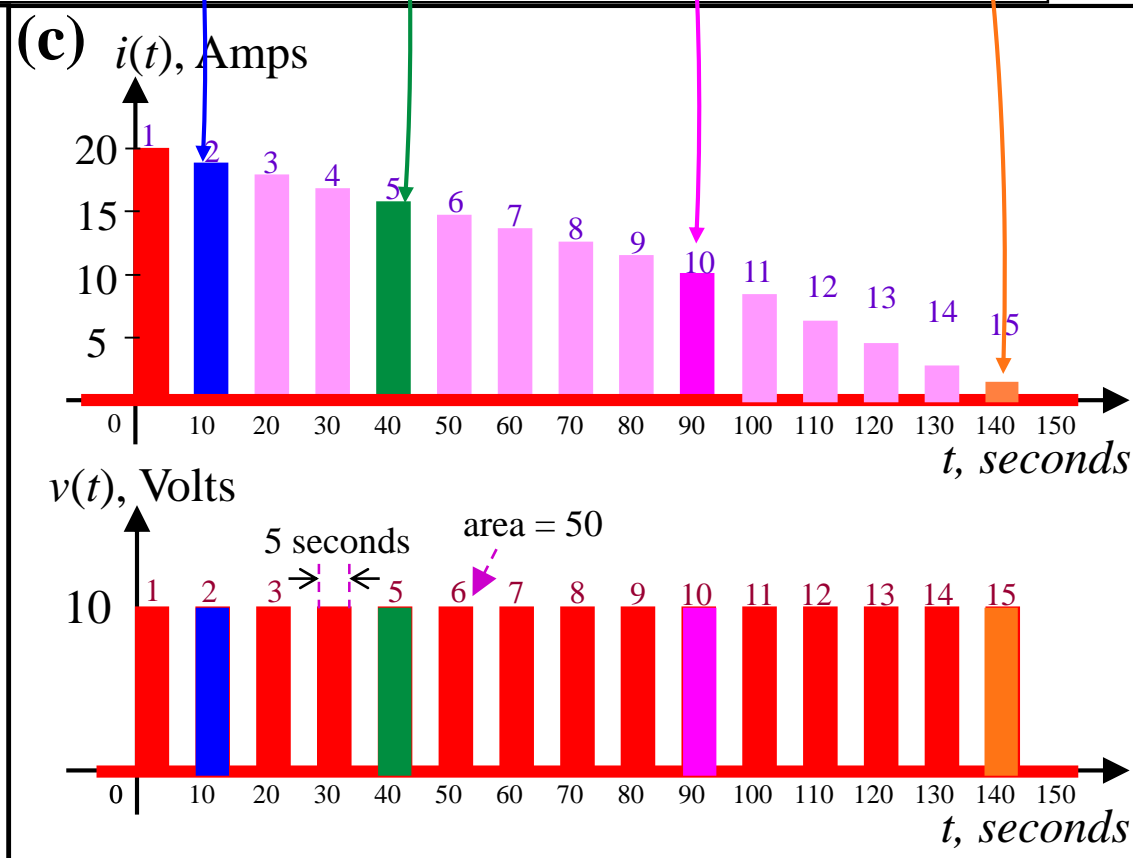
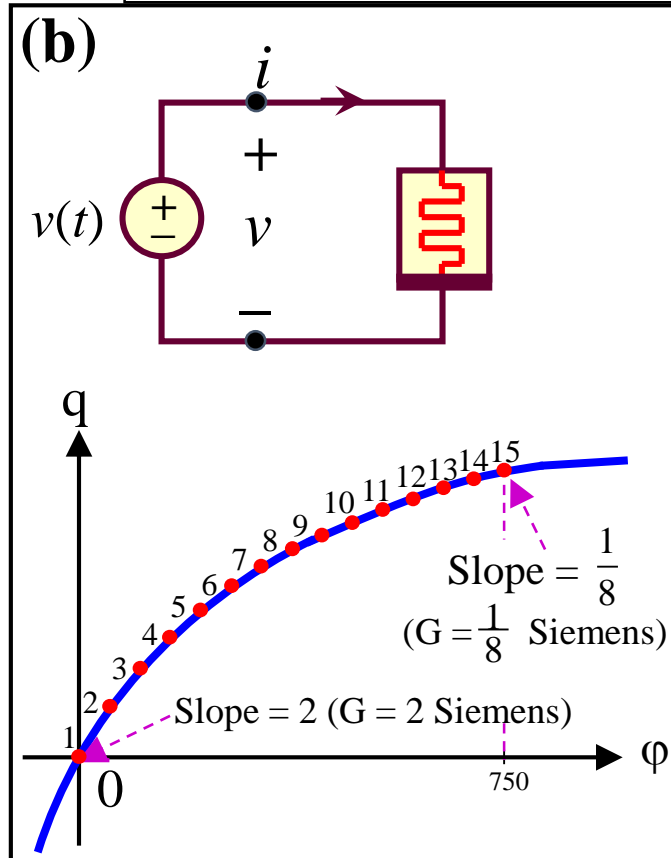
*2000  
Nobel  
Prize  
in  
Physiology*



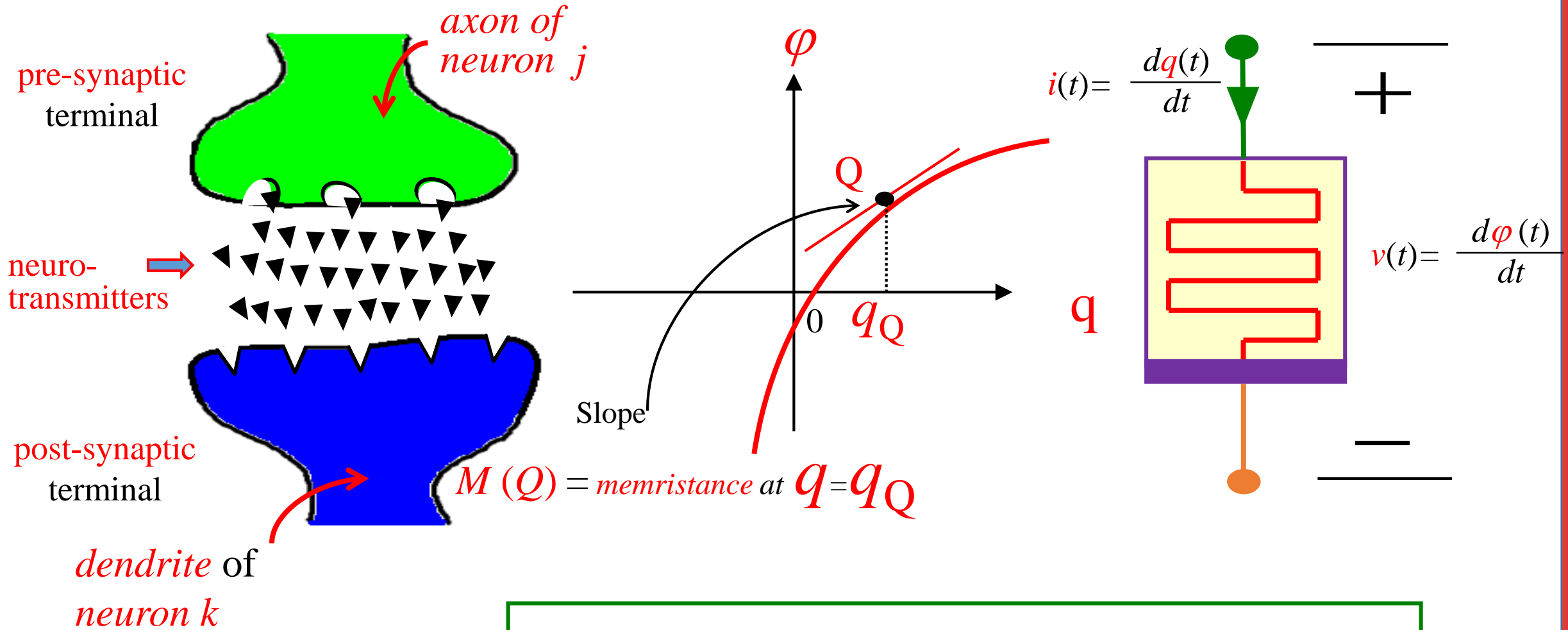
*Discovers  
the  
molecular  
basis of  
memory in  
Aplysia*







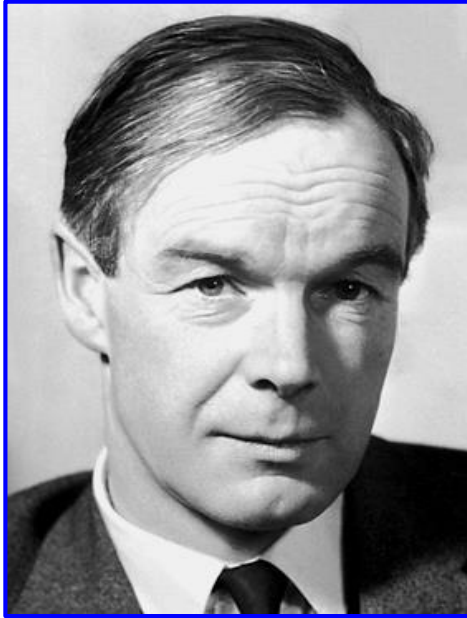
# Synapses are Memristors



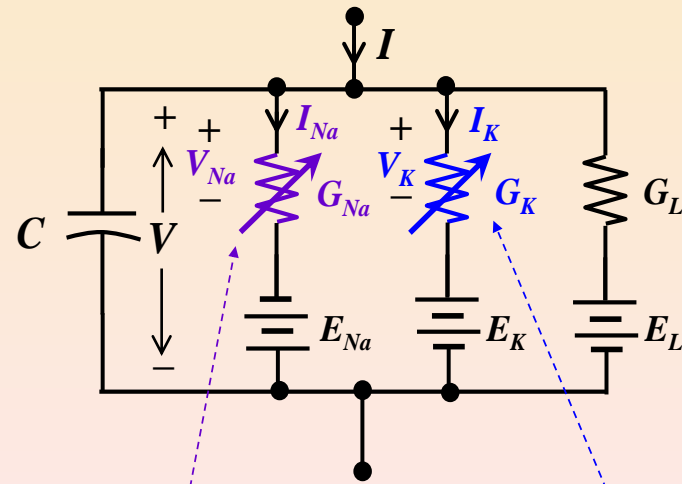
Synaptic strength  $\equiv$  memristance

# 1961 Nobel Prize in Physiology

## Hodgkin- Huxley Nerve Membrane Model

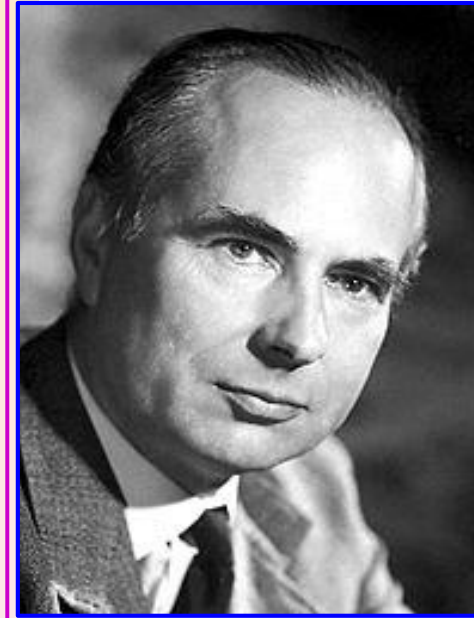


*Sir A. L. Hodgkin*



Time-varying Sodium  
conductance

Time-varying Potassium  
conductance



*Sir A. F. Huxley*

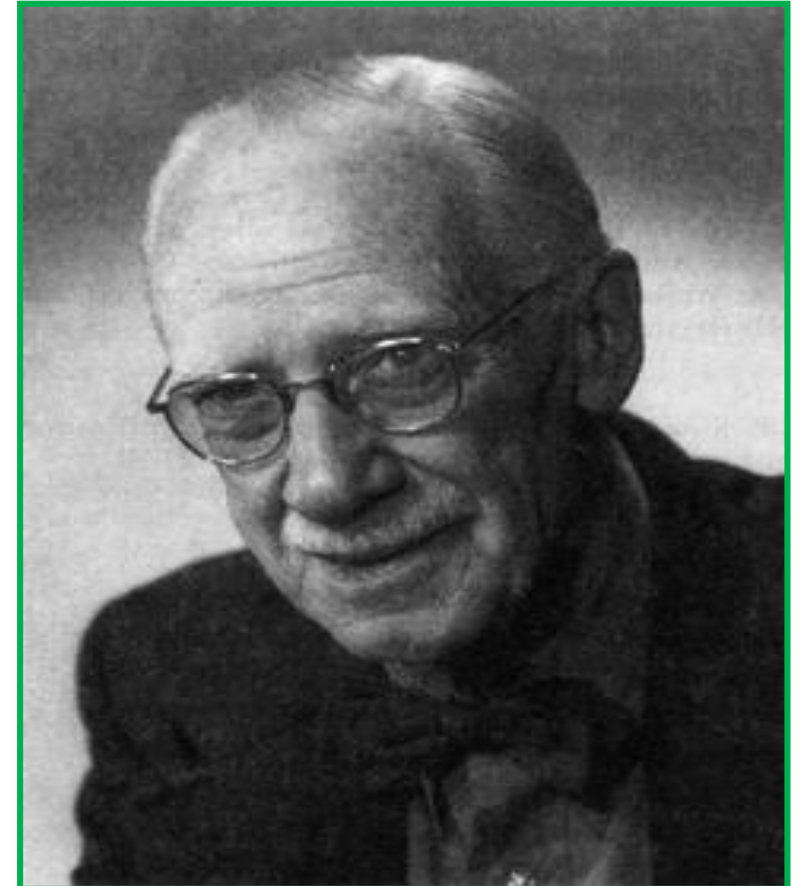
From

A.L. Hodgkin and A. F. Huxley

A Quantitative Description of Membrane Current and its  
Application to Conduction and Excitation in Nerve.

*Journal of Physiology*, Vol. 117, pp.500-544, 1952

*The suggestion of an inductive reactance anywhere in the system was shocking to the point of being unbelievable.*



*Kenneth Cole*



# *Hodgkin's Blunder*

Hodgkin had struggled in vain searching for a *physical* interpretation of the *squid axon inductance*. He failed because he had mistaken the *axon* for a *time-varying conductance*, when in fact it has a simple explanation if the *Potassium* and *Sodium ion channels* are identified as *memristors*.

*A. L. Hodgkin,*

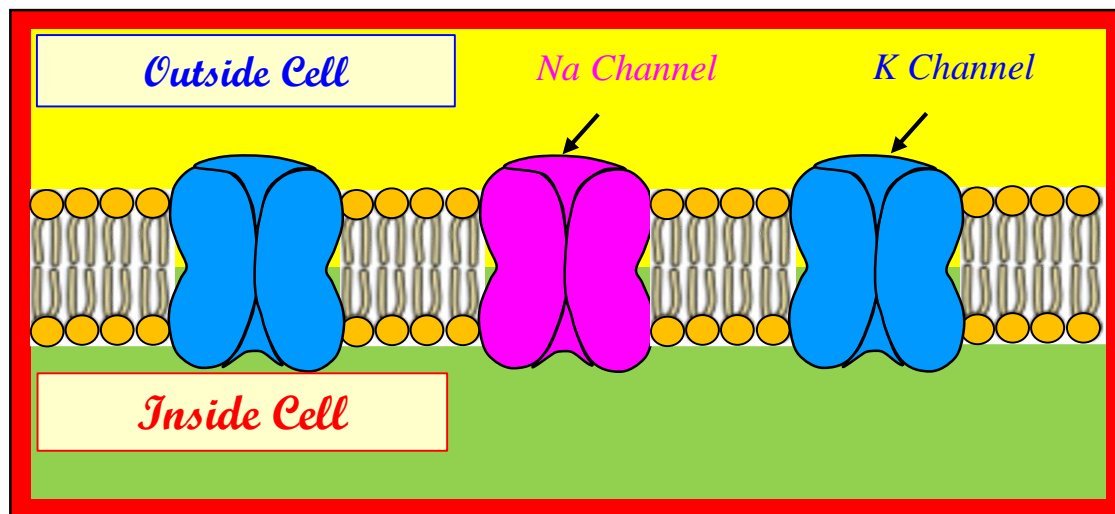
*“The ionic basis of electrical activity in nerve and muscle,”*

*Biological Review, Vol. 26, pp. 339-409, 1951*

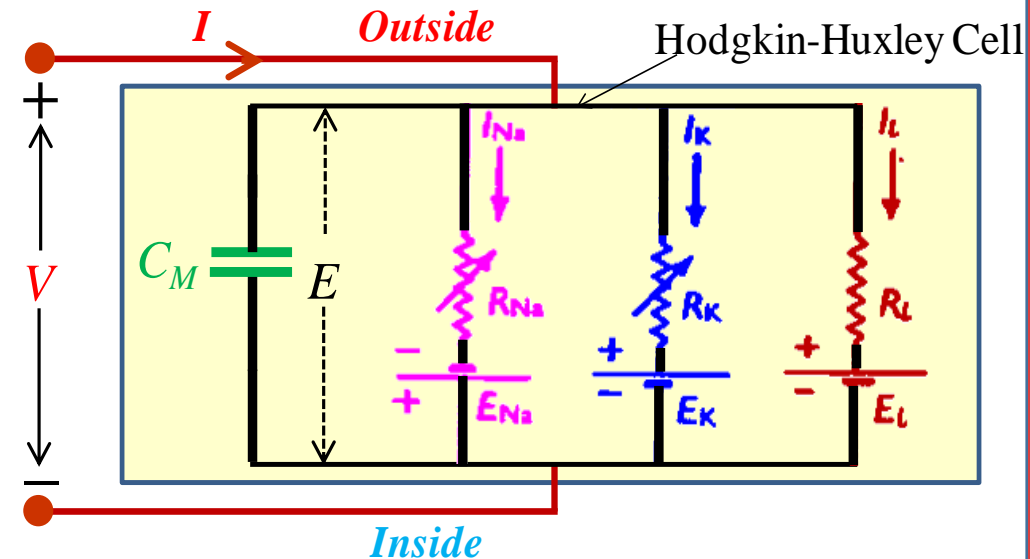
(a)



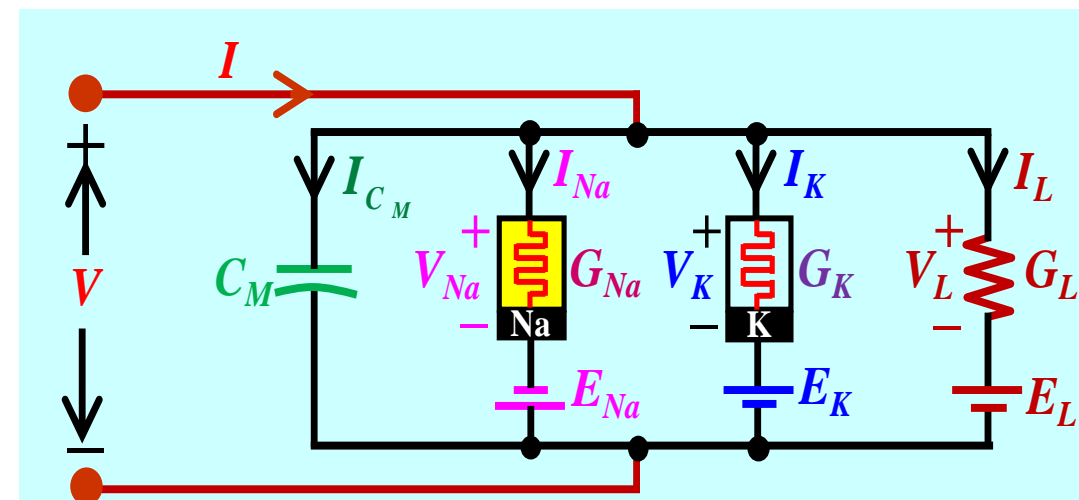
(b)



(c)



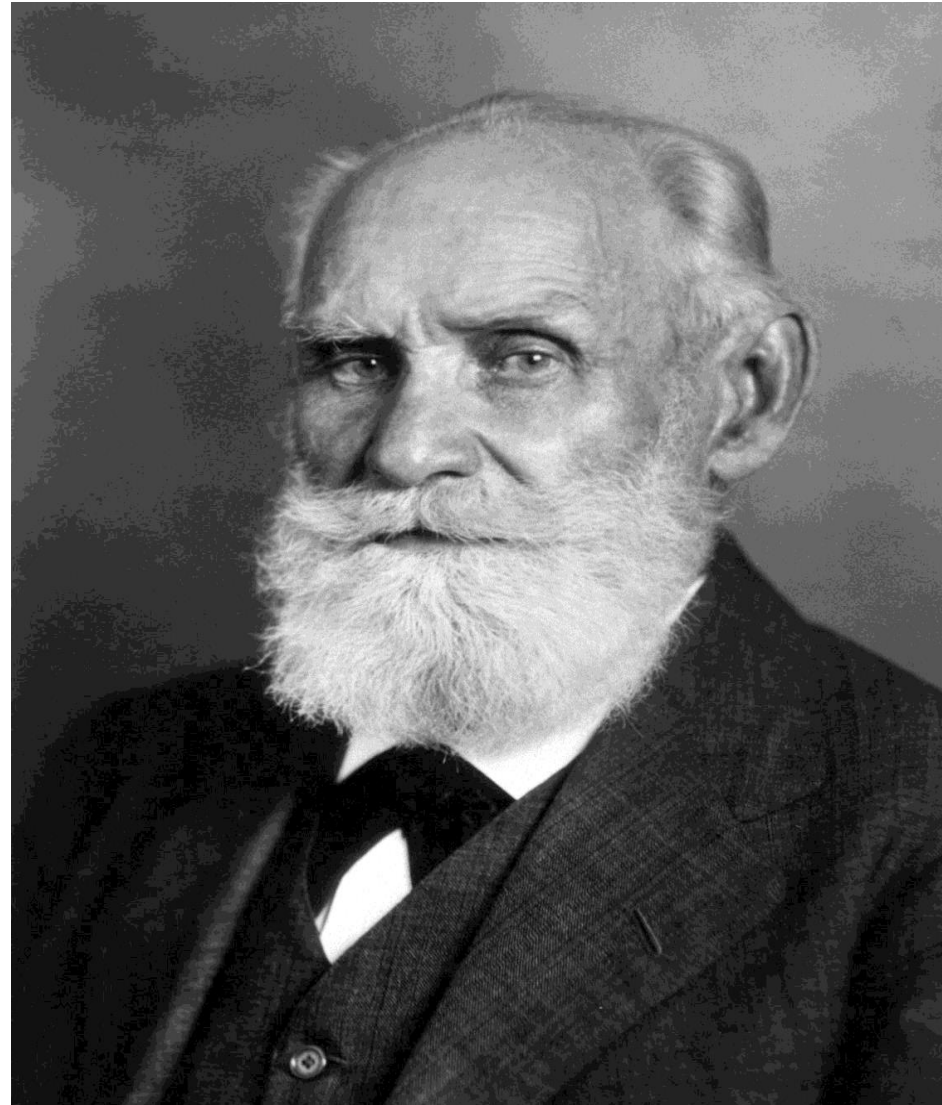
(d)



*Axons*  
*are made of*  
*Memristors !*



*1904  
Nobel  
Prize  
in  
Physiology*



**Ivan P. Pavlov**

*Discovers  
Associative  
memory  
and  
learning  
phenomenon*

Stimulus

Response

Before conditioning

CS



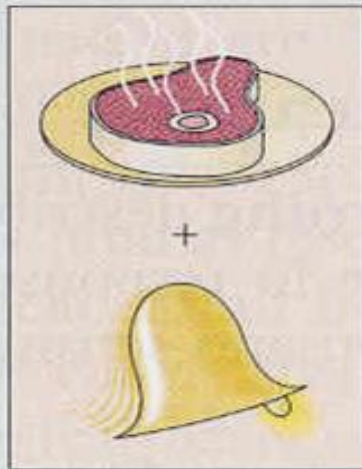
US



Stimulus

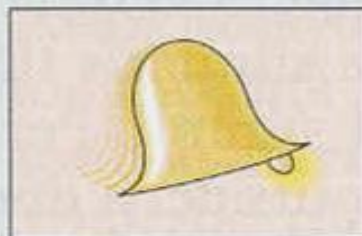
Response

Conditioning



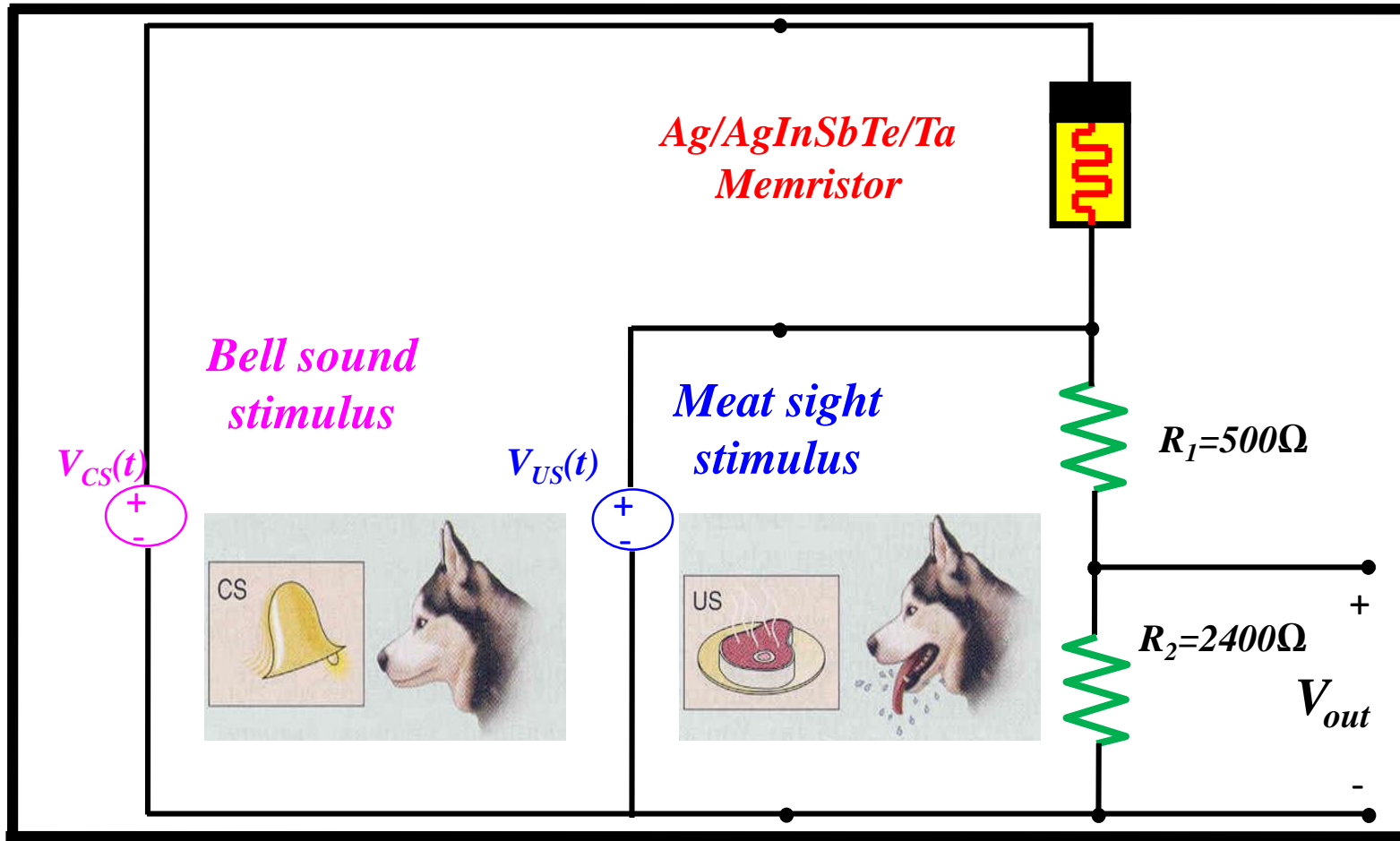
After conditioning

CR



# Emulating Pavlov's Dog Associative Learning Phenomenon

## Memristor Circuit for Emulating Pavlov's Dog



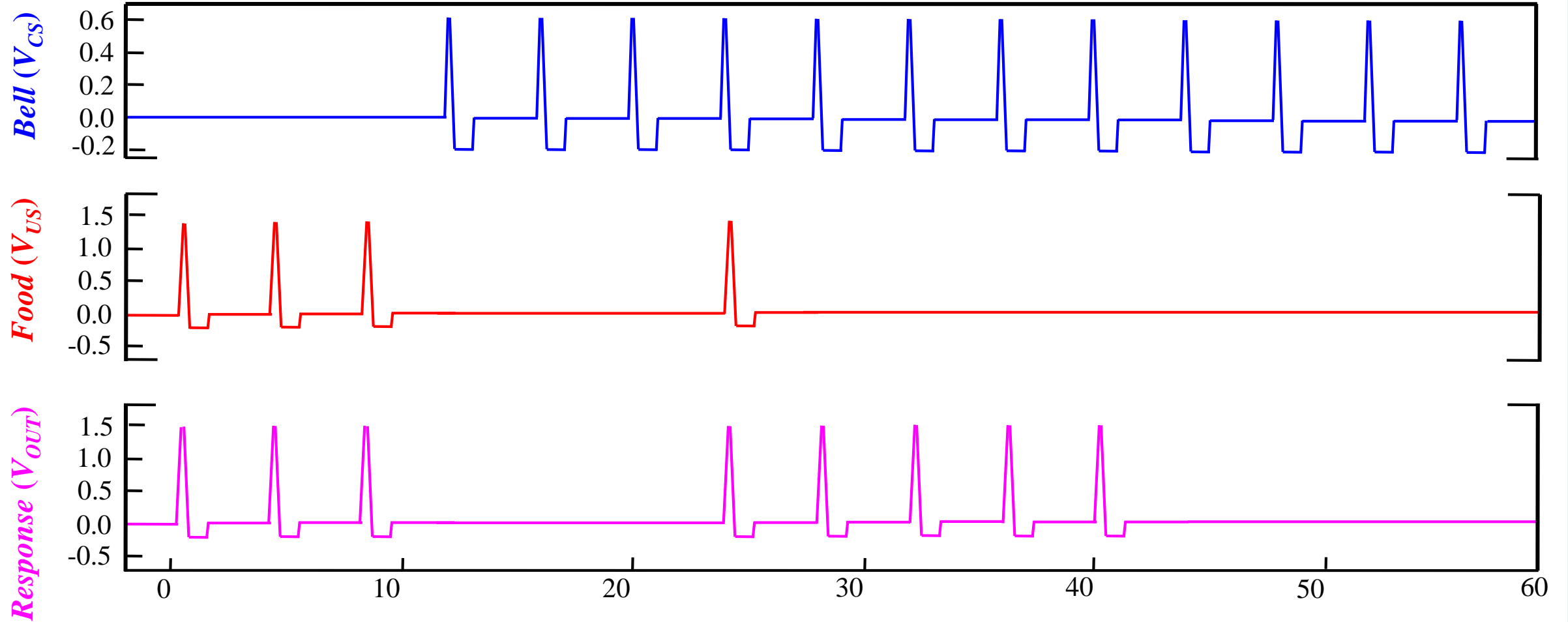
From:

Y. Li, L. Xu, Y. P. Zhong, Y. X. Zhou, S. J. Zhong, Y. Z. Hu, L. O. Chua, X. S. Miao

Associative Learning with Temporal Contiguity in a Memristive Circuit for Large-Scale Neuromorphic Networks

Adv. Electronic Materials, 1500125, p.1-8,2015.

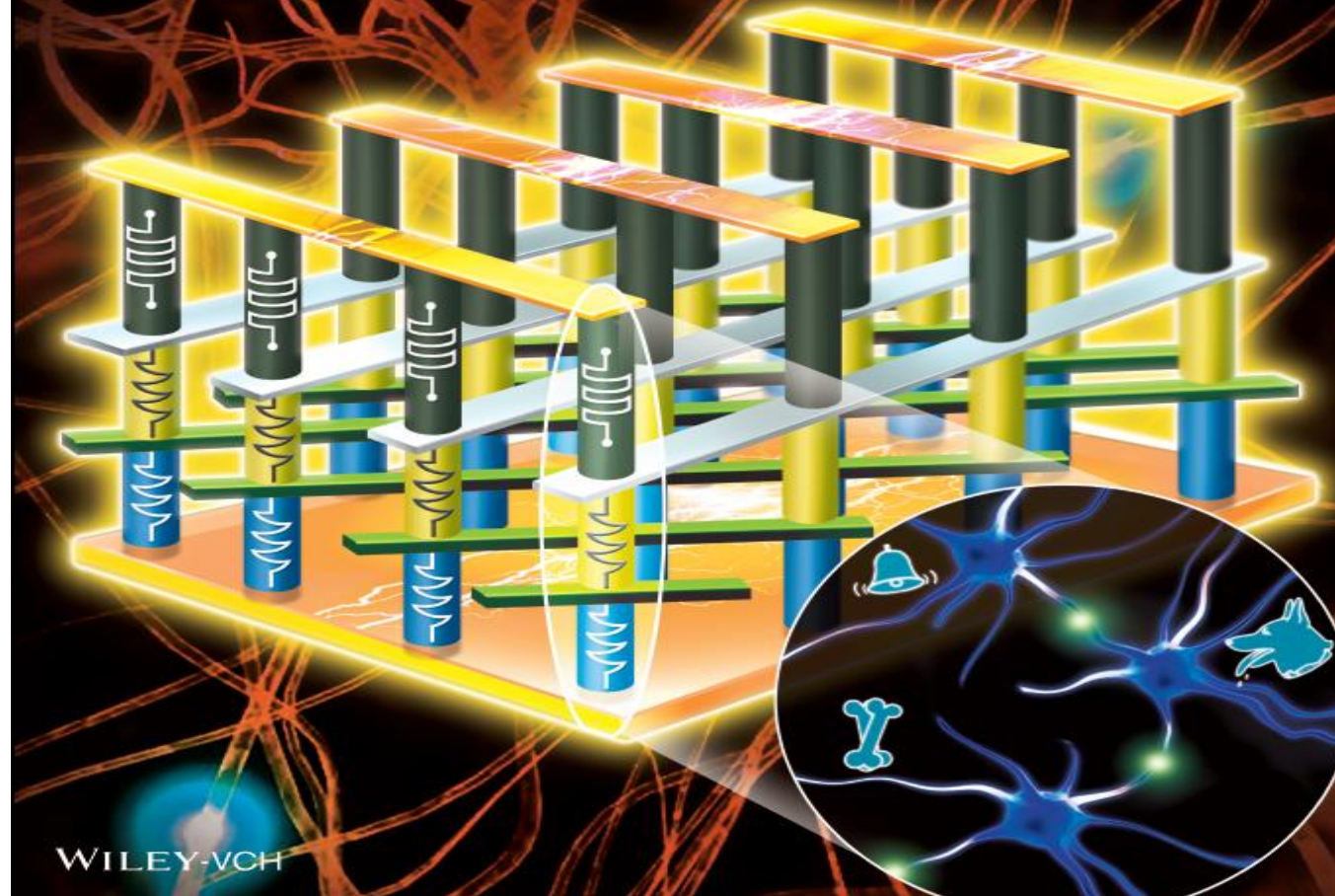
# *Waveforms Measured from Memristor Circuit Emulating Pavlov's Experiment*



Vol. 1 • No. 8 • August • 2015

[www.advelectronicmat.de](http://www.advelectronicmat.de)

# ADVANCED ELECTRONIC MATERIALS



WILEY-VCH

## A Medieval Catapult



K. Liu, C. C. Cheng, J. Suh,  
R. T.Kong. D. Fu, S. Lee, J. Zhou,  
L. O. Chua and J. Wu

# *Advanced Materials*

Vol.26,no.11,pp.1746-1750

March 2014

Dr. Junqiao Wu with President Obama

at the award ceremony for

*Presidential Early Career Awards*

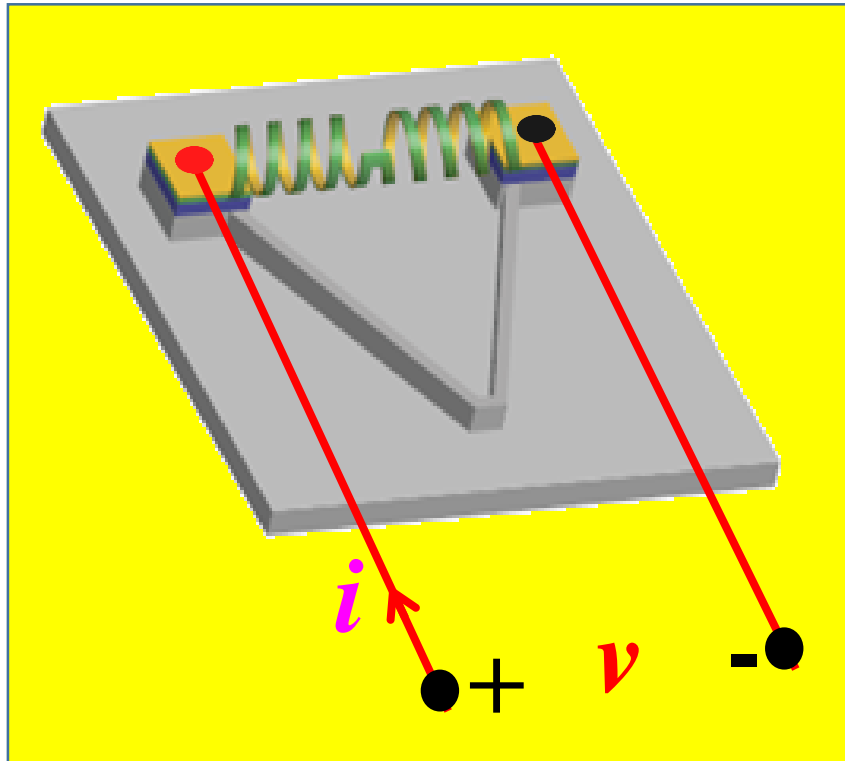
for Scientists and Engineers

Whitehouse, April 14, 2014.

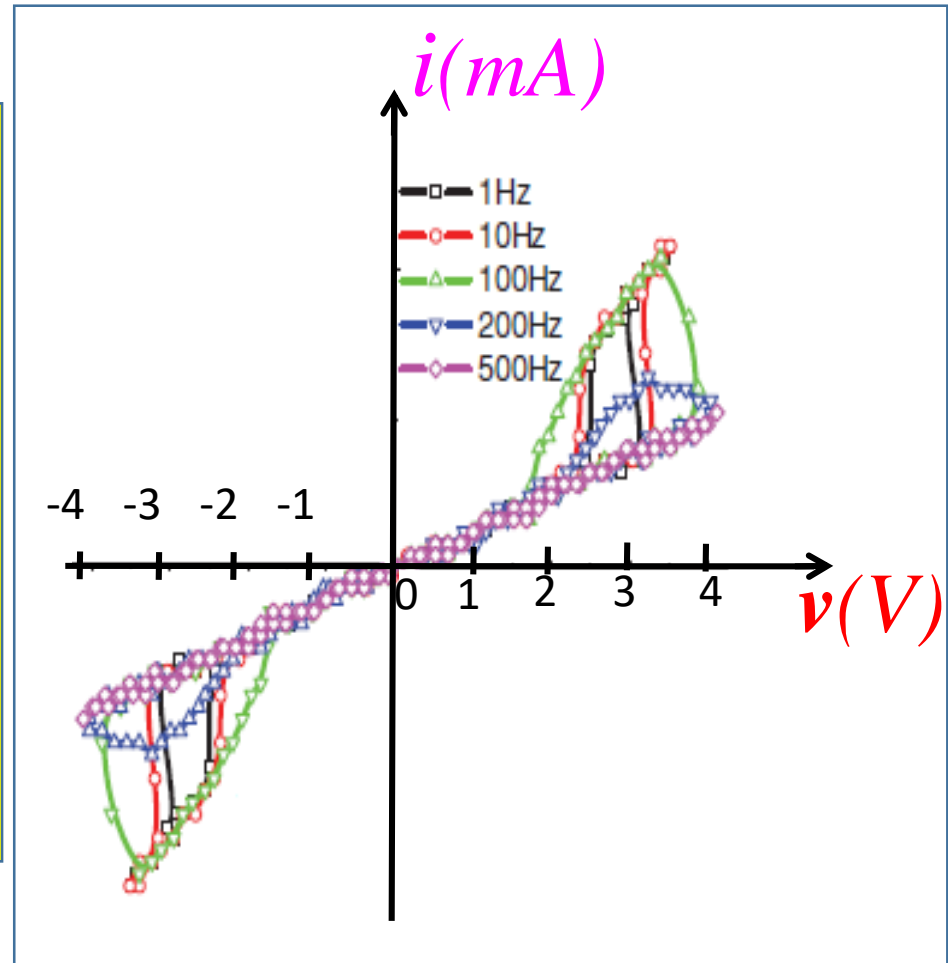




# A Micro-Catapult *Memristor*



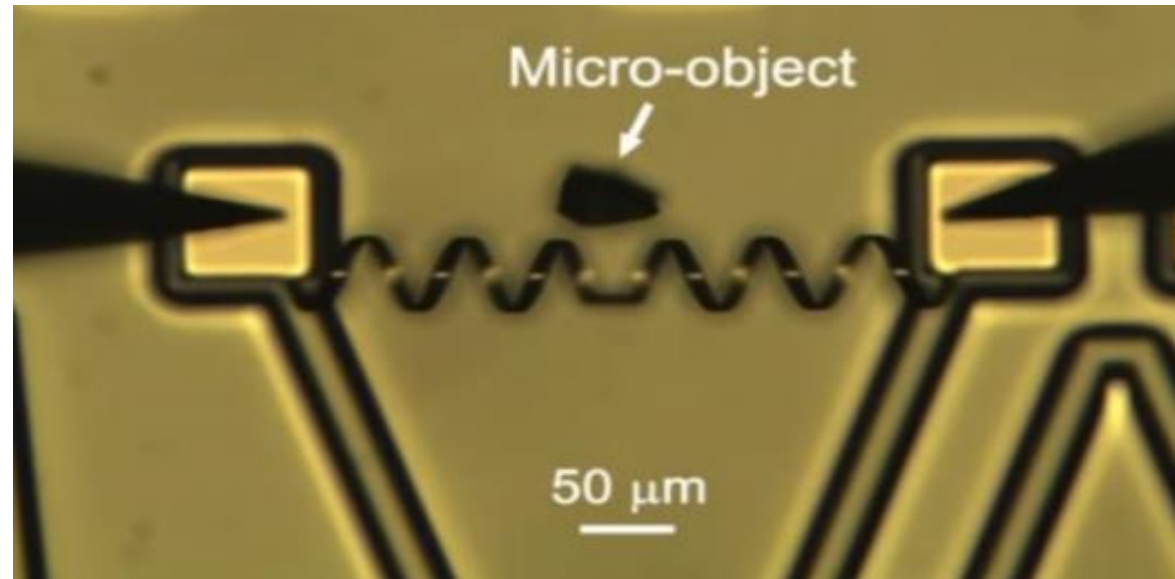
**Micro-Catapult Memristor**



**Pinched Hysteresis Loop  
Micro-Catapult Memristor**

# A Vanadium Dioxide Micro Catapult Memristor

*From: Advanced Materials, 2013*



50 μm Vanadium Dioxide *Memristor*

- 1000 times more powerful than a human muscle
- Can Catapult objects 50 times heavier than itself
- Can catapult objects over a distance 5 times its length
- Faster than the blink of an eye.

# GE90 Turbofan for Boeing 777



## *Performance of Turbofan for Boeing 777:*

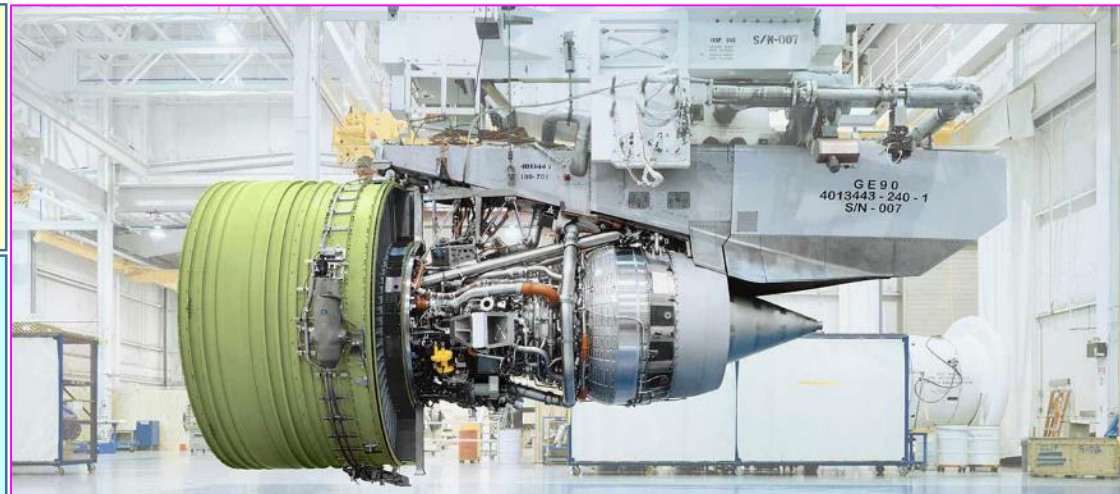
Power Density: 9 kW/kg

Rotation Speed: 10,000 rpm

## *Performance of Micro Catapult Memristor :*

Power Density: 39 kW/kg

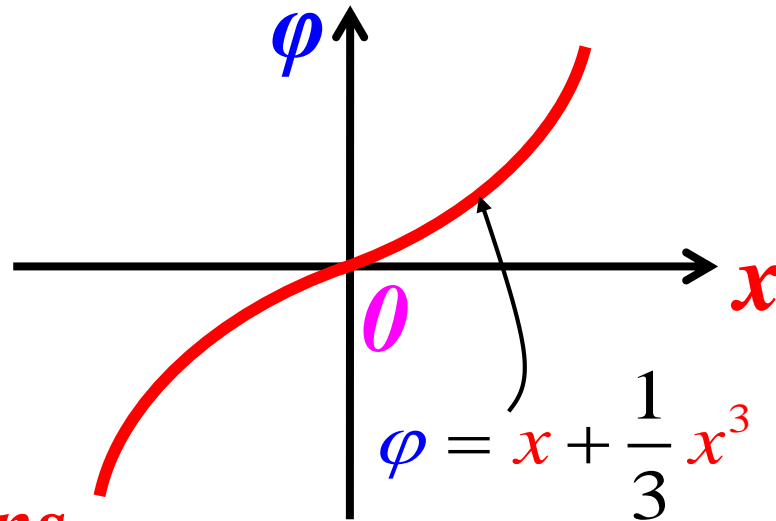
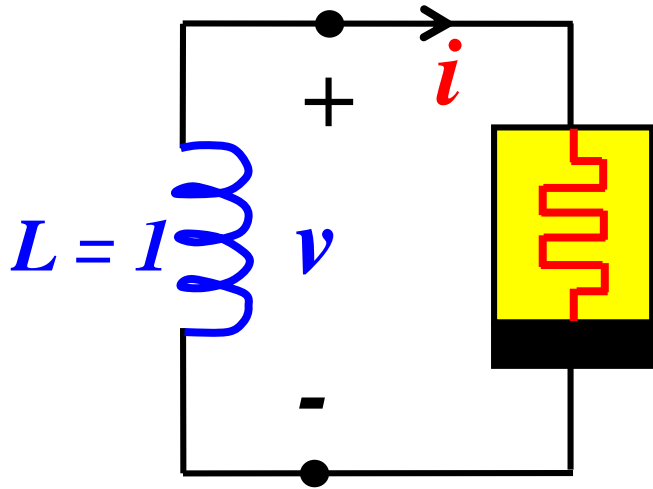
Rotation Speed: 200,000 rpm



*Some Memristor Circuits*

*have*

*Hamiltonians !*



### State Equations

$$\frac{dx}{dt} = i$$

$$\frac{di}{dt} = -(1 + x^2)i$$

### Hamiltonian Equations

$$\frac{dx}{d\tau} = \frac{\partial H}{\partial i}$$

$$\frac{di}{d\tau} = -\frac{\partial H}{\partial x}$$

$$\frac{dx}{d\tau} = 1$$

$$\frac{di}{d\tau} = -(1 + x^2)$$

$$\frac{dx}{i dt} = 1$$

$$\frac{di}{i dt} = -(1 + x^2)$$

$$d\tau \triangleq i dt$$

From :

M. Itoh and L. Chua

Memristor Hamiltonian Circuits

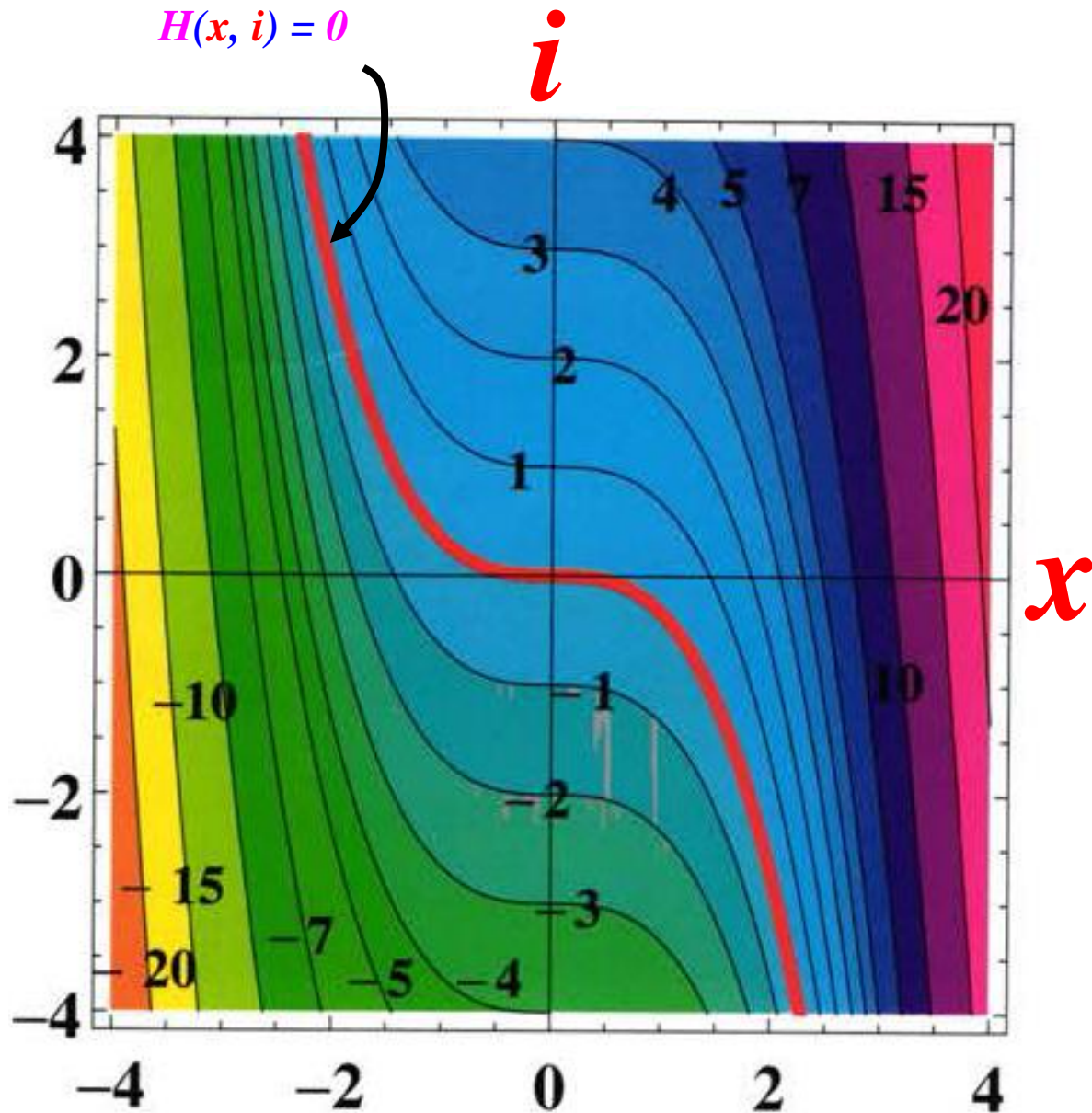
Int. J. of Bifurcation and Chaos

vol. 21, pp.2395-2425, 2011

Hamiltonian:

$$H(x, i) = \underbrace{\left(x + \frac{1}{3}x^3\right)}_{\text{Pseudo Potential Energy } H_x(x)} + \underbrace{i}_{\text{Pseudo Kinetic Energy } H_i(i)}$$

Pseudo Potential Energy  $H_x(x)$     Pseudo Kinetic Energy  $H_i(i)$

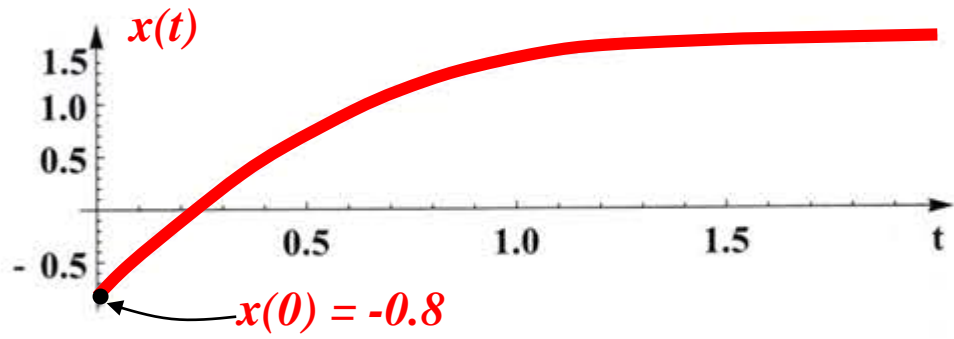


*The Hamiltonian has a constant value*

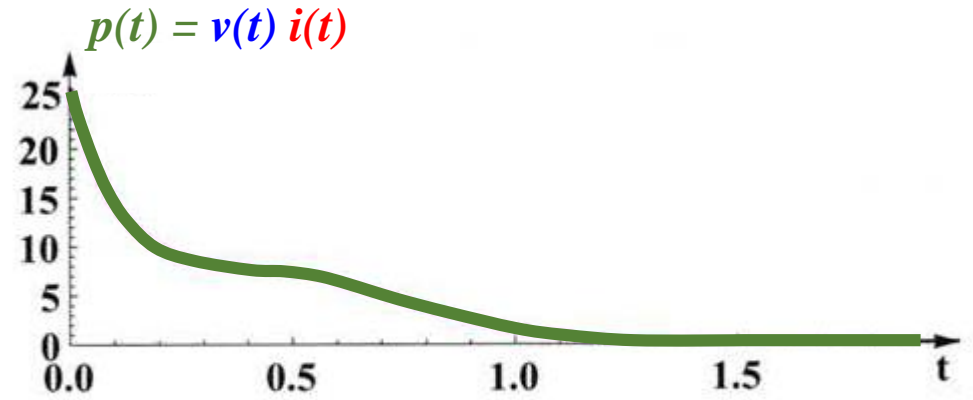
$H(x, i) = H_0$   
along each curve.

*Hamiltonian*

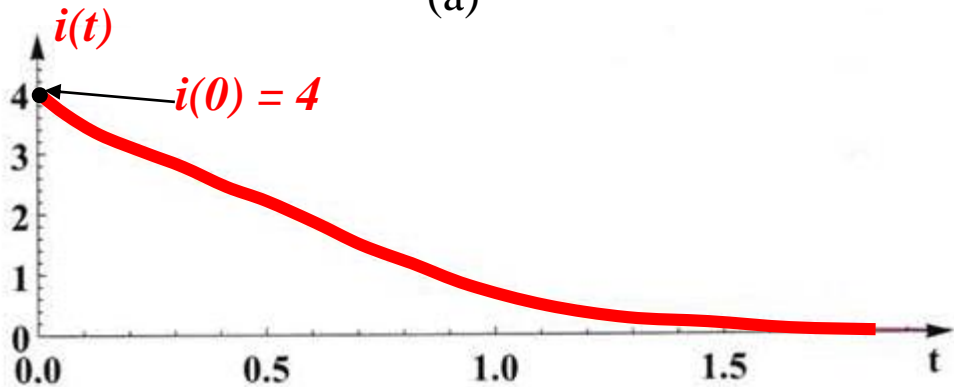
$$H(x, i) = x + \frac{1}{3}x^3 + i$$



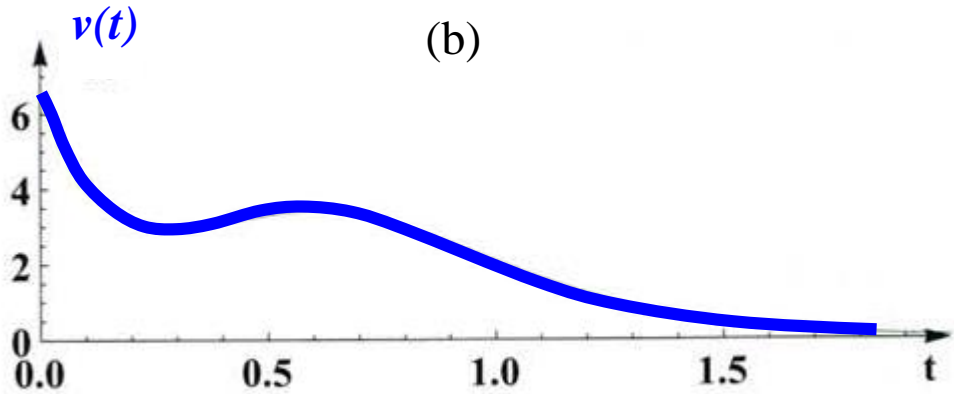
(a)



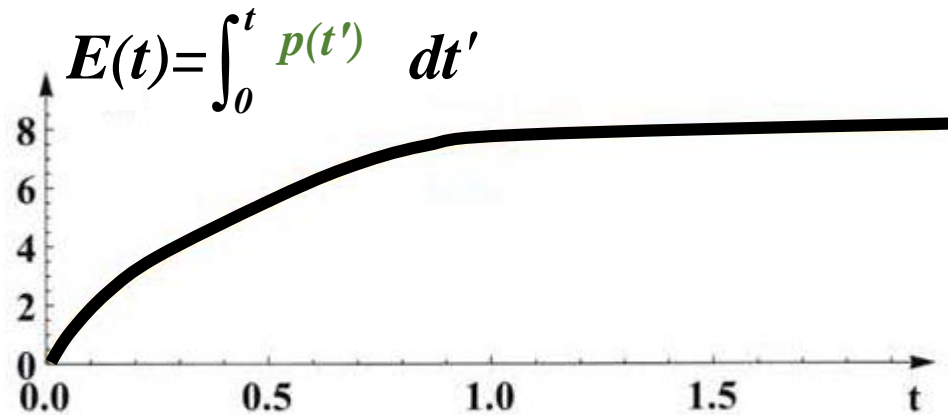
(d)



(b)



(c)



(e)

## Pseudo Potential Energy

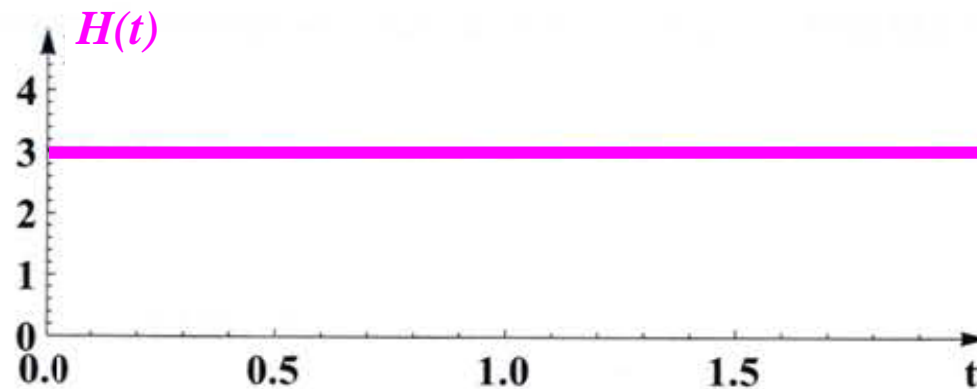
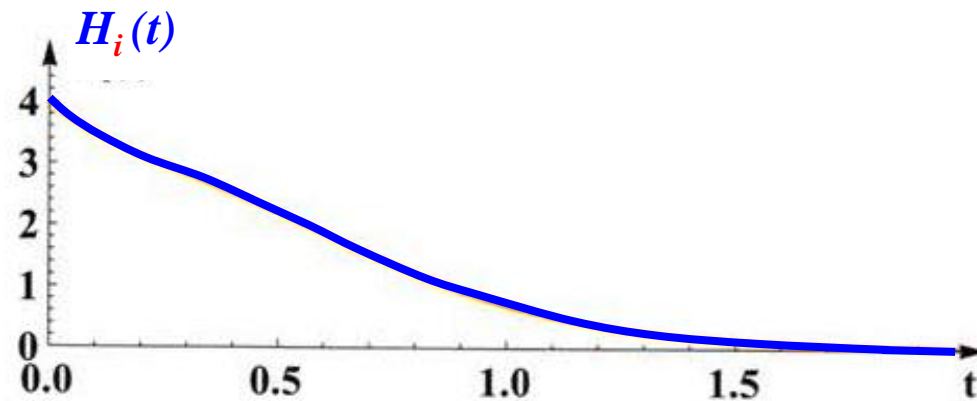
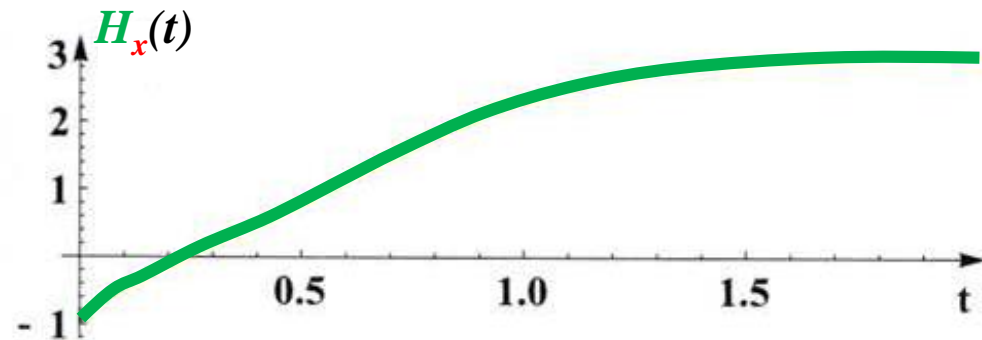
$$H_x = x + \frac{1}{3}x^3$$

## Pseudo Kinetic Energy

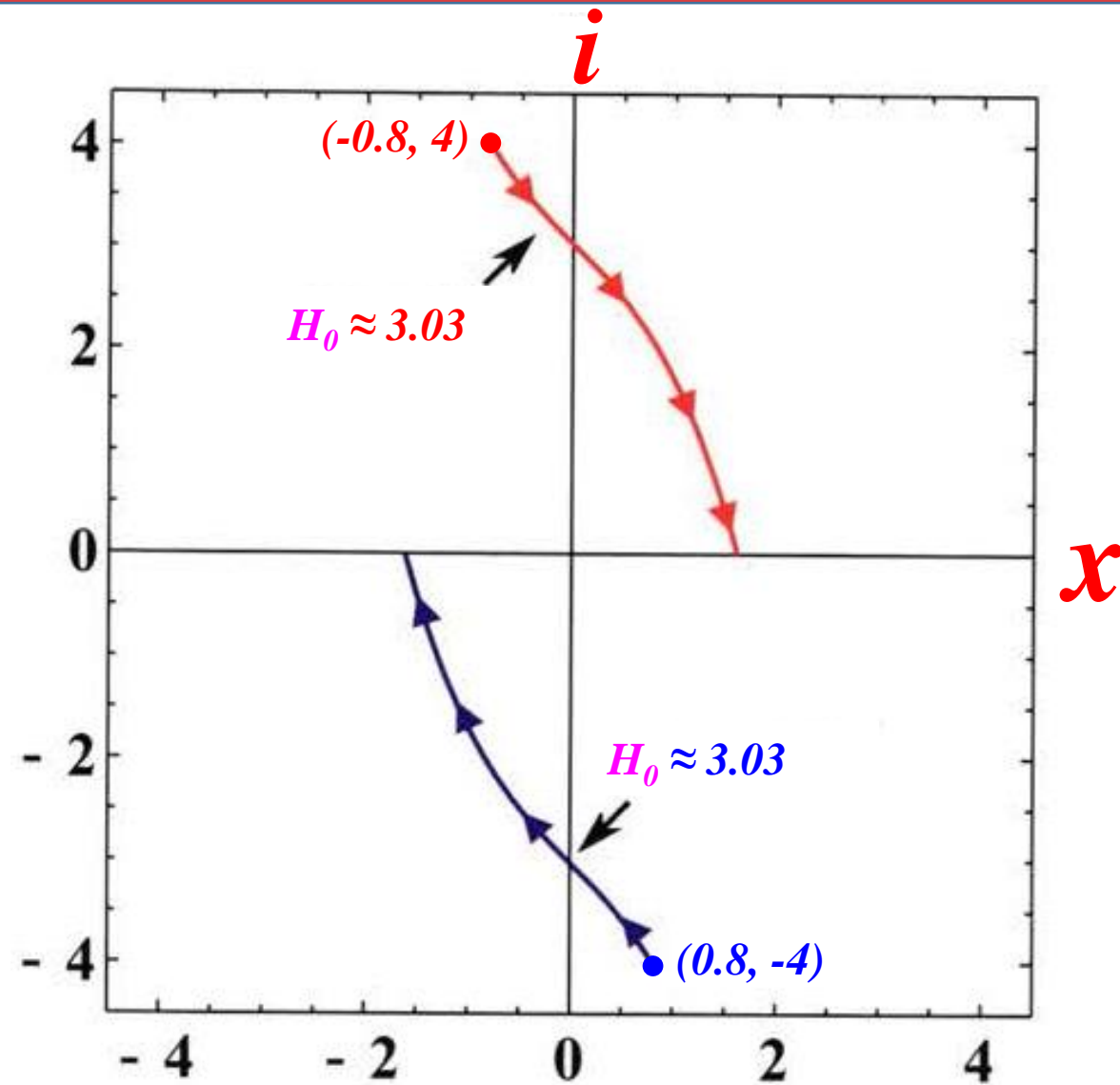
$$H_i = i$$

## Hamiltonian

$$H = \underbrace{H_x}_{\substack{\text{Pseudo} \\ \text{Potential} \\ \text{Energy}}} + \underbrace{H_i}_{\substack{\text{Pseudo} \\ \text{Kinetic} \\ \text{Energy}}}$$







*Two typical trajectories which tend to the  $x$ -axis along on the contour  $H_0 \approx 3.03$ .*

*Shocking Revelation !*

*Not all*

*Hamiltonian Systems*

*are*

*Conservative*

*Question :*

What *physical* quantity

is conserved in the

*Hamiltonian*  $H(x, i)$  ?

*Answer :*

**The *Hamiltonian*  $H(x, i)$**   
**conserved the total *flux***

$$\begin{array}{ccccc} \varphi(t) & = & \varphi(t) & + & \varphi(t) \\ \textit{Total} & & \textit{Inductor} & & \textit{Memristor} \end{array}$$

# Mendeleev's First Published Periodic Table, 1869

но въ ней, мнѣ кажется, уже ясно выражается примѣнимость выставляемаго мною начала во всей совокупности элементовъ, пай которыхъ извѣстенъ съ достовѣрностію. На этотъ разъ я и желалъ преимущественно найти общую систему элементовъ. Вотъ этотъ опытъ:

			Ti=50	Zr=90	?=180.
			V=51	Nb=94	Ta=182.
			Cr=52	Mo=96	W=186.
			Mn=55	Rh=104,4	Pt=197,4
			Fe=56	Ru=104,4	Ir=198.
			Ni=Co=59	Pt=106,6	Os=199.
			Cu=63,4	Ag=108	Hg=200.
			Zn=65,2	Cd=112	
			<b>?=68</b>	Ur=116	Au=197?
			<b>?=70</b>	Su=118	
			As=75	Sb=122	Bi=210
			Se=79,4	Te=128?	
			Br=80	I=127	
			Rb=85,4	Cs=133	Tl=204
			Sr=87,6	Ba=137	Pb=207.
			Ce=92		
			La=94		
			Di=95		
			Th=118?		
H=1					
	Be=9,4	Mg=24			
	B=11	Al=27,4			
	C=12	Si=28			
	N=14	P=31			
	O=16	S=32			
	F=19	Cl=35,5			
Li=7	Na=23	K=39			
		Ca=40			
		<b>?=45</b>			
		?Er=56			
		?Yt=60			
		?In=75,6			

**Ga**  
**Gallium**

**Sc**  
**Scandium**

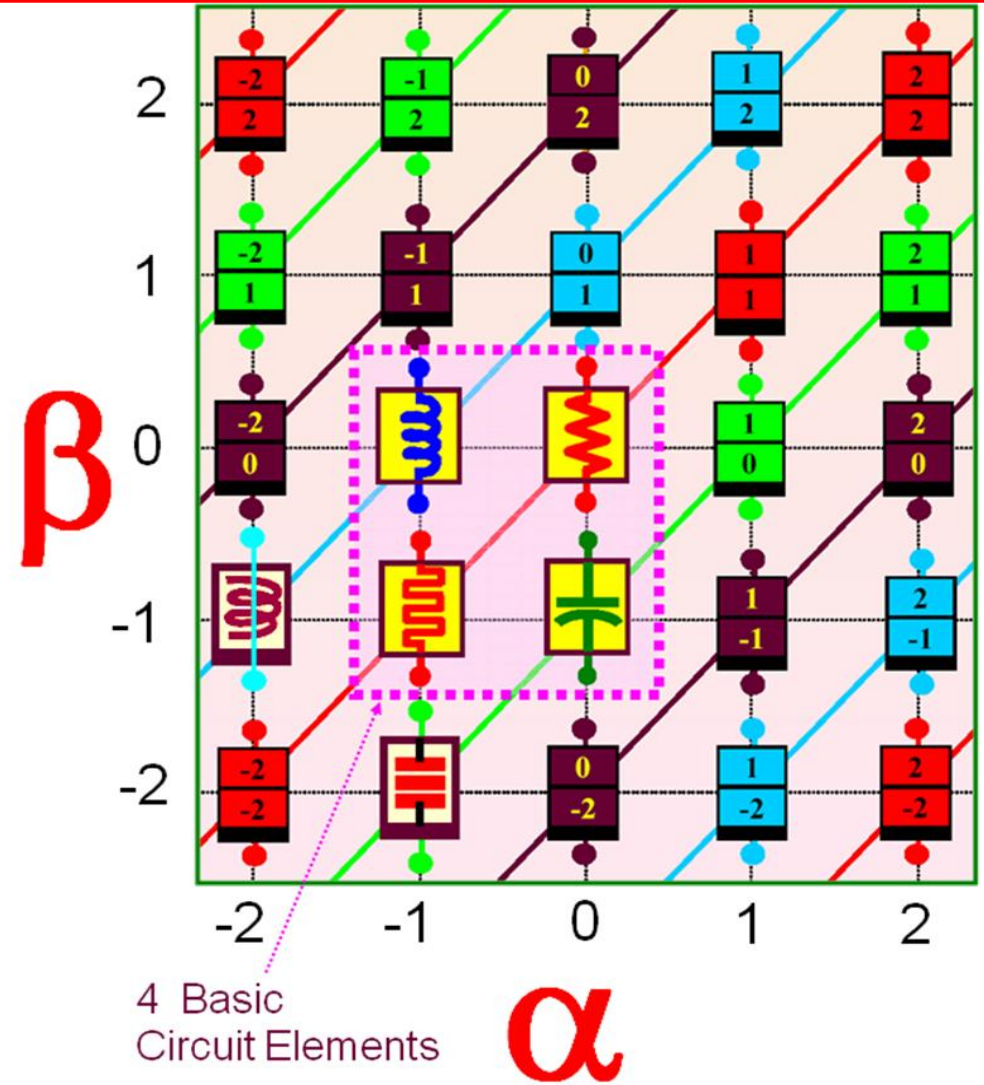
**Ge**  
**Germanium**

а потому приходится въ разныхъ рядахъ имѣть различное измѣненіе разностей, чего нѣтъ въ главныхъ числахъ предлагаемой таблицы. Или же придется предлагать при составленіи системы очень много недостающихъ членовъ. То и другое мало выгодно. Мнѣ кажется притомъ, наиболѣе естественнымъ составить

# The First 25 Circuit Elements

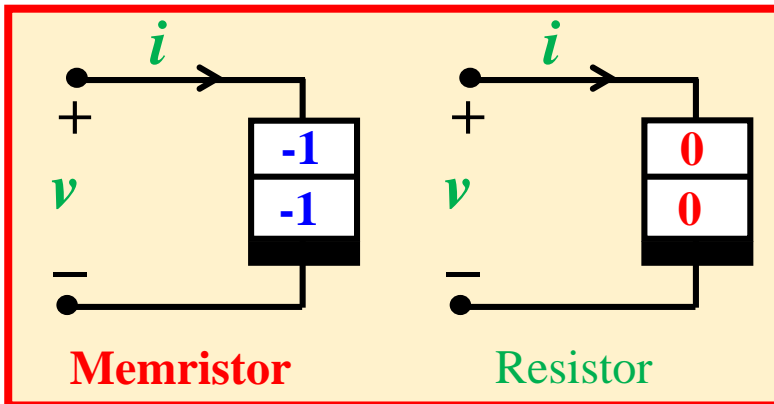
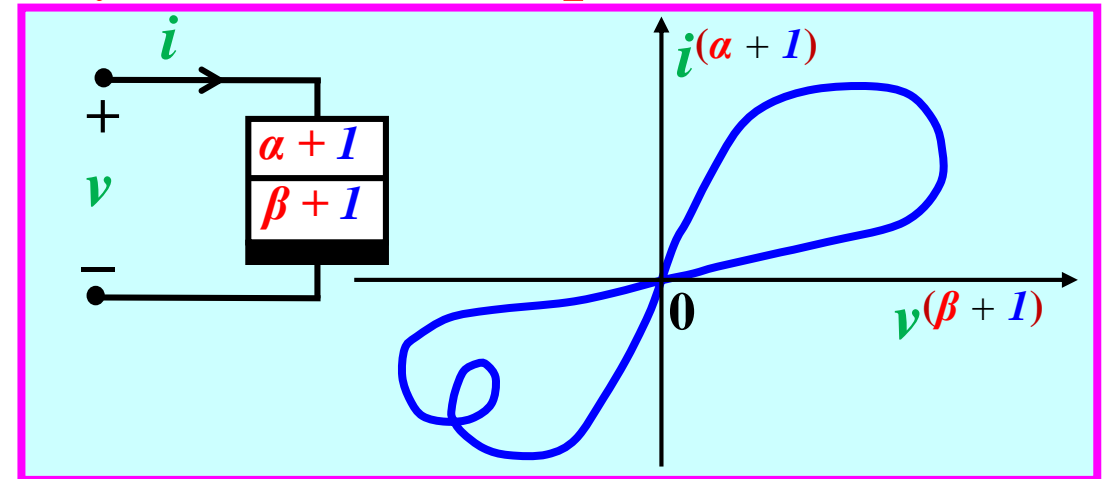
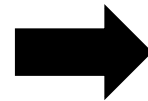
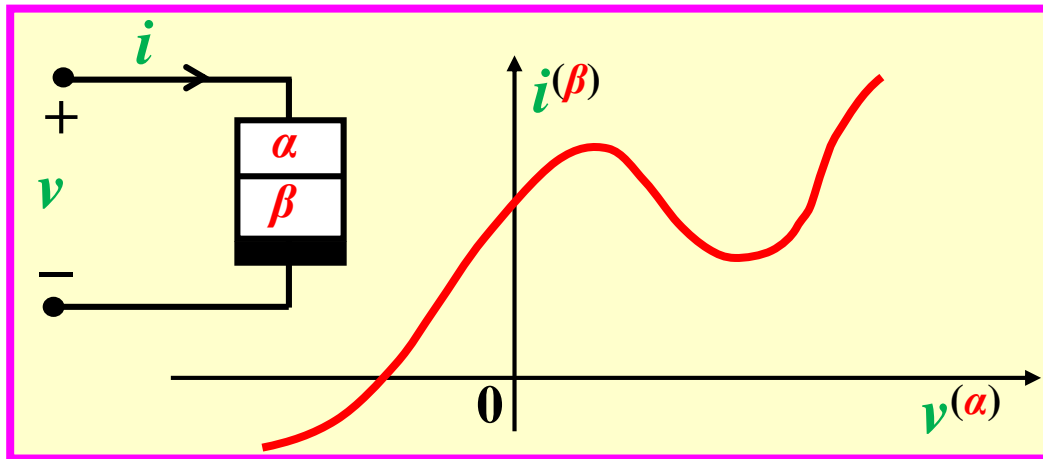
$$v^{(\alpha)}(t) \square \begin{cases} \frac{d^\alpha v(t)}{dt^\alpha}, & \text{if } \alpha = 1, 2, \dots, \infty \\ v(t), & \text{if } \alpha = 0 \\ \int_{-\infty}^t v(\tau) d\tau, & \text{if } \alpha = -1 \\ \int_{-\infty}^t \int_{-\infty}^{\tau_{|\alpha|}} \dots \int_{-\infty}^{\tau_2} v(\tau_1) d\tau_1 d\tau_2 \dots d\tau_{|\alpha|}, & \text{if } \alpha = -2, -3, \dots, \infty \end{cases}$$

$$i^{(\beta)}(t) \square \begin{cases} \frac{d^\beta i(t)}{dt^\beta}, & \text{if } \beta = 1, 2, \dots, \infty \\ i(t), & \text{if } \beta = 0 \\ \int_{-\infty}^t i(\tau) d\tau, & \text{if } \beta = -1 \\ \int_{-\infty}^t \int_{-\infty}^{\tau_{|\beta|}} \dots \int_{-\infty}^{\tau_2} i(\tau_1) d\tau_1 d\tau_2 \dots d\tau_{|\beta|}, & \text{if } \beta = -2, -3, \dots, \infty \end{cases}$$

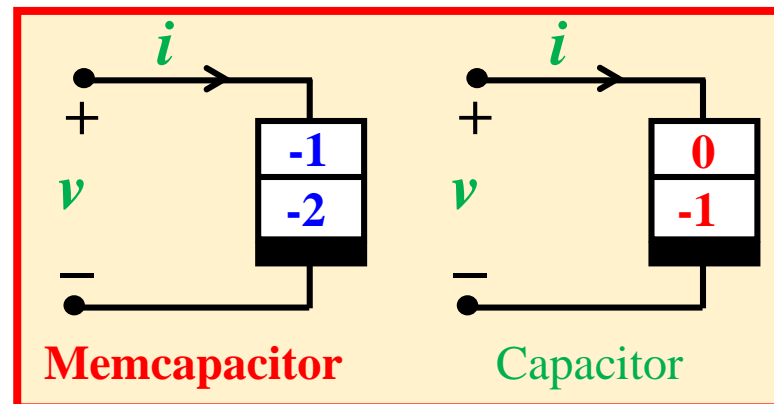


# Universal Pinched Hysteresis Loop Theorem

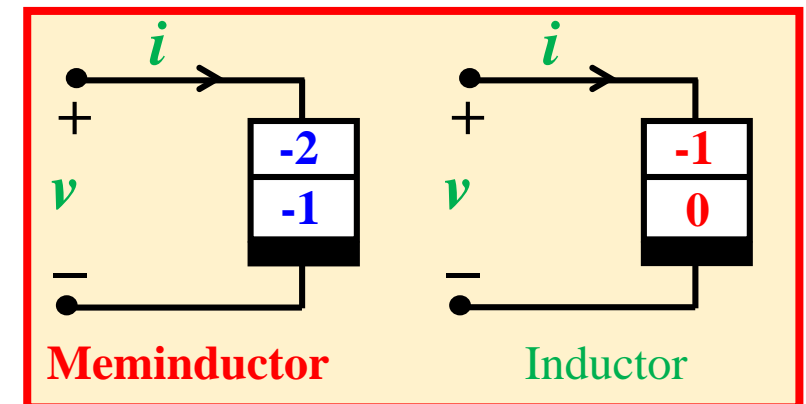
The  $((\alpha + 1), (\beta + 1))$  element associated with any  $(\alpha, \beta)$  element *must* exhibit a *pinched hysteresis loop*.



Example 1

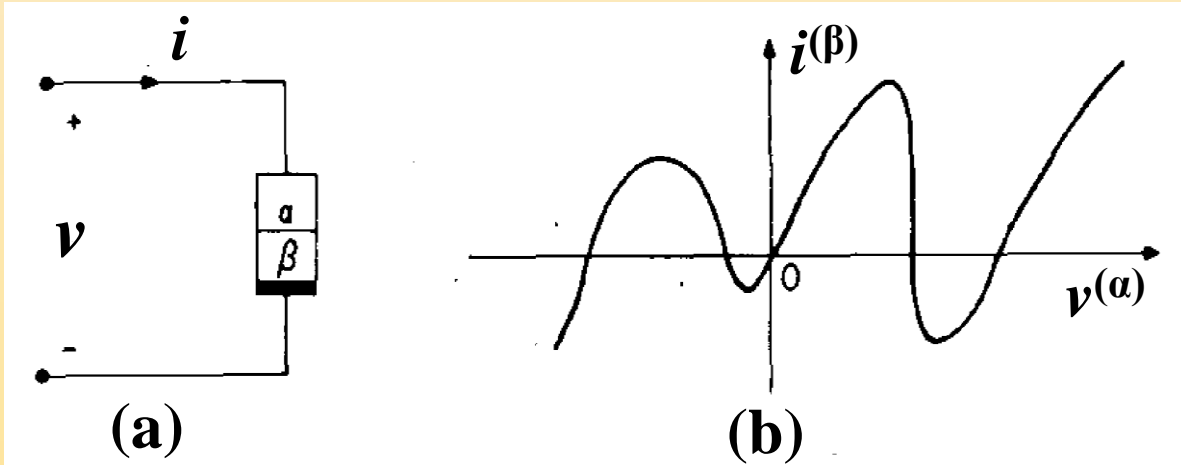


Example 2



Example 3

# $(\alpha, \beta)$ - Elements



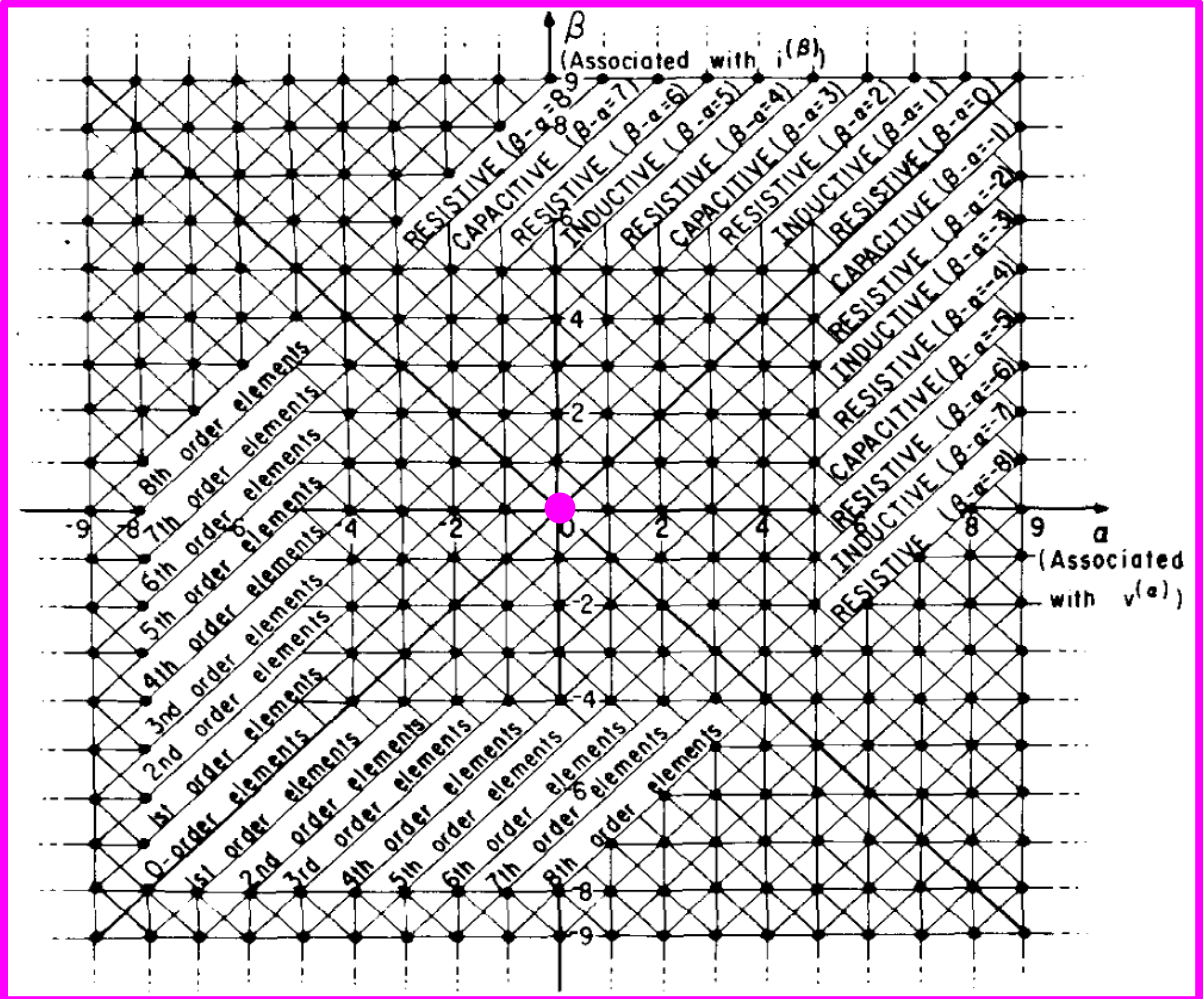
(a) Symbol for a  $v^{(\alpha)} - i^{(\beta)}$  element. (b) The constitutive relation of a curve or subset of points in the  $v^{(\alpha)} - i^{(\beta)}$  plane.

**Leon Chua**

*Device Modelling Via Basic Nonlinear  
Circuit Elements*

*IEEE Transactions on Circuits and Systems*  
vol. CAS-27, No. 11, pp. 1014-1044,

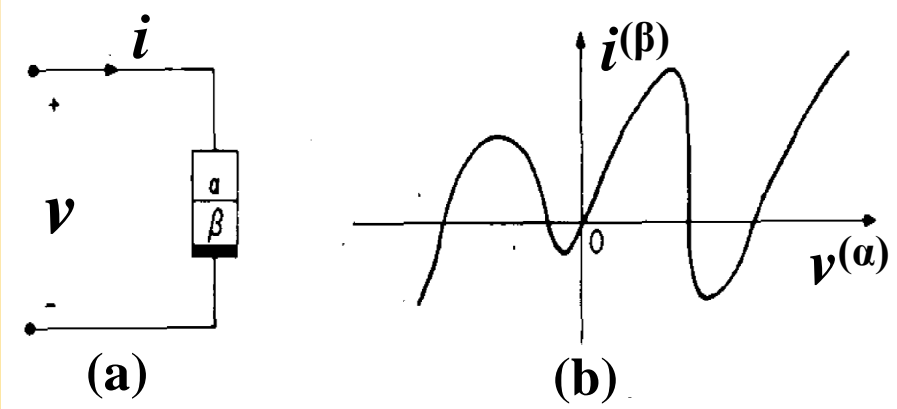
**1980**



Circuit-element array: Each dot with coordinates  $(\alpha, \beta)$  denotes a  $v^{(\alpha)} - i^{(\beta)}$  element.



# $(\alpha, \beta)$ - Elements



(a) Symbol for a  $v^{(\alpha)} - i^{(\beta)}$  element. (b) The constitutive relation of a curve or subset of points in the  $v^{(\alpha)} - i^{(\beta)}$  plane.

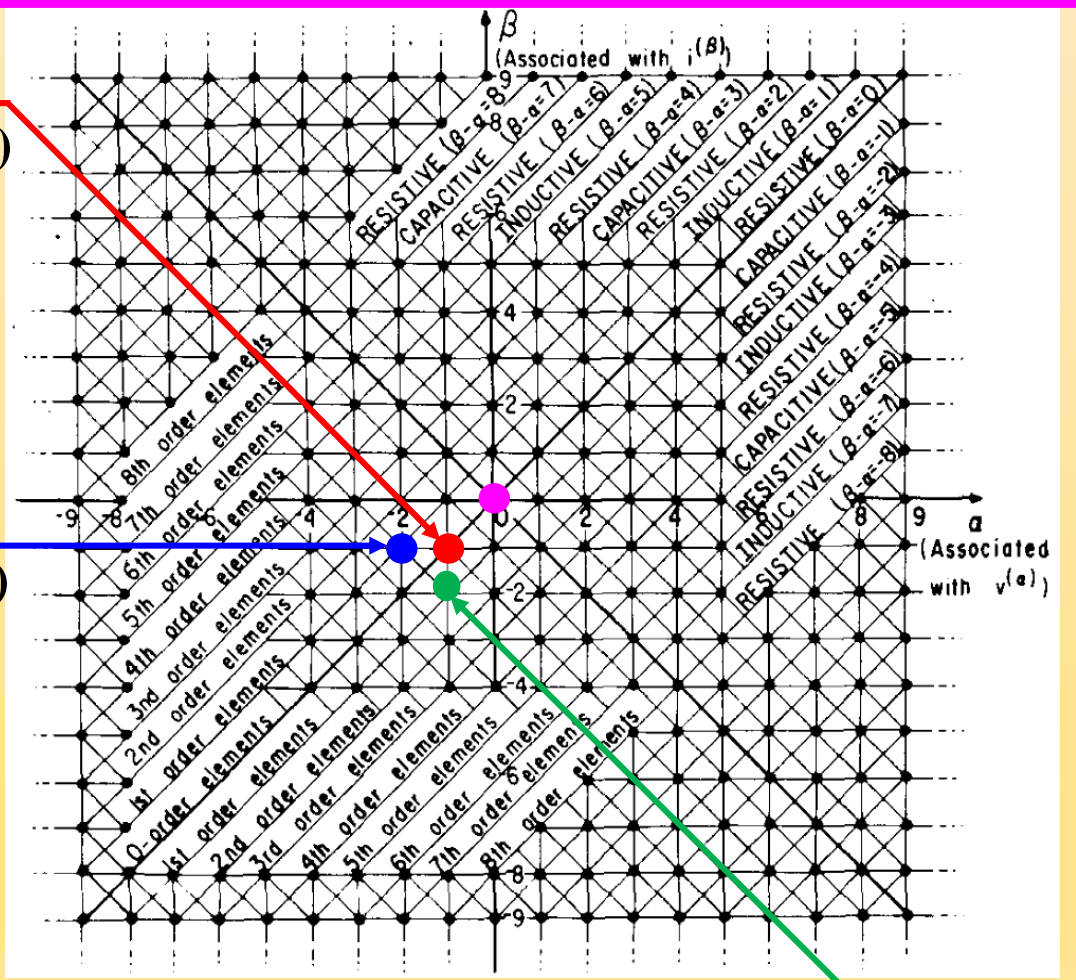
**Leon Chua**  
*Device Modelling Via Basic Nonlinear Circuit Elements*  
*IEEE Transactions on Circuits and Systems*  
 vol. CAS-27, No. 11, pp. 1014-1044,  
**1980**

## Memristor

$(\alpha, \beta) = (-1, -1)$

## Meminductor

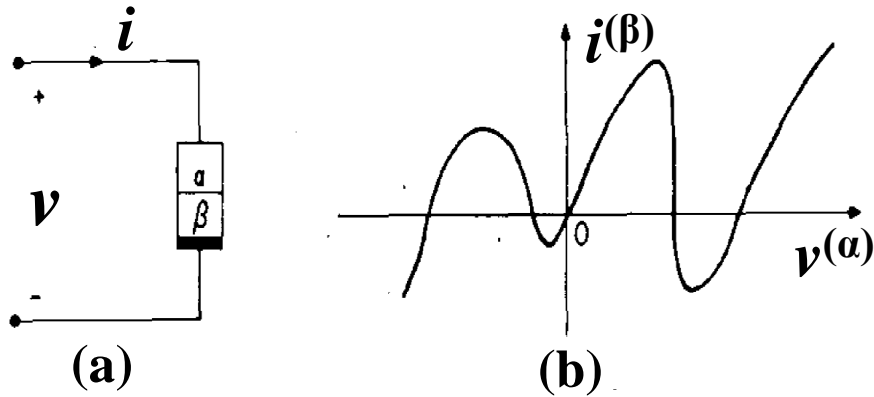
$(\alpha, \beta) = (-2, -1)$



## Memcapacitor

$(\alpha, \beta) = (-1, -2)$

# The Golden Strip



(a) Symbol for a  $v^{(\alpha)} - i^{(\beta)}$  element. (b) The constitutive relation of a curve or subset of points in the  $v^{(\alpha)} - i^{(\beta)}$  plane.

## Leon Chua

*Device Modelling Via Basic Nonlinear Circuit Elements*

*IEEE Transactions on Circuits and Systems*  
 vol. CAS-27, No. 11, pp. 1014-1044,  
**1980**

### Memristor

$$(\alpha, \beta) = (-1, -1)$$

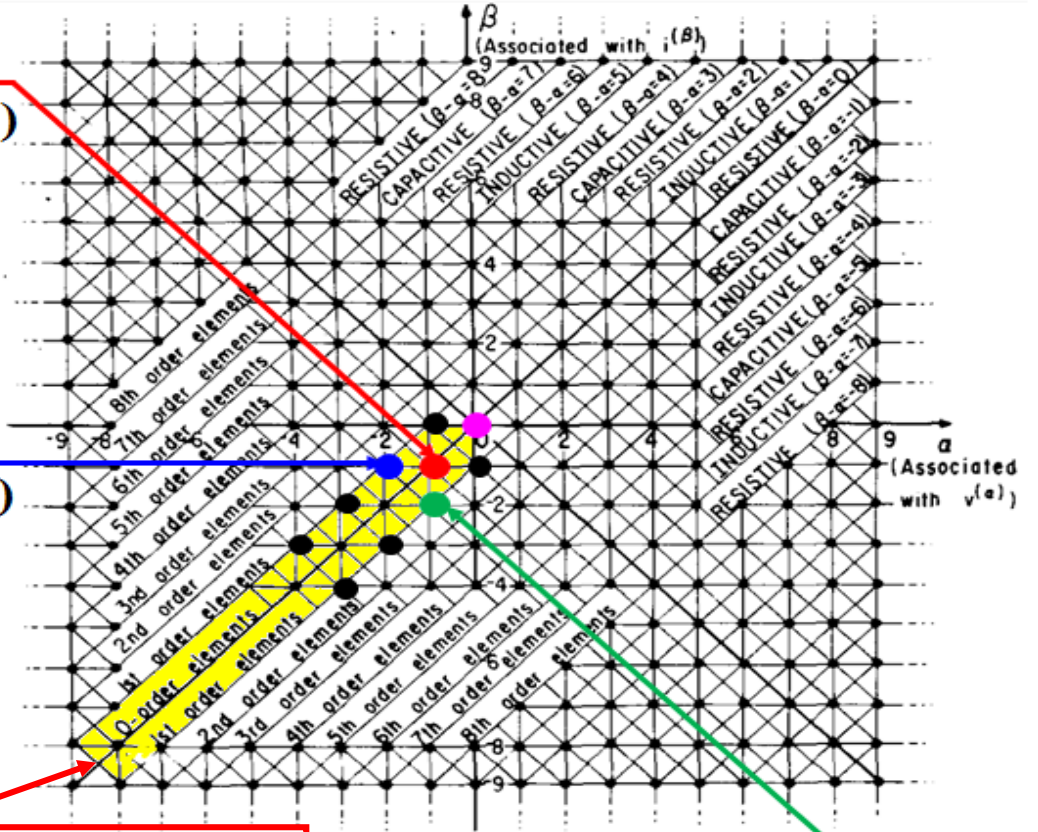
### Meminductor

$$(\alpha, \beta) = (-2, -1)$$

$$\text{Golden Strip : } \alpha \leq 0, \beta \leq 0 \\ |\alpha - \beta| \leq 2$$

### Memcapacitor

$$(\alpha, \beta) = (-1, -2)$$



**Theorem:** Only elements belonging to the Golden Strip are passive and physically realizable.



# HIGH-ORDER NON-LINEAR CIRCUIT ELEMENTS: CIRCUIT-THEORETIC PROPERTIES

LEON O. CHUA AND ELLEN W. SZETO

*Department of Electrical Engineering and Computer Sciences, and Electronics Research Laboratory, University of California, Berkeley,  
CA 94720, U.S.A.*

## SUMMARY

Higher- and mixed-order non-linear circuit elements have been introduced to provide a logically complete formulation for non-linear circuit theory. In this paper, we analyse the circuit-theoretic properties of these elements, including *reciprocity*, *passivity* and *losslessness*. We have derived necessary and sufficient conditions for a higher- or mixed-order *n*-port element to be reciprocal or antireciprocal. We have shown that under very mild assumptions, most *non-linear* higher-order 2-terminal elements are active and not lossless. Finally, we show that the number of lossless *linear* higher-order 2-terminal elements far exceeds that of the passive linear elements.

# *Inspiration from Chemistry*

The latest *Periodic Table* contains

***118 elements*** :

- ***92 elements*** exist in *nature*.
- ***26 elements*** are *artificially synthesized*.

Most *synthesized elements* are *unstable* ---  
some exist for only a few *milliseconds*, then  
decomposed into two lighter elements.

1  
**H**

HYDROGEN

# Periodic Table of the Elements

The periodic table lists all the known elements of the universe. Here, the human-made ones are called out. Scientists are working to find out if the table ever ends.

Atomic Number  
number of protons

Atomic Symbol

2  
**He**

HELIUM

3  
**Li**

LITHIUM

4  
**Be**

BERYLLIUM

5  
**B**

BORON

6  
**C**

CARBON

7  
**N**

NITROGEN

8  
**O**

OXYGEN

9  
**F**

FLUORINE

10  
**Ne**

NEON

11  
**Na**

SODIUM

12  
**Mg**

MAGNESIUM

13  
**Al**

ALUMINUM

14  
**Si**

SILICON

15  
**P**

PHOSPHORUS

16  
**S**

SULFUR

17  
**Cl**

CHLORINE

18  
**Ar**

ARGON

19  
**K**

POTASSIUM

20  
**Ca**

CALCIUM

21  
**Sc**

SCANDIUM

22  
**Ti**

TITANIUM

23  
**V**

VANADIUM

24  
**Cr**

CHROMIUM

25  
**Mn**

MANGANESE

26  
**Fe**

IRON

27  
**Co**

COBALT

28  
**Ni**

NICKEL

29  
**Cu**

COPPER

30  
**Zn**

ZINC

31  
**Ga**

GALLIUM

32  
**Ge**

GERMANIUM

33  
**As**

ARSENIC

34  
**Se**

SELENIUM

35  
**Br**

BROMINE

36  
**Kr**

KRYPTON

37  
**Rb**

RUBIDIUM

38  
**Sr**

STRONTIUM

39  
**Y**

YTTRIUM

40  
**Zr**

ZIRCONIUM

41  
**Nb**

NIOBIUM

42  
**Mo**

MOYBDENUM

43  
**Tc**

TECHNETIUM

44  
**Ru**

RUTHENIUM

45  
**Rh**

RHODIUM

46  
**Pd**

PALLADIUM

47  
**Ag**

SILVER

48  
**Cd**

CADMIUM

49  
**In**

INDIUM

50  
**Sn**

TIN

51  
**Sb**

ANTIMONY

52  
**Te**

TELLURIUM

53  
**I**

IODINE

54  
**Xe**

XENON

55  
**Cs**

CAESIUM

56  
**Ba**

BARIUM

72  
**Hf**

HAFNIUM

73  
**Ta**

TANTALUM

74  
**W**

TUNGSTEN

75  
**Re**

RHENIUM

76  
**Os**

OSMIUM

77  
**Ir**

IRIDIUM

78  
**Pt**

PLATINUM

79  
**Au**

GOLD

80  
**Hg**

MERCURY

81  
**Tl**

THALLIUM

82  
**Pb**

LEAD

83  
**Bi**

BISMUTH

84  
**Po**

POLONIUM

85  
**At**

ASTATINE

86  
**Rn**

RADON

87  
**Fr**

FRANCIUM

88  
**Ra**

RADIUM

104  
**Rf**

RUTHERFORDIUM

105  
**Db**

DUBNIUM

106  
**Sg**

SEABORGIUM

107  
**Bh**

BOHRIUM

108  
**Hs**

HASSIUM

109  
**Mt**

MEITNERIUM

110  
**Ds**

DARMSTADTIUM

111  
**Rg**

ROENTGENIUM

112  
**Cn**

COPIERNICIUM

113  
**Uut**

UNUNTRIUM

114  
**Fl**

FLEROVIUM

115  
**Uup**

UNUNPENTIUM

116  
**Lv**

LIVERMORIUM

117  
**Uus**

UNUNSEPTIUM

118  
**Uuo**

UNUNOCTIUM

57  
**La**

LANTHANUM

58  
**Ce**

CERIUM

59  
**Pr**

PRASEODYMIUM

60  
**Nd**

NEODYMIUM

61  
**Pm**

PROMETHIUM

62  
**Sm**

SAMARIUM

63  
**Eu**

EUROPIUM

64  
**Gd**

GADOLINIUM

65  
**Tb**

TERBIUM

66  
**Dy**

DYSPROSIUM

67  
**Ho**

HOLMIUM

68  
**Er**

ERBIUM

69  
**Tm**

THULIUM

70  
**Yb**

YTBERIUM

71  
**Lu**

LUTETIUM

89  
**Ac**

ACTINIUM

90  
**Th**

THORIUM

91  
**Pa**

PROTACTINIUM

92  
**U**

URANIUM

93  
**Np**

NEPTUNIUM

94  
**Pu**

PLUTONIUM

95  
**Am**

AMERICIUM

96  
**Cm**

CURIUM

97  
**Bk**

BERKELIUM

98  
**Cf**

CALIFORNIUM

99  
**Es**

EINSTEINIUM

100  
**Fm**

FERMIUM

101  
**Md**

Mendelevium

102  
**No**

Nobelium

103  
**Lr**

Lawrencium

Synthetic  
elements

*Nonlinear Circuit Theory predicts the existence of infinitely many passive  $(\alpha, \beta)$  - elements*

So far, *only 4 passive circuit elements* have been built *without power supply*:

- *Resistor*
- *Inductor*
- *Capacitor*
- *Memristor*

*A **Cap** for Number of Chemical  
Elements*

*No Element beyond*

*137*

*can exist ; because it would  
violate the laws of physics.*



# *The Mysterious 137*

$Fy^{137}$

*Feynmanium*

# *Fractional - Order*

*mem* – (*a*, *β*)

*Circuit elements*

**0**    $\vee$    *a*    $\vee$    **1**

**0**    $\wedge$    *β*    $\wedge$    **1**

# Fractional Derivative

**Definition : Fractional Derivative**  
**(Riemann – Liouville definition)**

$${}^R D_t^\alpha f(t) = \frac{1}{\Gamma(n-\alpha)} \frac{d^n}{dt^n} \int_a^t (t-\tau)^{n-\alpha-1} f(\tau) d\tau$$

$$= \frac{d^n}{dt^n} \left( {}_a J_t^{n-\alpha} f(t) \right), \quad t > a,$$

$$n-1 \leq \alpha < n,$$

where  $\Gamma$  is the gamma function and

${}_a J_t^\beta$  is the **Riemann-Liouville**

integral operator defined by:

$${}_a J_t^\beta = \frac{1}{\Gamma(\beta)} \int_a^t (t-\tau)^{\beta-1} f(\tau) d\tau.$$

**Laplace Transform of Riemann**  
**- Liouville differential Operator**

The Laplace Transform of the  $\alpha$ -order **Riemann-Liouville differential operator** is:

$$L\left\{{}_0^R D_t^\alpha f(t)\right\} = s^\alpha L\{f(t)\}$$

$$- \sum_{k=0}^{n-1} s^k \left[ {}_0^R D_t^{\alpha-1-k} f(t) \right]_{t=0}.$$

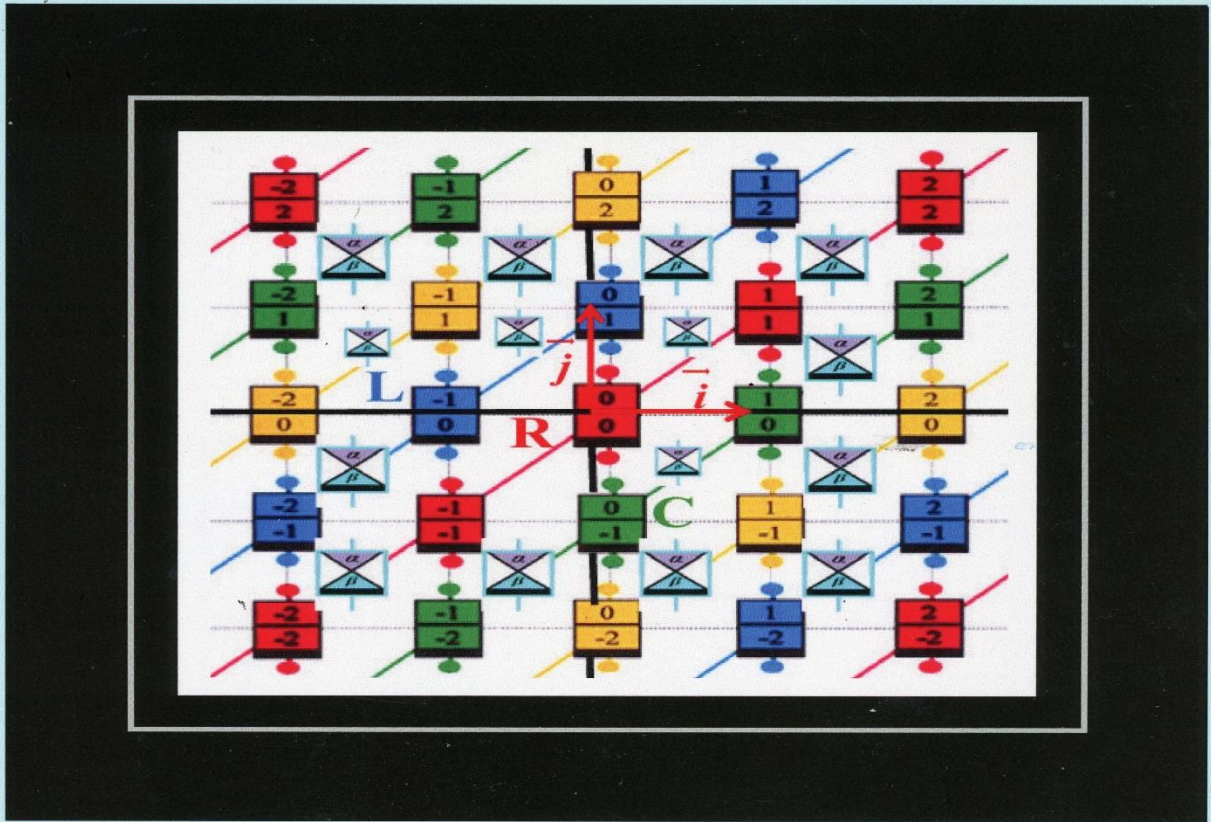
For zero initial conditions we have

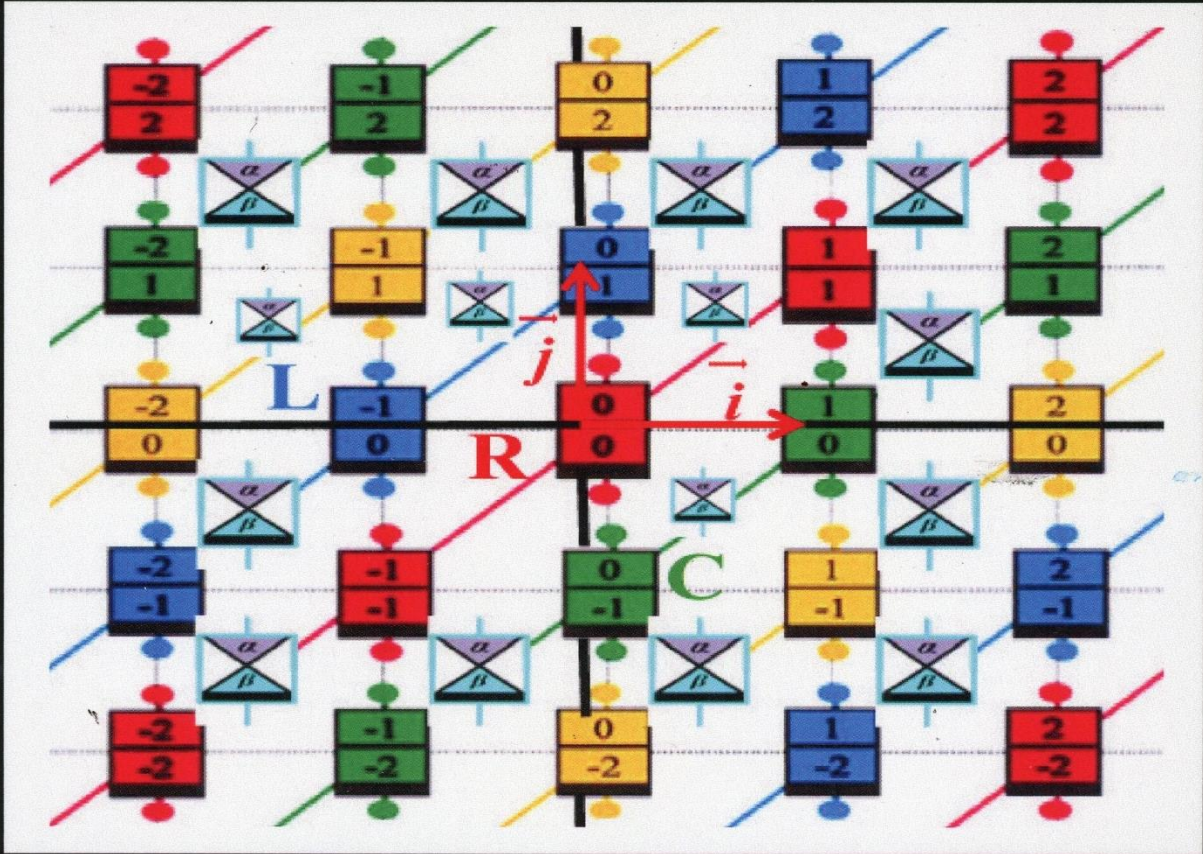
$$L\left\{{}_0 D_t^\alpha f(t)\right\} = s^\alpha L\{f(t)\}$$

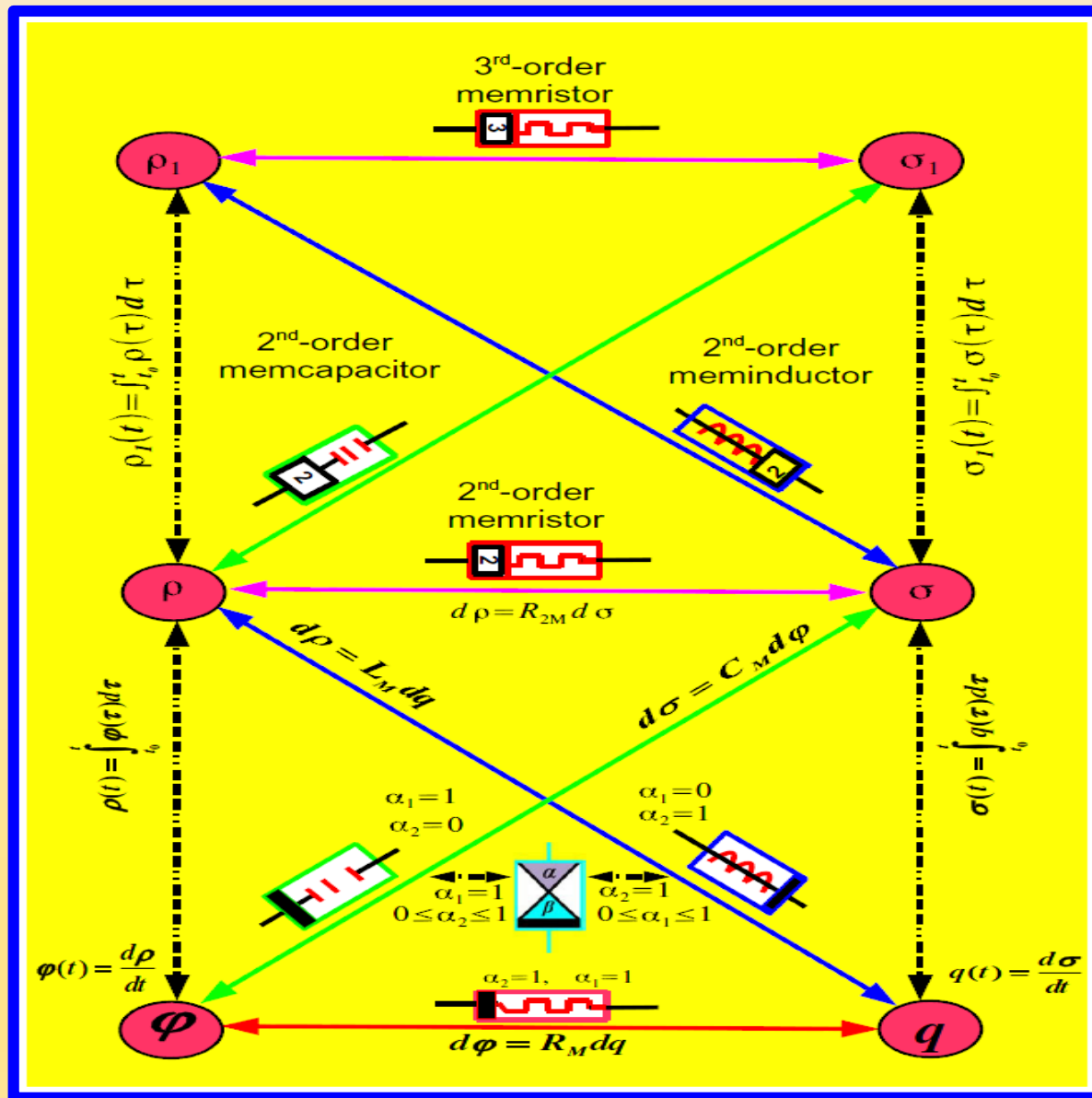
INTERNATIONAL JOURNAL OF  
**BIFURCATION AND CHAOS**  
IN APPLIED SCIENCES AND ENGINEERING



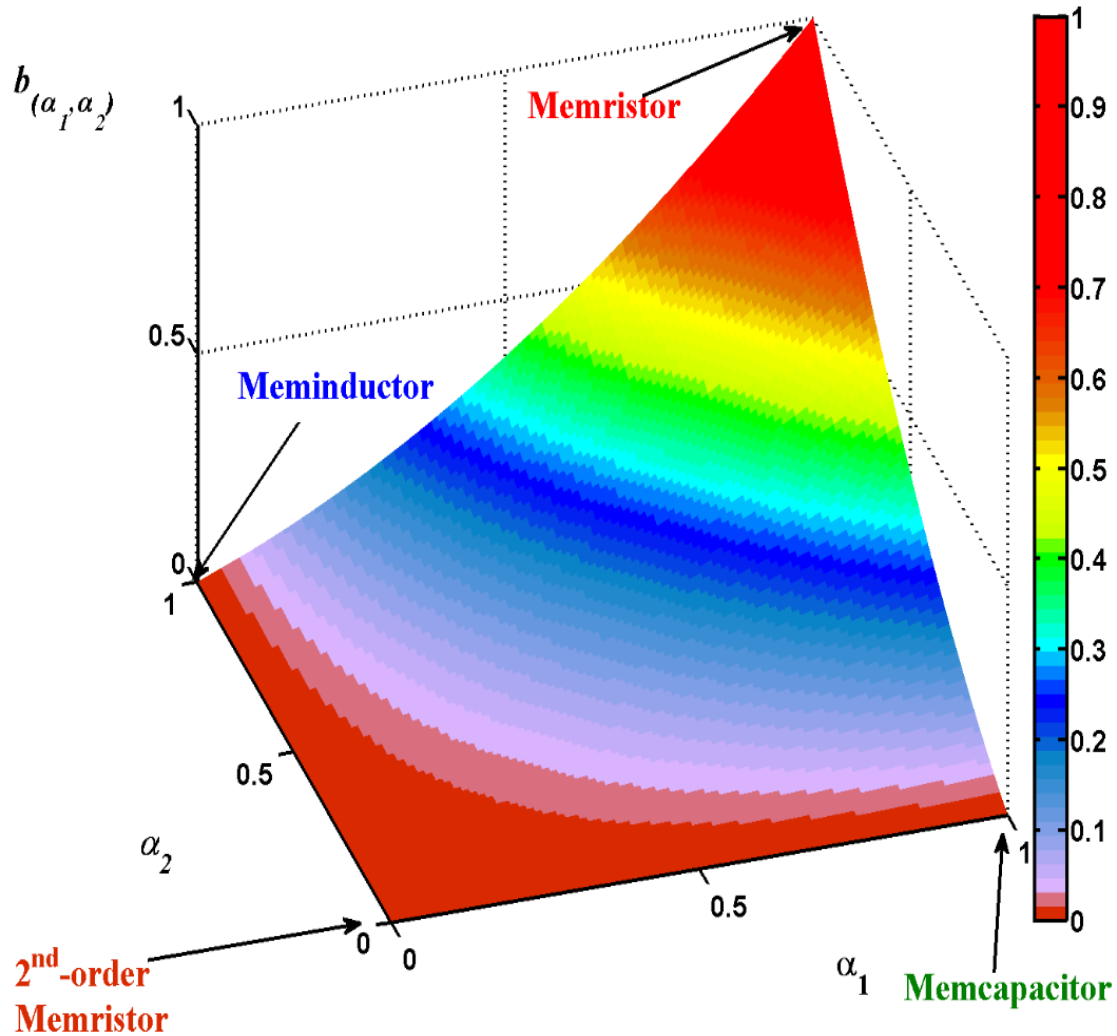
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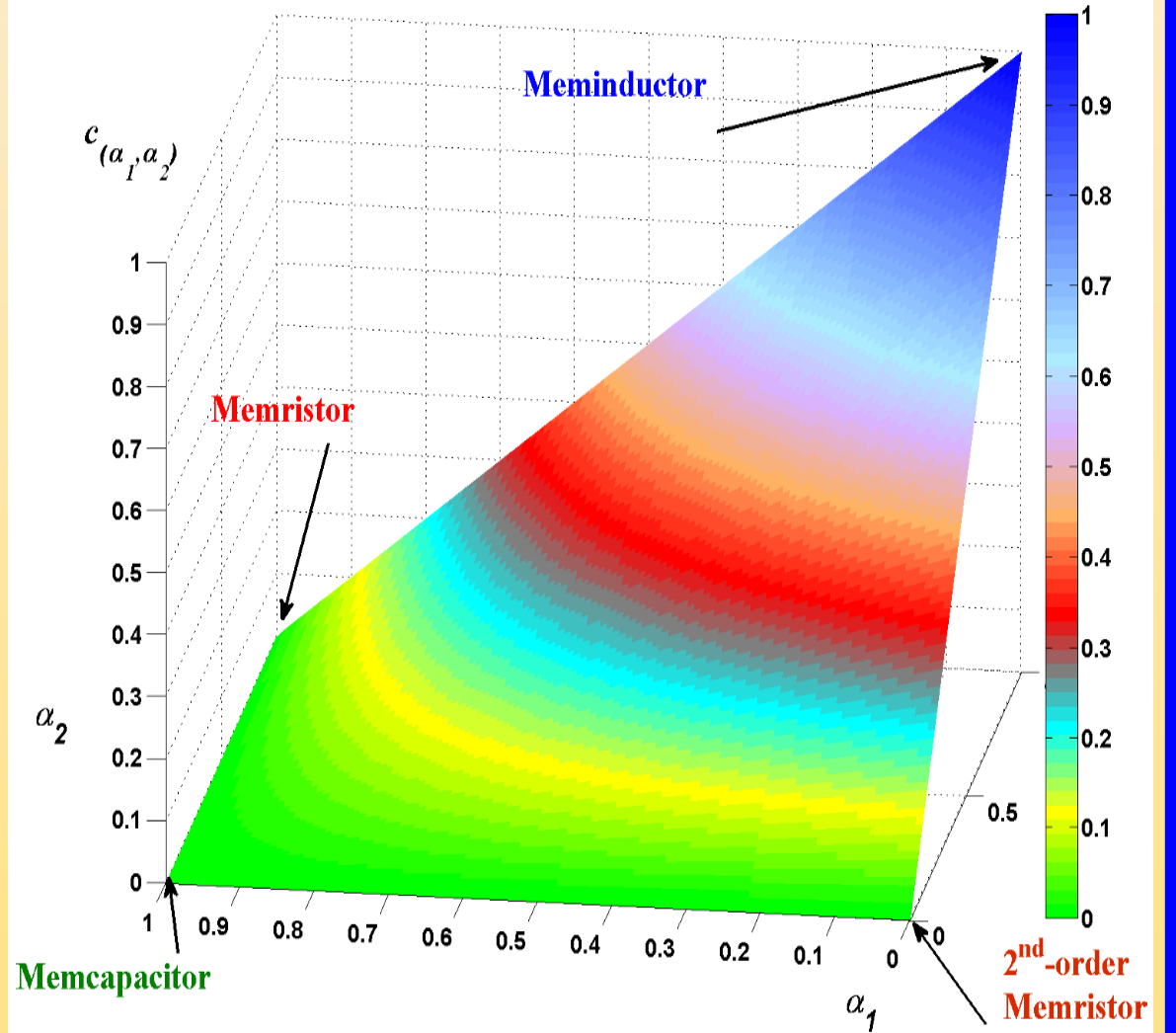


Interpolated characteristics of *memfactor* between a *memcapacitor*, a *memristor*, a *meminductor* and a second-order *memristor*.



Graphical representation of the coefficient

$$b_{(a_1, a_2)} = \alpha_1 \alpha_2 \frac{(\alpha_1 + \alpha_2)}{2}.$$



Graphical representation of the coefficient

$$c_{(a_1, a_2)} = \alpha_2 (1 - \alpha_1).$$



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## Memfractance: A Mathematical Paradigm for Circuit Elements with Memory

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René Lozi

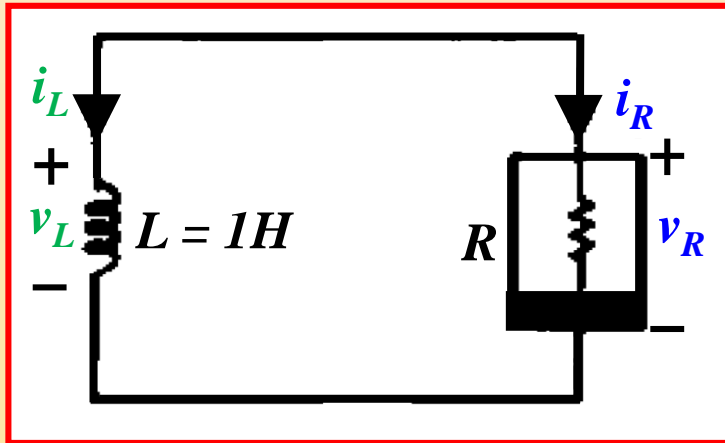
*Laboratory of Mathematics J. A. Dieudonné,  
U.M.R. CNRS 7351, University of Nice-Sophia Antipolis,  
Parc Valrose, 06108 Nice Cedex 02, France  
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Leon Chua

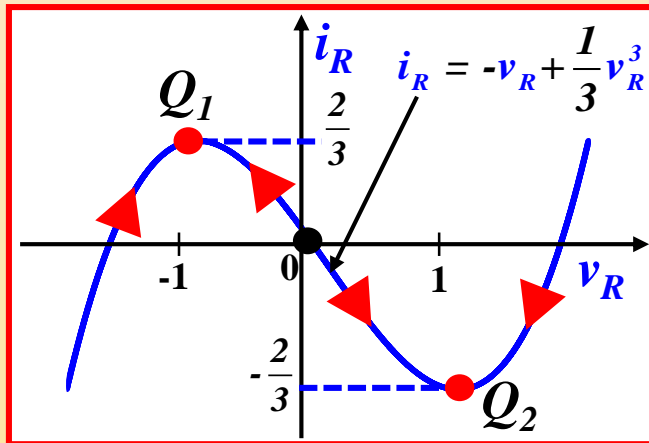
*Department of Electrical Engineering and Computer Sciences,  
University of California, Berkeley, CA 94720, USA  
chua@eecs.berkeley.edu*



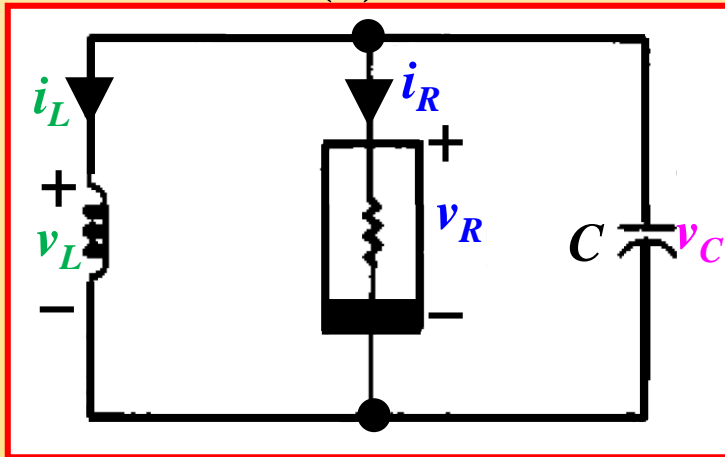
# The Curse of Impasse Points



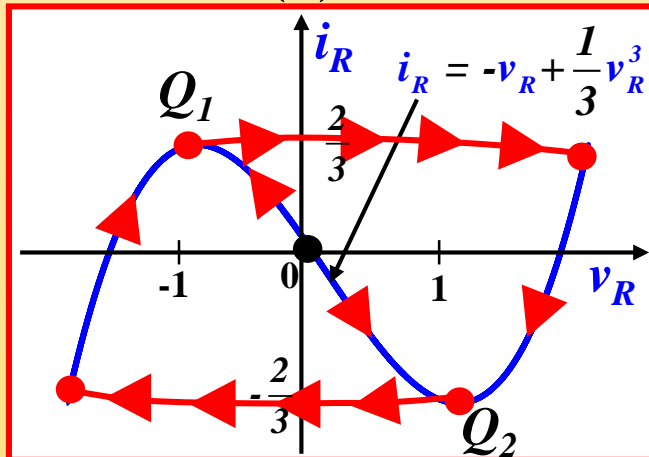
(a)



(b)

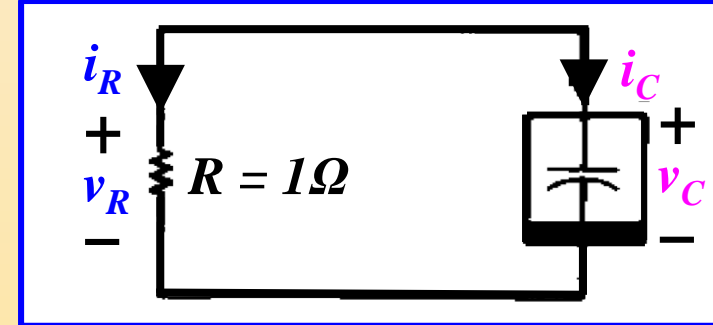


(c)

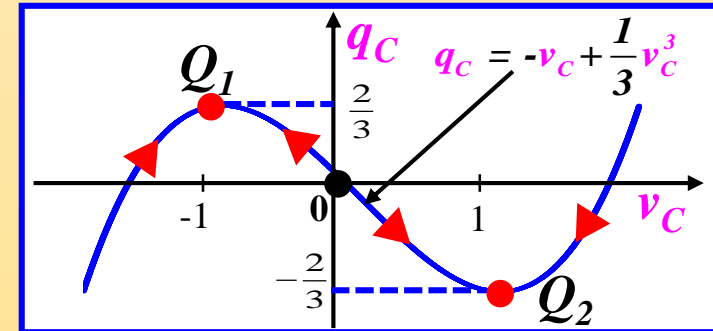


(d)

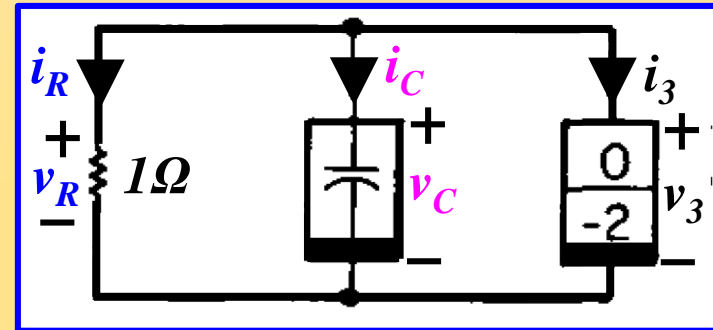
*Circuit for demonstrating the necessity of connecting a capacitor across a nonmonotonic voltage-controlled Resistor.*



(a)



(b)



(c)

*Circuit for demonstrating the necessity of connecting a  $v^{(0)} - i^{(-2)}$  element across a nonmonotonic voltage-controlled Capacitor.*

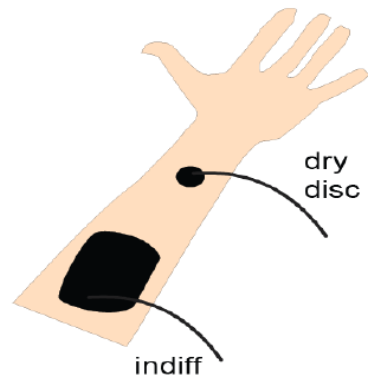
*Memristors*

are

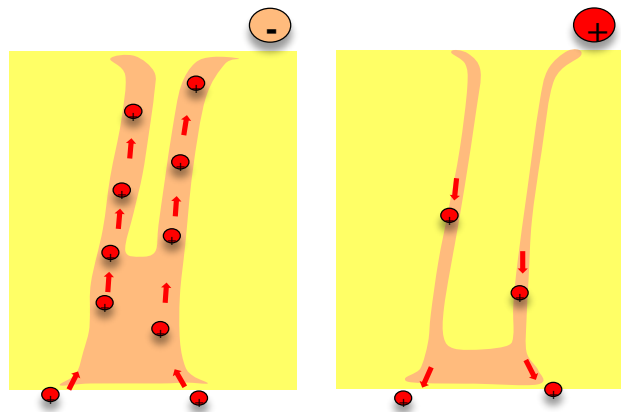
*Ubiquitous !*

# *Sweat Ducts are Memristors*

(a)

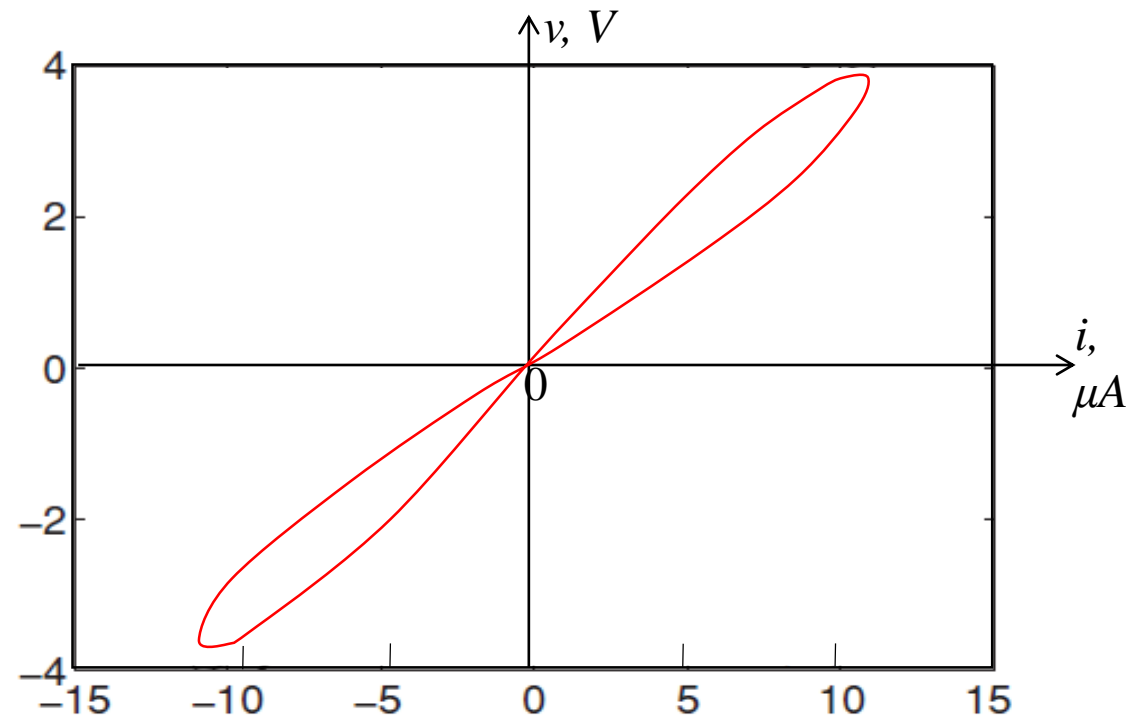


(b)

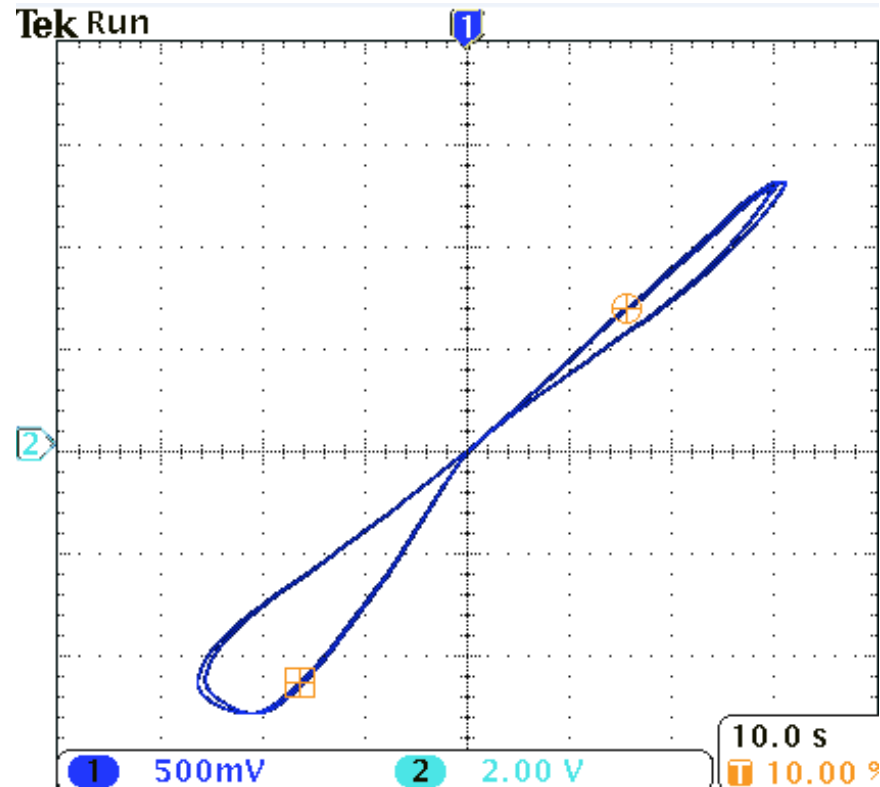


(c)

*Pinched Hysteresis Loop Measured from the  
Sweat duct*



# *Memristive Properties of Skin*



Measured by:  
Olivier Pabst, PhD Student

Supervisor:  
Professor Orjan Martinsen

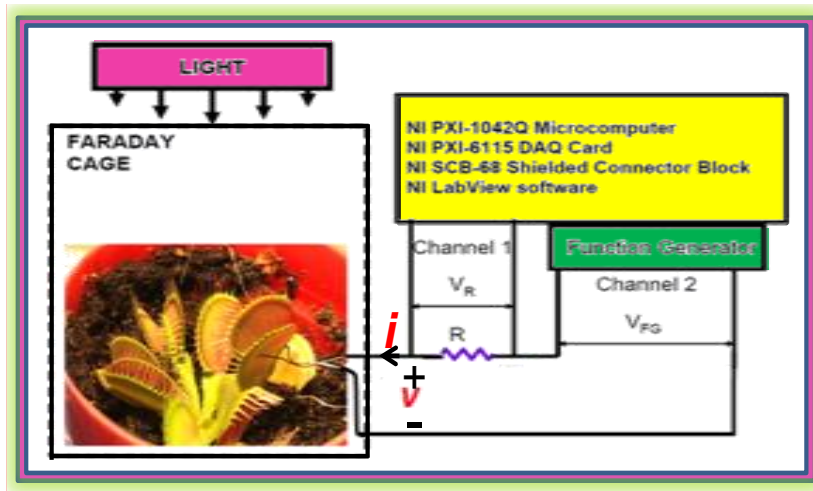
Department of Physics,  
University of Oslo  
September 21, 2015

*Voltage over voltage plot over 2 periods.  $V_{pp} = 10:5V$ ,  $f = 20\text{mHz}$ .  
Left Hand in saline solution, other electrode on left forearm*

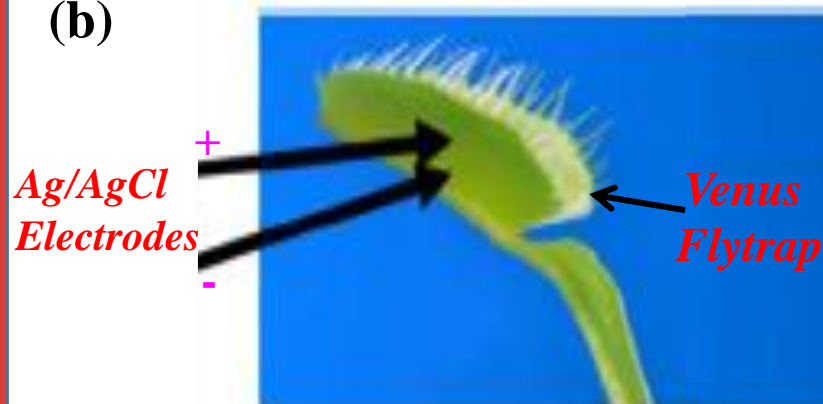
*Our body*  
*is*  
*covered with*  
*Memristors !*

# *Pinched Hysteresis Loop Measured from the Venus Flytrap*

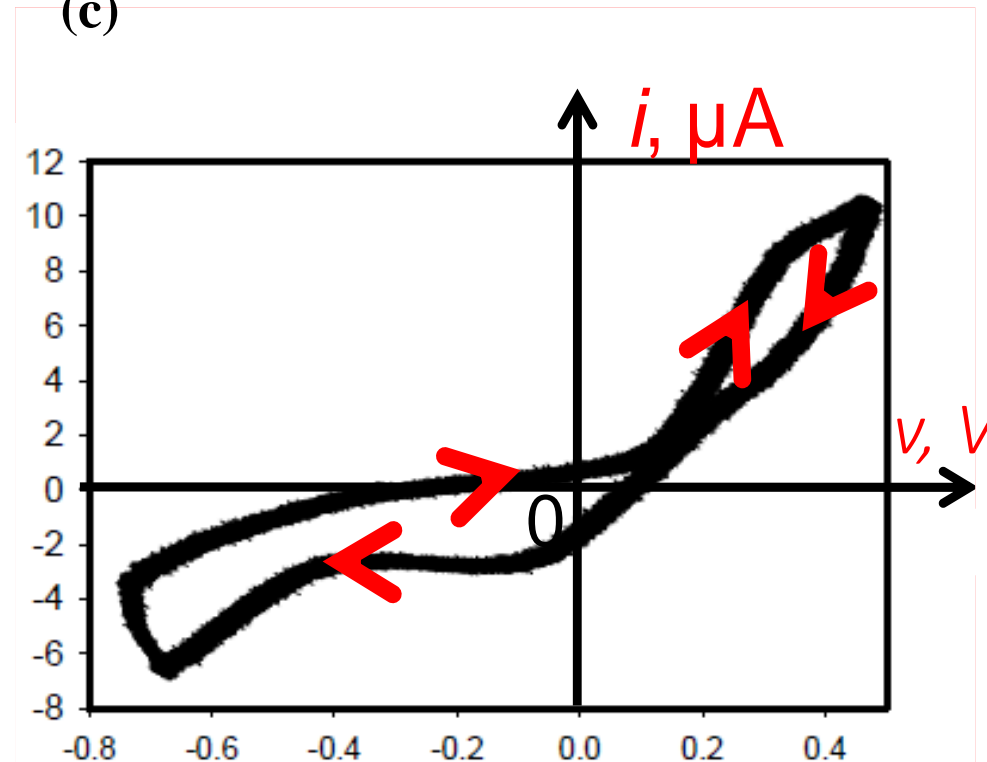
(a)



(b)



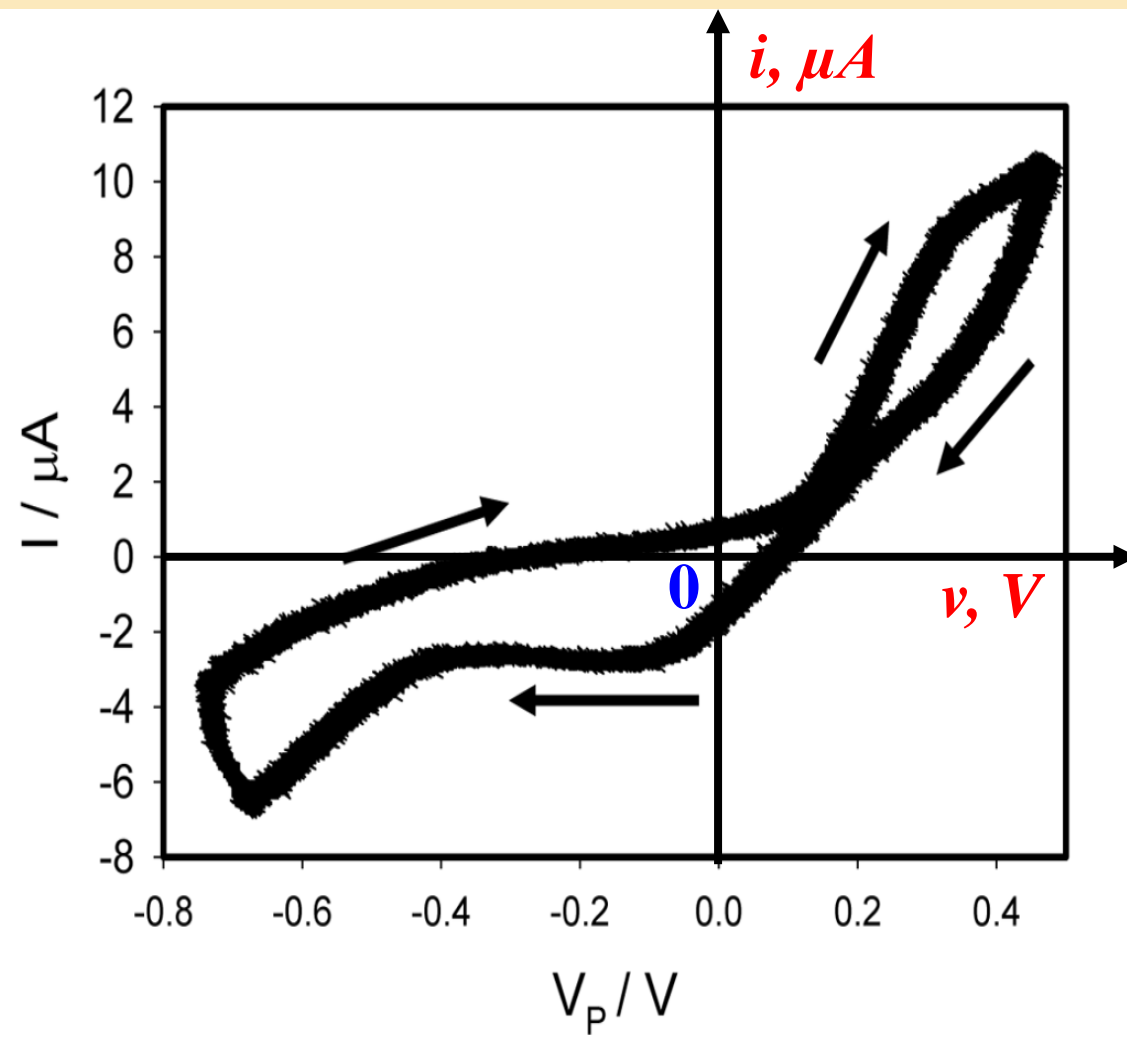
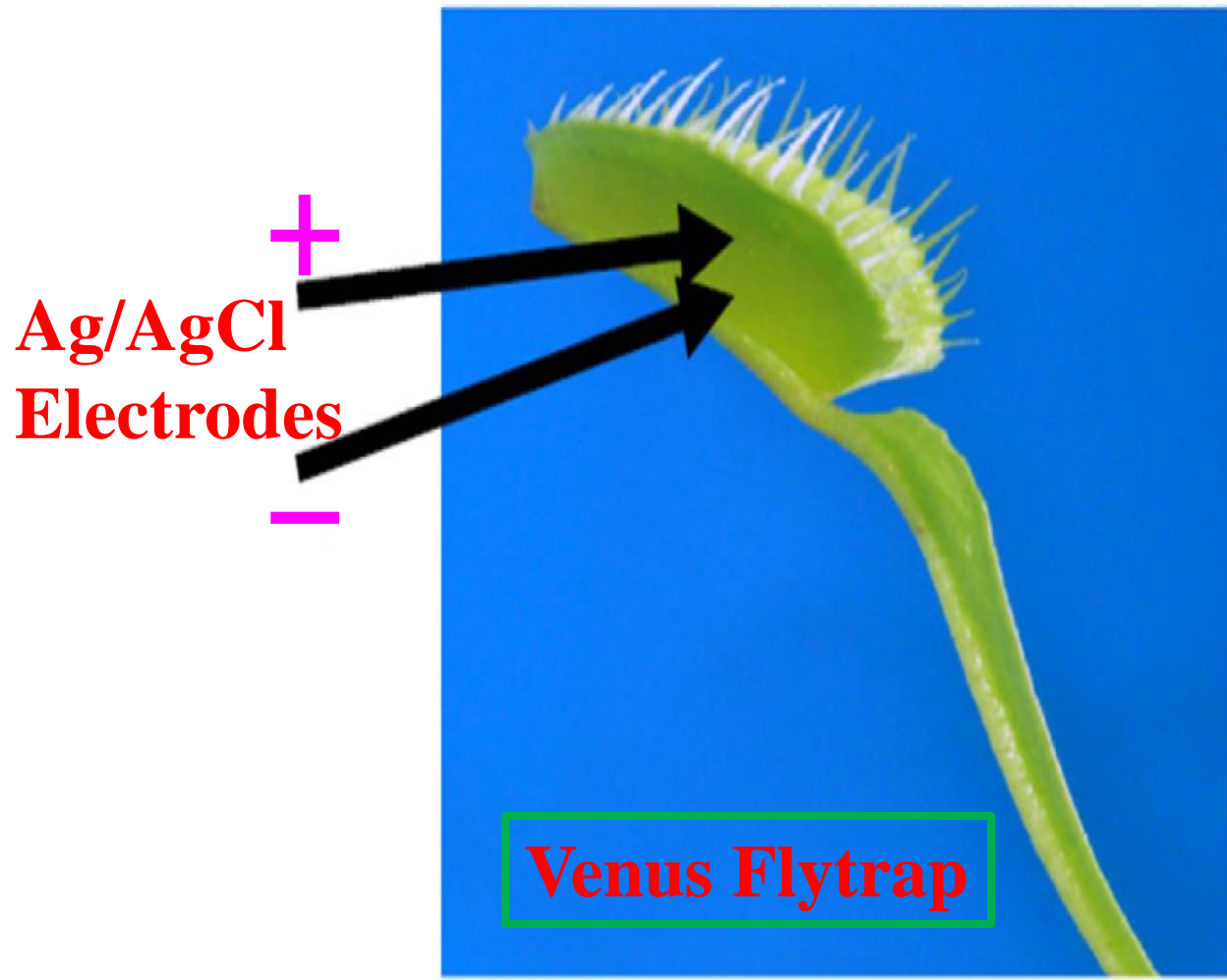
(c)



*Pinched Hysteresis Loop*

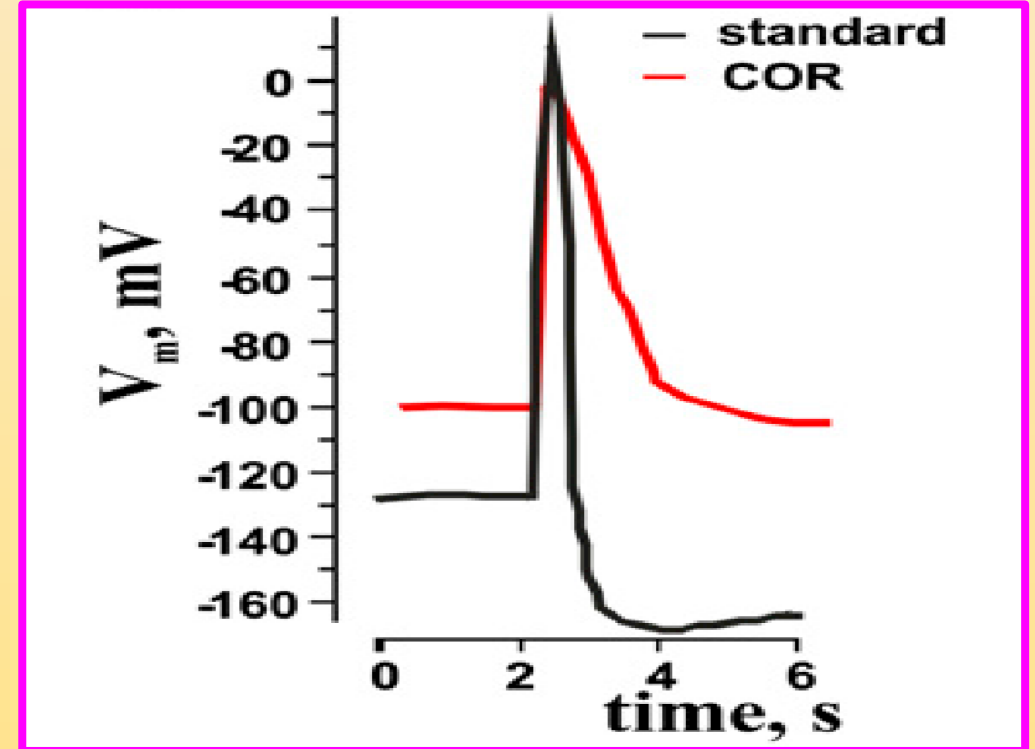
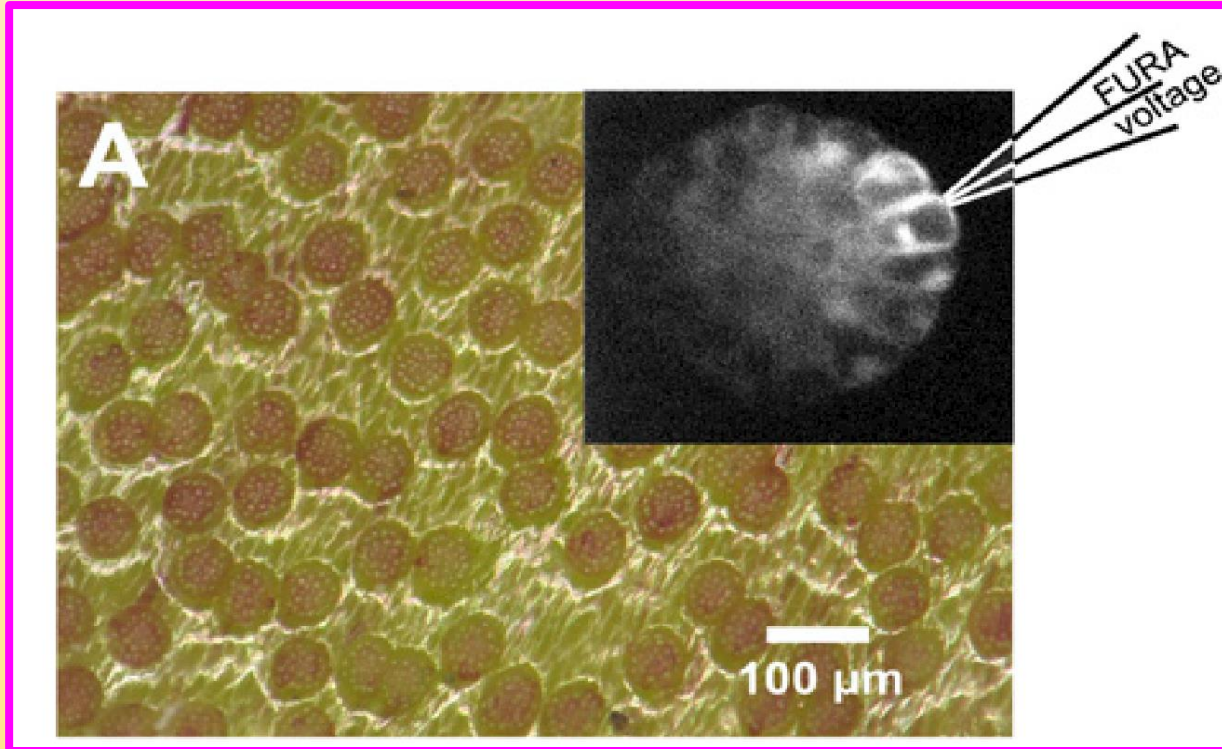
# Venus Flytrap







# *Action Potential Generated by calcium Ion-channel Memristors in the Venus Flytrap*

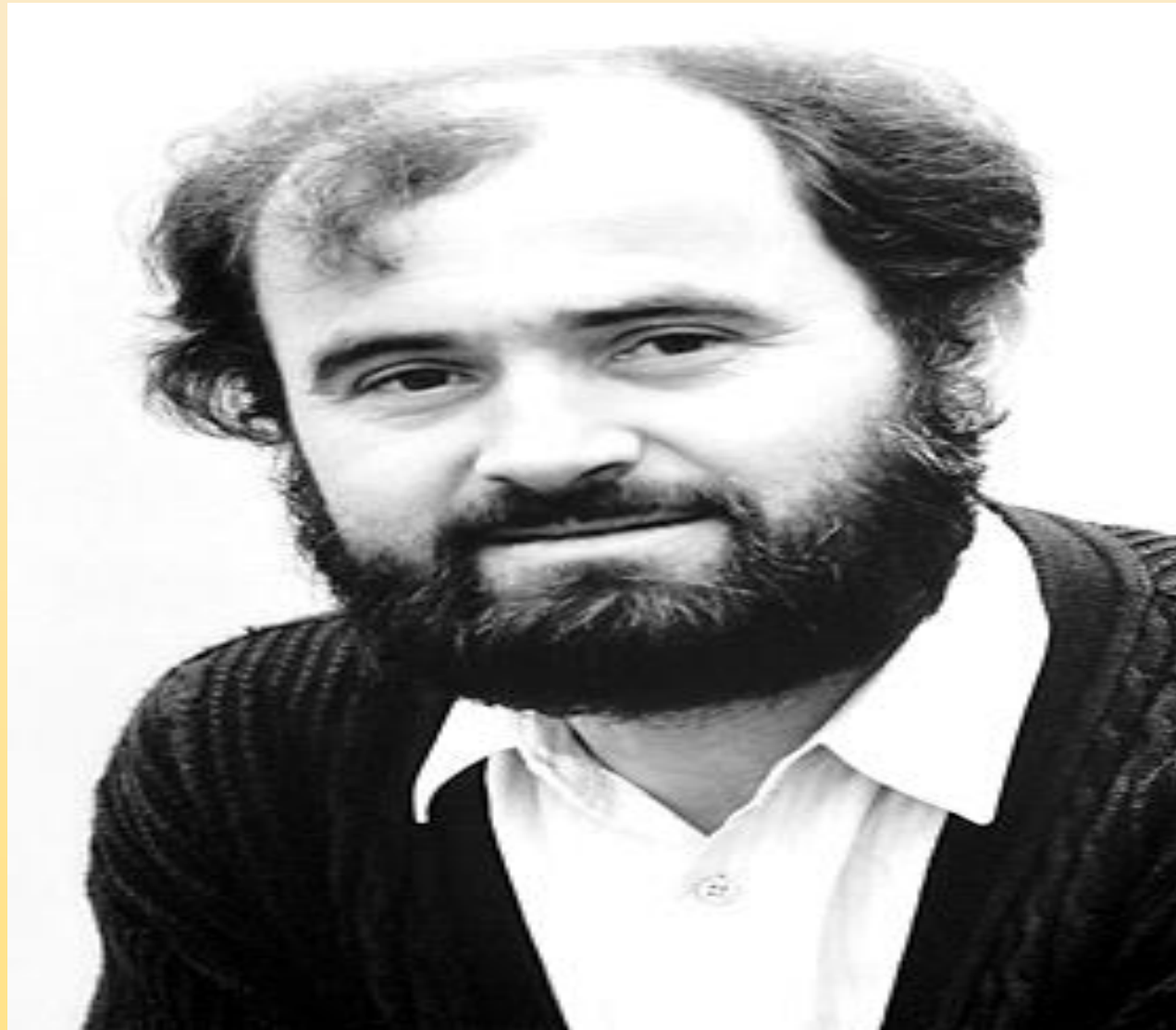


**From :** A special pair of phytohormones controls excitability, slow closure, and external stomach formation in the Venus flytrap

**From :** María Escalante-Pérez, Elzbieta Krol, Annette Stange, Dietmar Geiger, Khaled A. S. Al-Rasheid, Bettina Hause, Erwin Neher, and Rainer Hedrich

*Proc. of National Academy of Science*, vol. 108, September 13, 2011.

*1991  
Nobel  
Prize  
in  
Physiology*



*Discovers  
the function  
of single  
ion  
channels in  
cells*

**Erwin Neher**

*Voltage-Gated  
Ion Channels  
are  
Memristor*

*Where there is*

*smoke*

*there is*

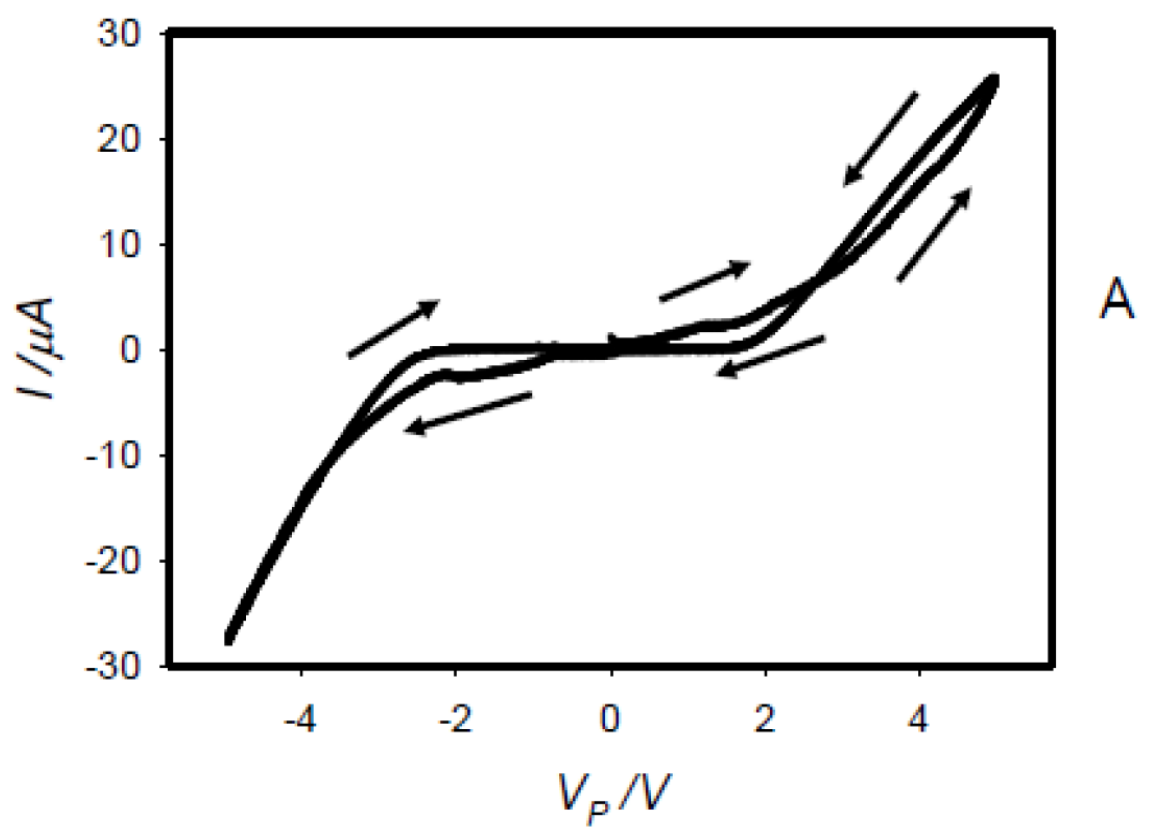
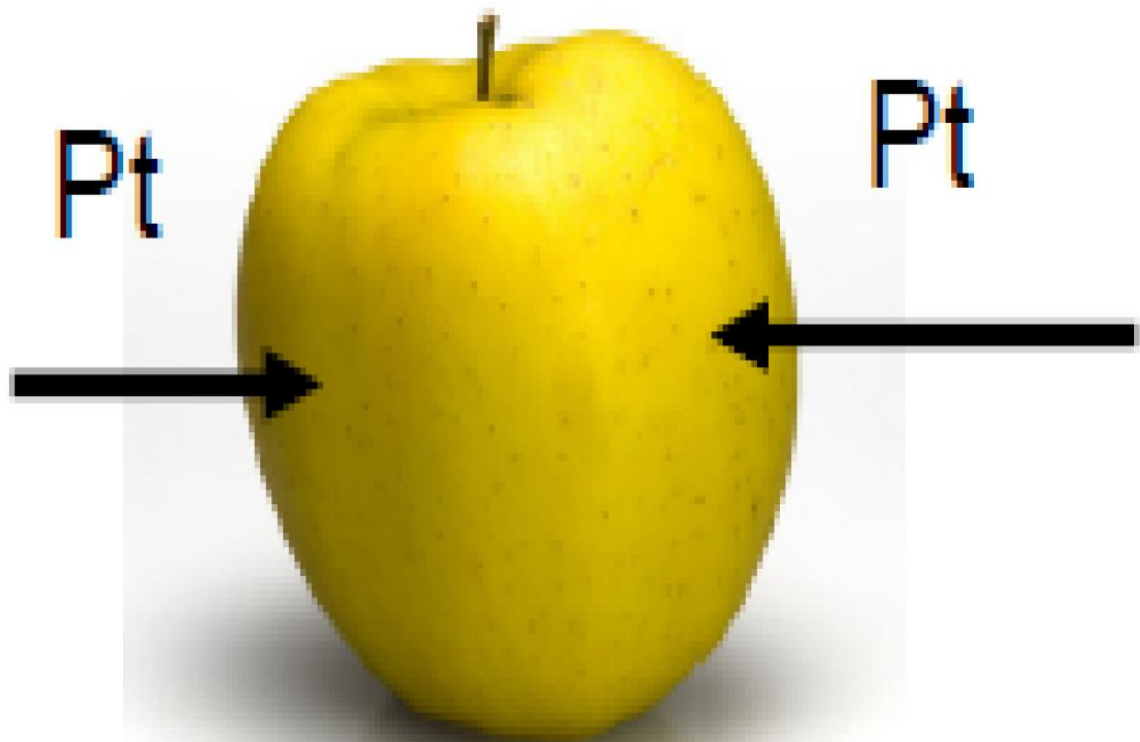
*fire*

*Where there is*

*ion*

*there is*

*memristor*



# *A SunPatiens Flower*

Platinum  
wire



+

$v$

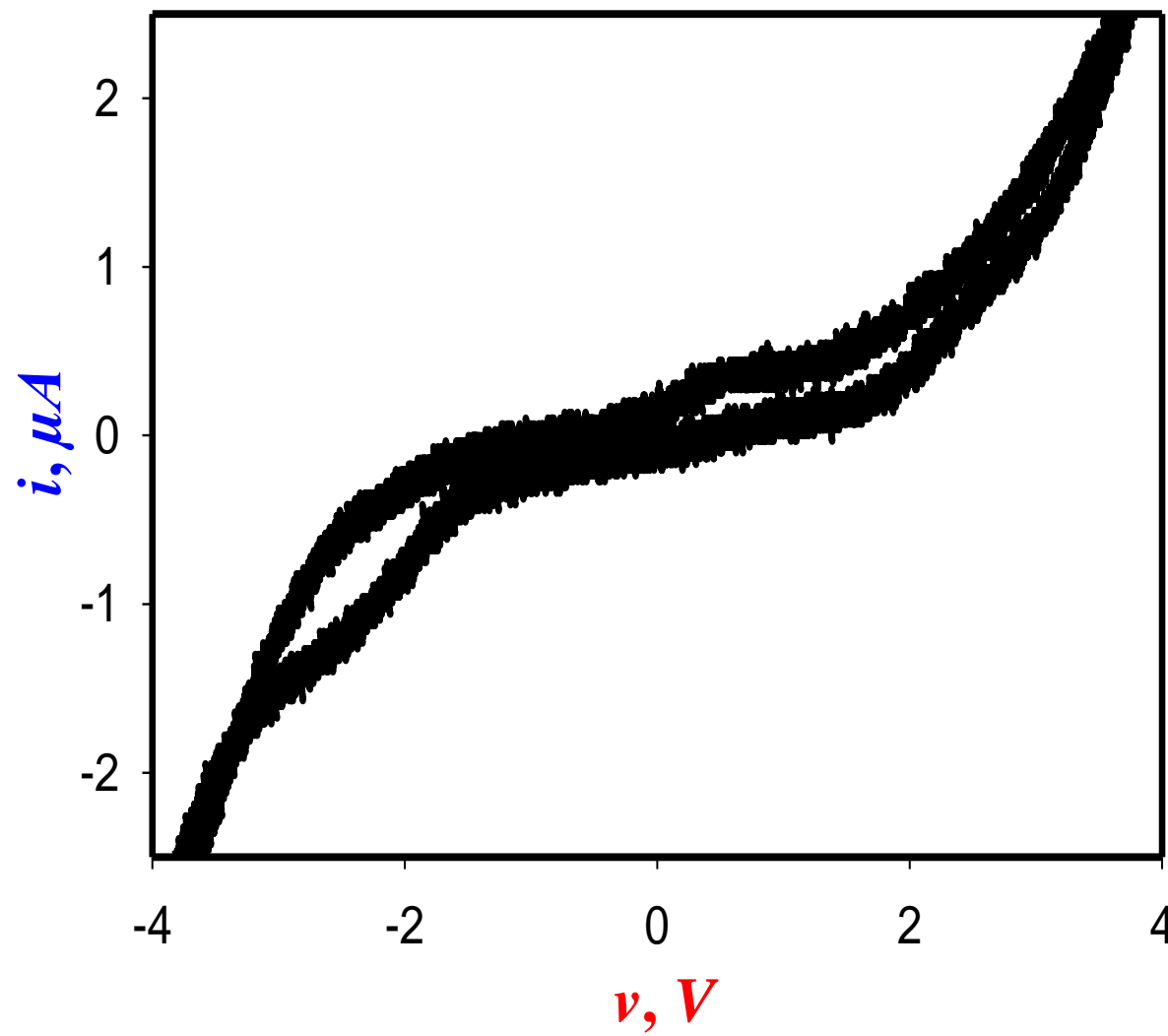


Platinum  
wire



Pt

Pt







Alessandro Volta



Volta explains the principle of the “*electrode column*” to Napoleon



In honor of his invention Volta was made a *count* by Napoleon in 1801.



Voltaic Pile  
(Invented by  
Volta 1800)

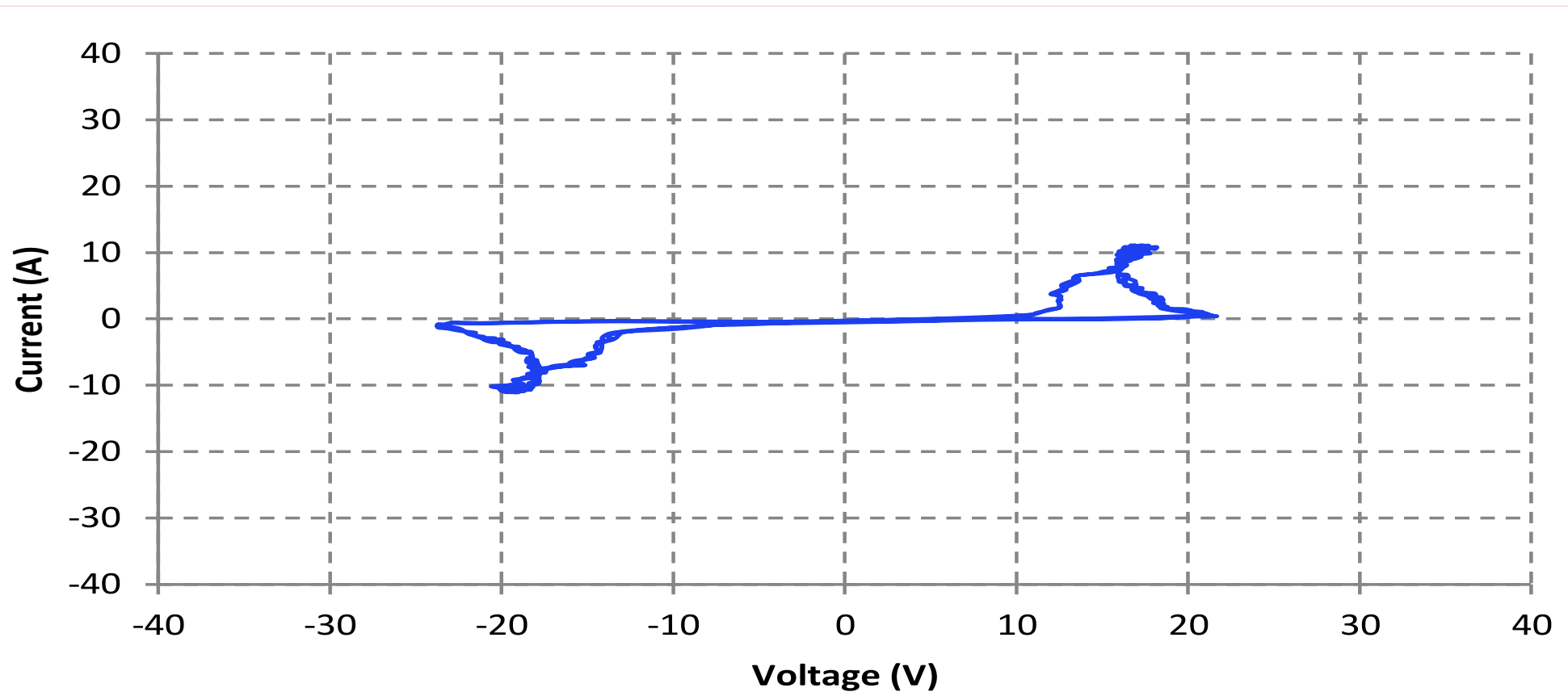


Setup of the carbon rod electrodes



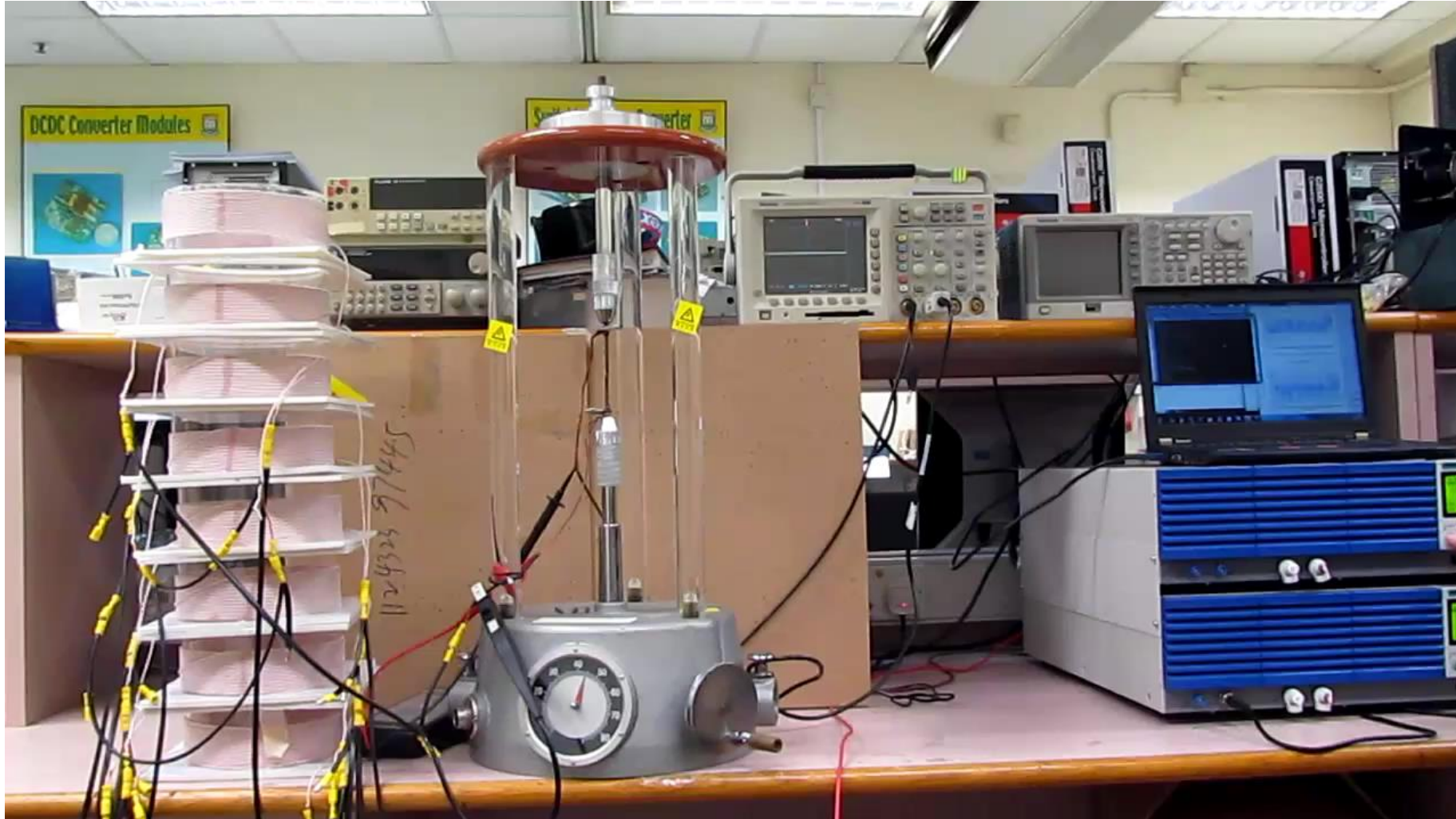
Carbon arc discharge in operation

# *Davy's Carbon-Rod Electrodes Exhibits the Memristor Pinched-Hysteresis Loop Fingerprints*

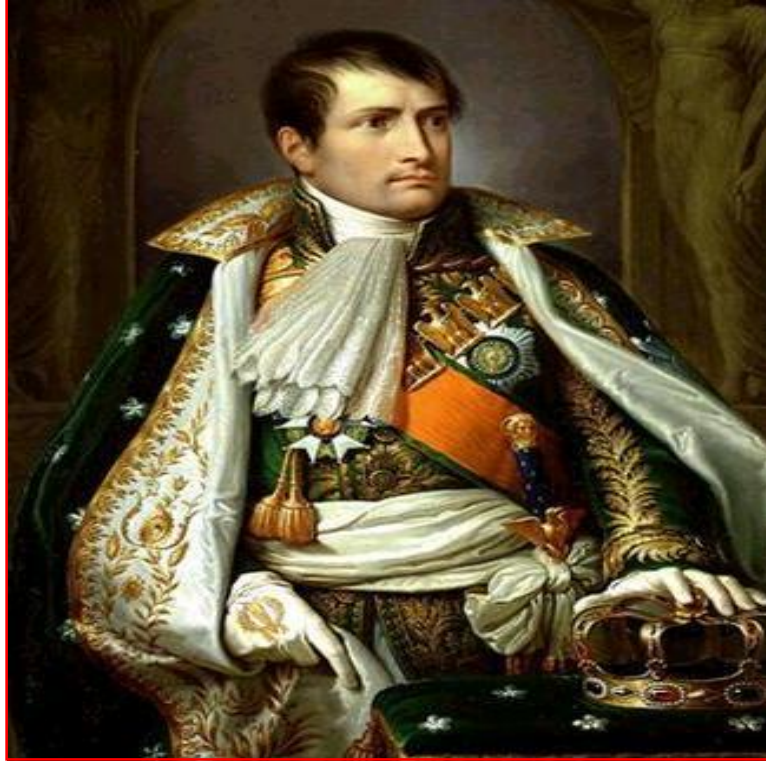


*Input Testing Signal: 3 KHz Sinusoidal Voltage*

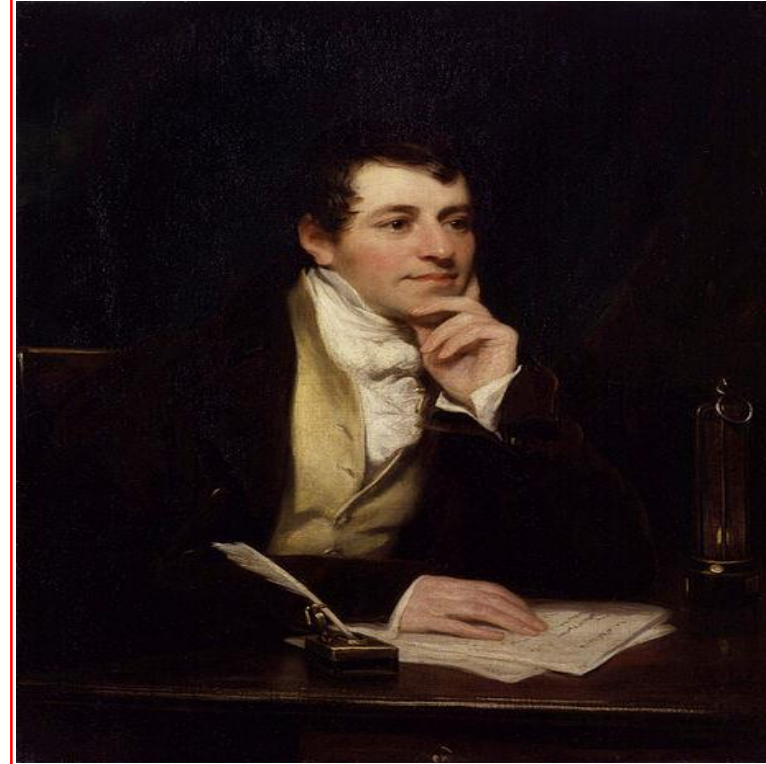
# *Video*



*Bonaparte Napoleon*



*Sir Humphry Davy*



In 1808, when France was at war with England, *Bonaparte Napoleon* has decided to award *Sir Humphry Davy*

*The Prix Napoleon de Institut !*


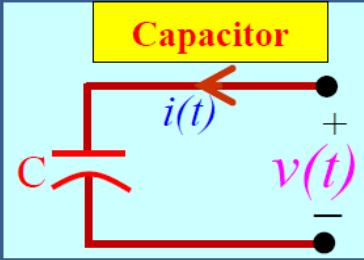

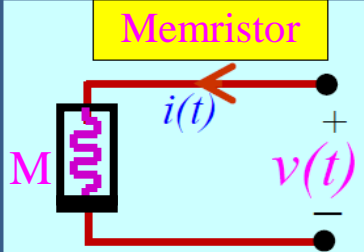

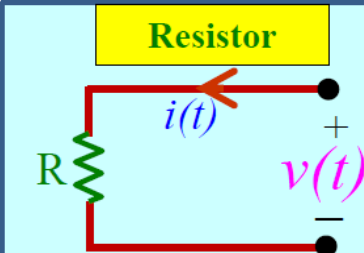

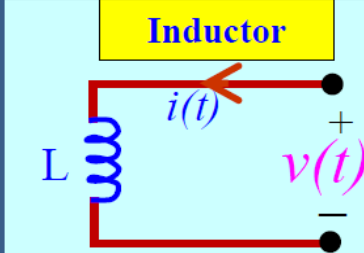
*Faraday* Invented the *Inductor* in 1831



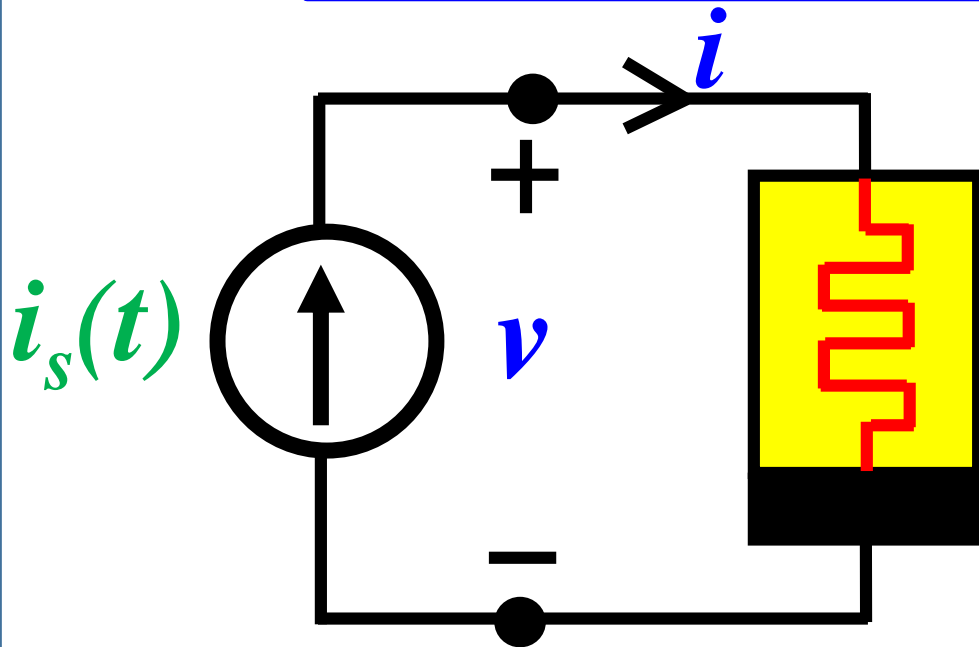
*Michael Faraday*



# 4 Basic Circuit Elements

1745	 Ewald Georg Von Kleist	 Capacitor $C$	$i(t) = C \frac{dv(t)}{dt}$
1801	 Sir Humphry Davy	 Memristor $M$	$v(t) = R(x) i(t)$ $\frac{dx}{dt} = f(x, i)$
1827	 Georg Ohm	 Resistor $R$	$v(t) = R i(t)$
1831	 Michael Faraday	 Inductor $L$	$v(t) = L \frac{di(t)}{dt}$

The Most General *Memristors* are called *Extended Memristors*



**Current-Controlled  
Memristor**

**State and Input-Dependent  
Ohm's Law**

$$v = R(x, i)i$$

where

$$R(x, 0) \neq \infty$$

**State Equation**

$$\frac{dx}{dt} = f(x, i)$$

Why is the **Condition**

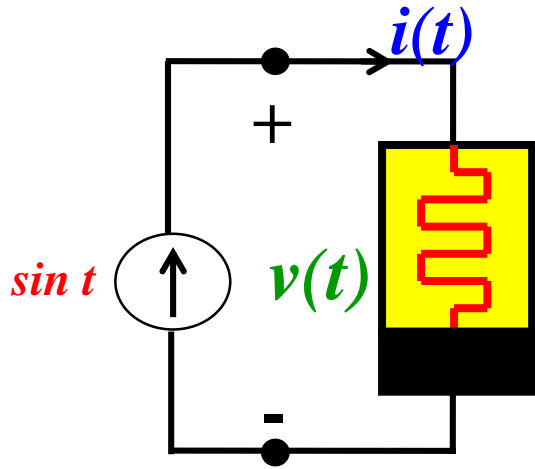
$$R(x, 0) \neq \infty$$

*necessary* in the  
definition of the **state**  
and **Current-Dependent**  
**Ohm's Law**

$$v = R(x, i) i$$



# An Extended Memristor with Unbounded Memristance



*State-Dependent Ohm's Law*

$$v = \left( \frac{x}{i} \right) i$$

$R(x, i)$

*State Equation*

$$\frac{dx}{dt} = i$$

$f(x, i)$

$$i(t) = \sin t$$

$$\frac{dx}{dt} = i = \sin t$$

Assuming  $x(0) = -1$

$$x(t) = -1 + \int_0^t \sin t \, dt = -1 + [-\cos t + 1] = -\cos t$$

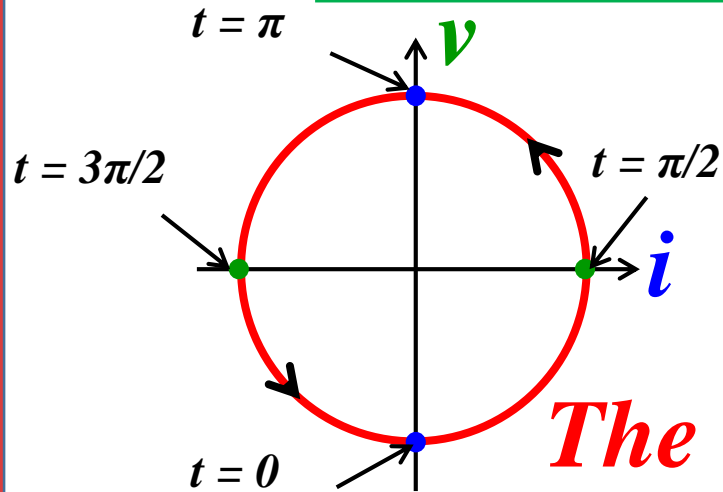
$$v(t) = \left[ \frac{x(t)}{i(t)} \right] i(t) = x(t)$$

$$v(t) = -\cos t$$

Hence,

$$v^2(t) + i^2(t) = (-\cos t)^2 + (\sin t)^2 = 1$$

# An Extended Memristor



$$i = \sin t$$

$$v = -\cos t$$

$$v^2(t) + i^2(t) = 1$$

The  $v$  vs.  $i$  loci is  
**NOT Pinched !**

**Observations :**

(1).  $v = \left( \frac{x}{i} \right) i = x$

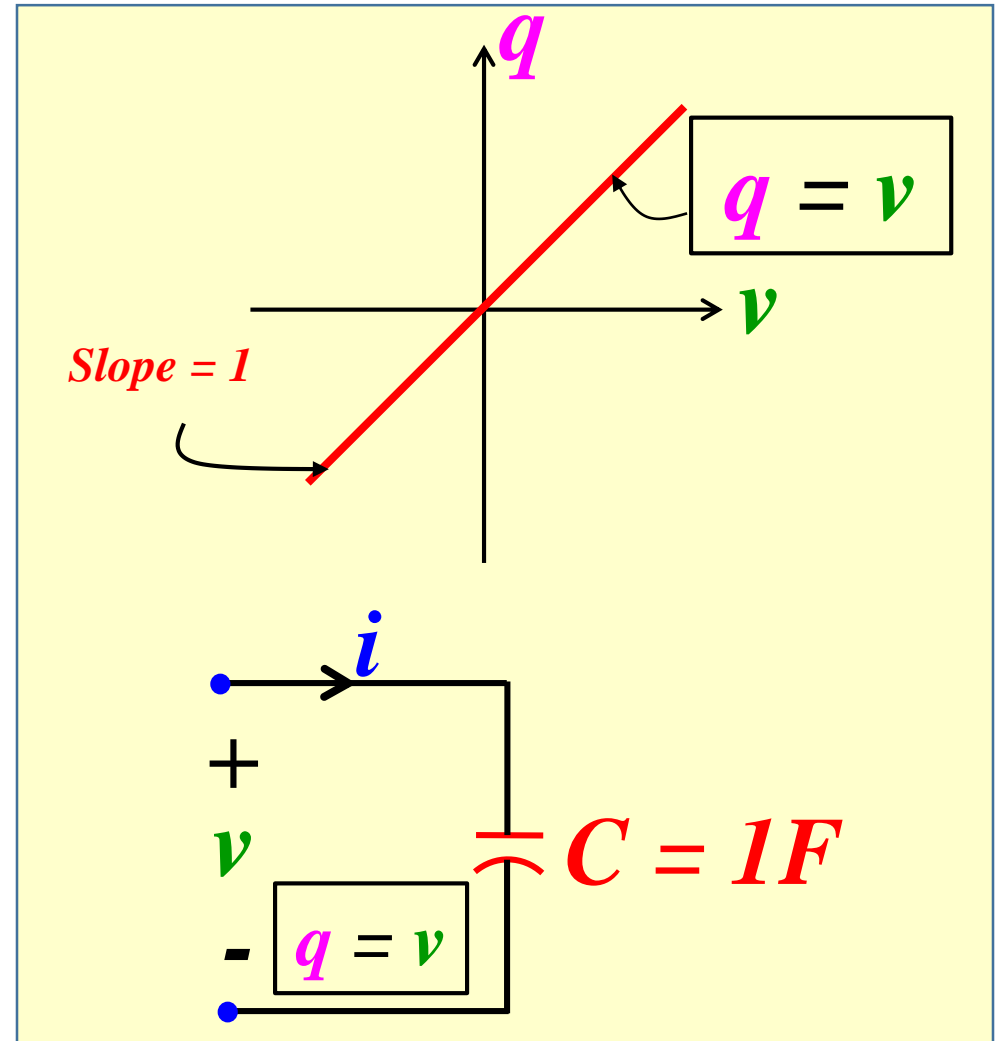
$R(x, i)$

(2).  $\frac{dx}{dt} = i$

$f(x, i)$

$\therefore x = q$  (Charge)

(3). (1) and (2)  $\longrightarrow q = v$



*If It's Not Pinched*

*It's Not A*

***MEMRISTOR***

# Example of An *Erroneous Memcapacitor*

PHYSICAL REVIEW B **81**, 195430 (2010)



## Solid-state memcapacitive system with negative and diverging capacitance

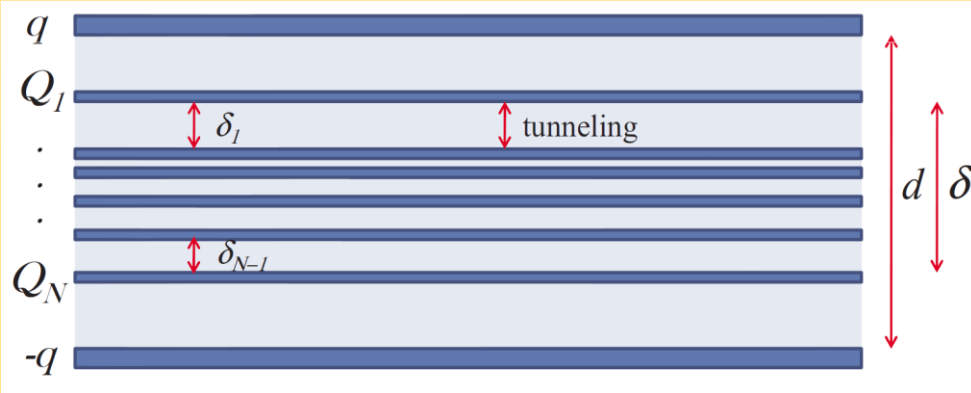
J. Martinez-Rincon,<sup>1</sup> M. Di Ventra,<sup>2</sup> and Yu. V. Pershin<sup>1</sup>

<sup>1</sup>Department of Physics and Astronomy and USC Nanocenter, University of South Carolina, Columbia, South Carolina 29208, USA

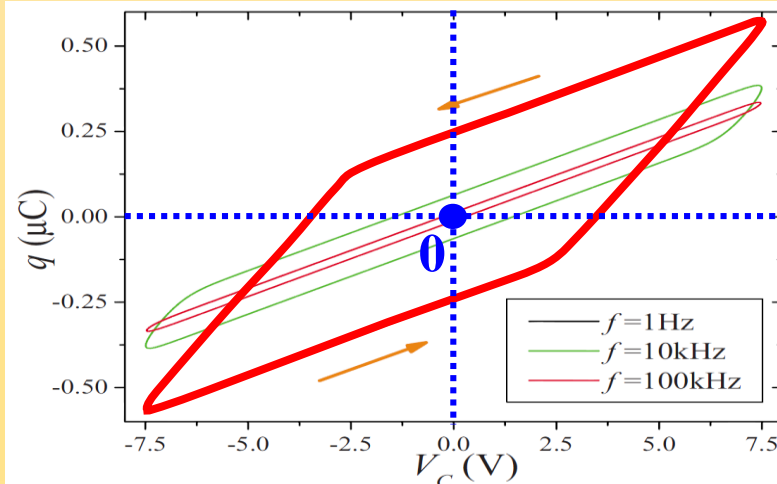
<sup>2</sup>Department of Physics, University of California–San Diego, La Jolla, California 92093-0319, USA

(Received 24 February 2010; revised manuscript received 30 April 2010; published 25 May 2010)

We suggest a possible realization of a solid-state memory capacitive (memcapacitive) system. Our approach relies on the slow polarization rate of a medium between plates of a regular capacitor. To achieve this goal, we consider a multilayer structure embedded in a capacitor. The multilayer structure is formed by metallic layers separated by an insulator so that nonlinear electronic transport (tunneling) between the layers can occur. The suggested memcapacitor shows hysteretic charge-voltage and capacitance-voltage curves, and both negative and diverging capacitance within certain ranges of the field. This proposal can be easily realized experimentally and indicates the possibility of information storage in memcapacitive systems.



General scheme of a solid-state memcapacitor. A metamaterial medium consisting of  $N$  metal layers embedded into an insulator is inserted between the plates of a “regular” capacitor.



Charge-voltage plot at different applied voltage frequencies  $f$ . The decrease in the hysteresis at higher frequencies is a signature of memcapacitors.

Hysteresis loop in  $q - v$  plane is *not pinched*

➔ **not a memcapacitor**